(11) Publication number:

0 091 326

A2

(12)

EUROPEAN PATENT APPLICATION

21) Application number: 83303664.3

(51) Int. Cl.³: **G** 03 **C** 1/02 G 03 C 7/12

(22) Date of filing: 24.06.83

(43) Date of publication of application: 12.10.83 Bulletin 83/41

(84) Designated Contracting States: GB

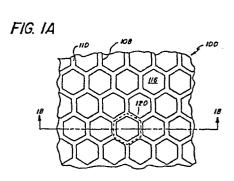
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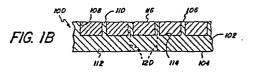
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(54) Imaging with high aspect ratio tabular grain emulsions and nonplanar support elements.

A photosensitive element comprising a support and radiation-sensitive imaging means capable of undergoing as a function of at least one of photographic exposure and processing a change in the optical density or mobility of the imaging means is disclosed. The support provides a nonplanar surface pattern forming an array, and the imaging means includes a high aspect ratio tabular grain silver halide emulsion coprised of a dispersing medium and silver halide grains, wherein tabular silver halide grains having a thickness of less than 0.5 micron and a diameter of at least 0.6 micron have an average aspect ratio of greater than 8:1 and account for at least 50 percent of the total projected area of the silver halide grains.







IMAGING WITH HIGH ASPECT RATIO TABULAR GRAIN EMULSIONS AND NONPLANAR SUPPORT ELEMENTS

This invention relates to a photosensitive element comprising a nonplanar support and a tabular grain silver halide emulsion.

High aspect ratio tabular grain silver halide emulsions, their preparation, and use in photographic elements is the subject matter of Research Disclosure, Vol. 225, January 1983, Item 22534.

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Photosensitive elements having supports providing a nonplanar surface pattern forming an array have been disclosed by Whitmore U.S. Patents 4,362,806 and 4375,507, Gilmour U.K. Specification 2,091,433A, Blazey et al U.S. Patent 4,307,105, Gilmour et al E.P.C. Specification 50,474, Land E.P.C. Specification 58,568, Gerber U.S. Patents 4,356,257 and 4,359,525, and Walworth U.S. Patent 4,359,526.

20 According to the present invention there is provided a photosensitive element comprising a support and radiation-sensitive imaging means capable of undergoing as a function of at least one of photographic exposure and processing a change in 25 the optical density or mobility of said imaging means characterized in that said support provides a nonplanar surface pattern forming an array and said imaging means includes a high aspect ratio tabular grain silver halide emulsion comprised of a dispersing medium and silver halide grains, wherein tabular silver halide grains having a thickness of less than 0.5 micron and a diameter of at least 0.6 micron have an average aspect ratio of greater than 8:1 and account for at least 50 percent of the total 35 projected area of the silver halide grains.

Summary of the Drawings

The invention can be better appreciated by consideration of the detailed description in

conjunction with the drawings, in which

Figure 1A is a plan view of an element portion;

Figure 1B is a sectional view taken along section line 1B-1B in Figure 1A;

Figures 2 through 5 are sectional views of alternative pixel (defined below) constructions;

Figure 6 through 8 are plan views of alternative element portions;

Figures 9 and 10 are sectional details of alternative element portions;

Figures 11A and 11D are plan views of alternative element portions;

Figure 11B is a sectional view taken along 15 section line 11B-11B is Figure 11A;

Figures 11C and 12 through 14 are sectional views of photographic elements according to this invention;

Figures 15, 16, and 17 are sectional 20 details of image transfer film units;

Figure 18 is a schematic isometric view of a microcell filling arrangement;

Figures 19A through D are sectional details illustrating a sequence for filling microcells;

Figure 20 is a sectional detail of an element portion having microcells formed in a photoconductive layer;

Figures 21A through D are sectional details illustrating a sequence for filling microcells;

Figure 22 is a plan view of an element showing a particular loading pattern of the microcells;

Figure 23A is a plan view of an element portion;

Figure 23B is a sectional detail taken along section line 23B-23B in Figure 23A;

Figure 24 is a plan view of an alternative element portion;

Figure 25A is a plan view of an alternative element portion;

Figure 25B and 25C are sectional details taken along section line 25B-25B in Figure 25A showing differing stages of angled exposure;

Figures 26A and 26B show different angled exposure patterns of an element portion shown in plan view;

Figures 27 and 28A are plan views of 10 alternate element portions;

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Figures 28B and 28C are sectional views at different stages of loading taken along section line 28B-28B in Figure 28A;

Figure 29 is a sectional detail of an 15 alternate element portion;

Figure 30A is a plan view of an alternate element portion;

Figures 30B and 30C are sectional views at different stages of loading taken along section line 30B-30B in Figure 30A;

Figures 31, 32, and 33 are plan views of alternate element portions; and

Figure 34 is a sectional detail of an alternate element portion construction.

Description of the Preferred Embodiments

While subheadings are provided for convenience, to appreciate fully the elements of the invention, it is intended that the disclosure be read and intrepreted as a whole.

30 <u>Illustrative Photographic Element Configurations</u>

A preferred embodiment of a photographic element constructed according to the present invention is a photographic element 100 schematically illustrated in Figures 1A and 1B. The element is comprised of a support 102 having substantially parallel first and second major surfaces 104 and

parallel first and second major surfaces 104 and 106. The support defines a plurality of tiny cavities or microcells (hereinafter termed micro-

cells or reaction microcells) 108 which open toward the second major surface of the support. The reaction microcells are defined in the support by an interconnecting network of lateral walls 110 which are of lesser width than the adjacent microcells they define. As a result, next adjacent microcells

are laterally spaced by less than their widths. The lateral walls are integrally joined to an underlying portion 112 of the support so that the support acts

as a barrier between adjacent microcells. The underlying portion of the support defines the bottom wall 114 of each reaction microcell. Within each reaction microcell is provided a radiation-sensitive imaging material 116 which is capable of undergoing

as a function of photographic exposure and/or processing a change in its optical density or mobility but which includes at least one component exhibiting the characteristic of visually detectable lateral image spreading in translating an exposure pattern to a viewable form when coated on a planar

support surface as a continuous layer.

The dashed line 120 is a boundary of a pixel. The term "pixel" is employed herein to indicate a single unit of the photographic element which is repeated to make up the entire imaging area of the element. This is consistent with the general use of the term in the imaging arts. The number of pixels is, of course, dependent on the size of the individual pixels and the dimensions of the photographic element. Looking at the pixels collectively, it is apparent that the imaging material in the reaction microcells can be viewed as a segmented layer associated with the support.

The photographic elements of the present
invention can be varied in their geometrical configurations and structural makeup. For example, Figure
schematically illustrates in section a single
pixel of a photographic element 200. The support

202 is provided for a first major surface 204 and a second, substantially parallel major surface 206. A reaction microcell 208 opens toward the second major surface. Contained within the reaction microcell is a radiation-sensitive material 216. The reaction microcells are formed so that the support provides inwardly sloping walls which perform the functions of both the lateral and bottom walls of the microcells 108. Such inwardly curving wall structures are more conveniently formed by certain techniques of manufacture, such as etching, and also can be better suited toward redirecting exposing radiation toward the interior of the reaction microcells.

In Figure 3 a pixel of a photographic 15 element 300 is shown. The element is comprised of a first support element 302 having a first major surface 304 and a second, substantially parallel major surface 306. Joined to the first support element is a second support element 308 which is provided in each pixel with an aperture 310. second support element is provided with an outer major surface 312. The walls of the second support element forming the aperture 310 and the second major surface of the first support element together define a reaction microcell. A radiation-sensitive material 316 is located in the reaction microcell. Additionally, a relatively thin extension 314 of the radiation-sensitive material overlies the outer major surface of the upper support element and forms 30 a continuous layer joining adjacent pixels. The lateral extensions of the radiation-sensitive material are sometimes a by-product of a specific technique of coating the radiation-sensitive material. One coating technique which can leave 35 extensions of the radiation-sensitive material is doctor blade coating. It is generally preferred that the lateral extensions be absent or of the least possible thickness.

In Figure 4 a pixel of a photographic element 400 is illustrated comprised of a support 402, which can be of extended depth. The support is provided with a first major surface 404 and a 5 second, substantially parallel major surface 406. The support defines a reaction microcell 408 which can be similar to reaction microcell 108, but is by comparison of extended depth. Two components 416 and 418 together form a radiation-sensitive imaging 10 means which is capable of translating an imaging radiation pattern striking it into a viewable image, but which exhibits the characteristic of permitting visually detectable lateral image spreading to occur in translating the imaging radiation pattern to a viewable form when coated on a planar surface as two continuous layers. The first component 416, which in a continuous layer form would produce visually detectable lateral image spreading, forms a column of extended depth, as compared with the material 116 20 in the reaction microcells 108. The second component 418 is in the form of a continuous layer overlying the second major surface of the support. In an alternative form the first component can be identical to the radiation-sensitive imaging 25 material 116--that is, itself form the entire radiation-sensitive imaging means--and the second component 418 can be a continuous layer which performs another function, such as those conventionally performed by overcoat layers.

In Figure 5 a pixel of a photographic element 500 is illustrated comprised of a first support element 502 having a first major surface 504 and a second, substantially parallel major surface 506. Joined to the first support element is a transparent second support element 508 which is provided with a network of lateral walls 510 integrally joined to an underlying portion 512 of the second support element. In one preferred form the

first support element is a relatively nondeformable element while the second support element is relatively deformable. An indentation 514 is formed in the second support element in each pixel area. The surfaces of the second support element adjacent its outer major surface, that is the outer surface of the lateral walls, as well as the surfaces of the indentation, are overlaid with a thin layer 515, which performs one or a combination of surface 10 modifying functions. The portion of the coating lying within the indentation defines the boundaries of a reaction microcell 517. A first component 516 which lies within the reaction microcell and a second component 518 which overlies one entire major 15 surface of the pixel can be similar to the first and second components 416 and 418, respectively.

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Each of the pixels shown in Figures 2 through 5 can be of a configuration and arranged in relation to other pixels so that the photographic 20 elements 200, 300, 400 and 500 (ignoring any continuous material layers overlying the viewed major surfaces of the supports) appear identical in plan view to the photographic element 100. The pixels 120 shown in Figure 1 are hexagonal in plan view, 25 but it is appreciated that a variety of other pixel shapes and arrangements are possible. For example, in Figure 6 a photographic element 600 is shown comprised of a support 602 provided with reaction microcells 608, which are circular in plan view, 30 containing radiation-sensitive material 616. Reaction microcells which are circular in plan are particularly suited to formation by etching techniques, although they can be easily formed by other techniques, as well. A disadvantage of the circular 35 reaction microcells as compared with other configurations shown is that the lateral walls 610 vary continuously in width. Providing lateral walls of at least the minimum required width at their narrowest point inherently requires the walls in some portions of the pattern to be larger than that required minimum width. In Figure 7 a photographic element 700 is shown comprised of a support 702 provided with reaction microcells 708, which are square in plan view, containing radiation-sensitive material 716. The lateral walls 710 are of uniform width.

Figure 8 illustrates an element 800

10 comprised of a support 802 having an interlaid pattern of rectangular reaction microcells 808.

Each of the microcells contains a radiation-sensitive imaging material 816. The dashed line 820 identifies a single pixel of the element.

In each of the elements 100 through 500, the surface of the support remote from the reaction microcells is illustrated as being planar. This is convenient for many photographic applications, but is not essential to the practice of this invention.

Other element configurations are contemplated, particularly where the support is transparent to exposing radiation and/or when viewed.

For example, in Figure 9 a photographic element 900 is illustrated. The element is comprised of a support 902 having substantially parallel first and second major surfaces 904 and The support defines a plurality of reaction microcells 908A and 908B which open toward the first and second major surfaces, respectively. In the 30 preferred form, the reaction microcells 908A are aligned with the reaction microcells 908B along axes perpendicular to the major surfaces. The reaction microcells are defined in the support by two interconnecting networks of lateral walls 910A and 910B 35 which are integrally joined by an underlying, preferably transparent, portion 912 of the support. Within each reaction microcell is provided a radiation-sensitive material 916.

It can be seen that element 900 is essentially similar to element 100, except that the former element contains reaction microcells along both major surfaces of the support. Thus the microcells form two separate planar arrays, one along each major surface of the support. As shown, the lateral walls 910A and 910B and the underlying portion 912 are proportioned so that next adjacent of the microcells forming the same planar array are laterally spaced by less than the width of adjacent microcells opening toward either of the first and second major surfaces. It is apparent that similar variants of the photographic elements 200, 300, 400, 500, 600, 700 and 800 can be formed.

15 In Figure 10 a photographic element 1000 is illustrated. The element is comprised of a support 1002 having a lenticular first major surface 1004 and a second major surface 1006. Reaction microcells 1008 containing radiation-sensitive material 20 1016 and defined by lateral walls 1010 of the support open toward the second major surface. element is made up of a plurality of pixels indicated in one occurrence by dashed line boundary 1020. Individual lenticules are coextensive with 25 the pixel boundaries. Although element 1000 is shown as a modification of element 100 to which the feature of a lenticular surface has been added, it is appreciated that photographic elements 200, 300,

The photographic elements and pixels thereof illustrated schematically in Figures 1 through 10 are merely exemplary of a wide variety of forms which the elements of this invention can take. For ease of illustration the drawings show the pixels greatly enlarged and with some deliberate distortions of relative proportions. For example, as is well known in the photographic arts, support

400, 500, 600, 700 and 800 can be similarly modified

30 to provide lenticules.

thicknesses often range from about 10 times the thickness of the radiation-sensitive layers coated thereon up to 50 or even 100 times their thickness. Thus, in keeping with the usual practice in patent drawings in this art, the relative thicknesses of the supports have been reduced. This has permitted the reaction microcells to be drawn conveniently to a larger scale.

One function of the microcells provided in 10 the photographic elements is to limit or control lateral image spreading. The degree to which it is desirable to limit or control lateral image spreading will depend upon the photographic application. For most imaging applications the microcells are 15 preferably sufficiently small in size that the unaided eye does not detect discrete image areas (graininess) in viewing images in the photographic element or images made from the photographic element. Where the photographic image is to be 20 viewed without enlargement and minimal visible graininess is desired, microcells having widths within the range of from about 1 to 200 microns, preferably from about 4 to 100 microns, are contemplated for use in the practice of this invention. 25 To the extent that visible graininess can be tolerated for the photographic application, the microcells can be still larger in width. Where the photographic images produced are intended for enlargement, microcell widths in the lower portion 30 of the width ranges are preferred. It is accordingly preferred that the microcells be about 20 microns or less in width where enlargements are to be made of the images produced by the photographic elements of this invention.

The lower limit on the size of the reaction microcells is a function of the photographic speed desired for the element. As the areal extent of the reaction microcell is decreased, the probability of

an imaging amount of radiation striking a particular reaction microcell on exposure is reduced. Reaction microcell widths of at least about 7 microns, preferably at least 8 microns, optimally at least 10 microns, are contemplated where the reaction microcell contains radiation-sensitive material. At widths below 7 microns, silver halide emulsions in the microcells can be expected to show a significant reduction in speed.

10 The reaction microcells are of sufficient depth to contain at least a major portion of the radiation-sensitive material. In one preferred form the reaction microcells are of sufficient depth that the radiation-sensitive materials are entirely 15 contained therein when employed in conventional coating thicknesses, and the support element which forms the lateral walls of the reaction microcells efficiently divides the radiation-sensitive materials into discrete units or islands. In some 20 forms the reaction microcells do not contain all, but only a major portion, of the radiation-sensitive material, as can occur, for example, by introducing the radiation-sensitive material into the reaction microcells by doctor blade coating.

The minimum depth of the reaction microcells is that which allows the support element to provide an effective lateral wall blockage of image spreading. In terms of actual dimensions the minimum depth of the reaction microcells can vary as a function of the radiation-sensitive material employed and the maximum density which is desired to be produced. The depth of the reaction microcells can be less than, equal to or greater than their width. The thickness of the imaging material or the component thereof coated in the microcells is preferably at least equal to the thicknesses to which the material is conventionally continuously coated on planar support surfaces. This permits a

maximum density to be achieved within the area subtended by the reaction microcell which approximates the maximum density that can be achieved in imaging a corresponding coating of the same radiation-sensitive material. It is recognized that reflected radiation from the microcell walls during exposure and/or viewing can have the effect of yielding a somewhat different density than obtained in an otherwise comparable continuous coating of the 10 radiation-sensitive material. For instance, where the microcell walls are reflective and the radiation-sensitive material is negative-working, a higher density can be obtained during exposure within the microcells than would be obtained with a 15 continuous coating of the same thickness of the radiation-sensitive material.

Because the areas lying between adjacent reaction microcells are free of radiation-sensitive material (or contain at most a relatively minor 20 proportion of the radiation-sensitive material), the visual effect of achieving a maximum density within the areas subtended by the reaction microcells equal to the maximum density in a corresponding conventional continuous coating of the radiation-sensitive 25 material is that of a somewhat reduced density. exact amount of the reduction in density is a function of the thickness of any material lying within the reaction microcells as well as the spacing between adjacent reaction microcells. Where 30 the continuous conventional coating produces a density substantially less than the maximum density obtainable by increasing the thickness of the coating and the reaction microcell area is a larger fraction of the pixel area (e.g., 90 to 99 percent), 35 the comparative loss of density attributable to the spacing of reaction microcells can be at least partially offset by increasing the thickness of the imaging material or component in the reaction

microcell. This, of course, means increasing the
minimum depth of the reaction microcells. Where the
photographic element is not intended to be viewed
directly, but is to be used as an intermediate for
photographic purposes, such as a negative which is
used as a printing master to form positive images in
a reflection print photographic element, the effect
of spacing between adjacent reaction microcells can
be eliminated in the reflection print by applying
known printing techniques, such as slightly displacing the reflection print with respect to the master
during the printing exposure, employing an optical
filter, controlling a chemical diffusion path, or
controlling a scanning beam. Thus, in this
instance, increase in the depth of the reaction

instance, increase in the depth of the reaction microcells is not necessary to achieve conventional maximum density levels with conventional thicknesses of radiation-sensitive materials.

The maximum depth of the reaction micro- 20 cells can be substantially greater than the thickness of the radiation-sensitive matereal to be placed therein. For certain coating techniques it is preferred that the maximum depth of the reaction microcells approximate or substantially equal the 25 thickness of the radiation-sensitive material to be employed. In forming conventional continuous coatings of radiation-sensitive materials one factor which limits the maximum thickness of the coating material is acceptable lateral image spreading, 30 since the thicker the coating, the greater is the tendency, in most instances, toward loss of image definition. In the present invention lateral image spreading is limited by the lateral walls of the support element defining the reaction microcells and 35 is independent of the thickness of the radiaon-sensitive material located in the microcells. Thus, it is possible and specifically contemplated in the

present invention to employ reaction microcell

depths and radiation-sensitive material thicknesses therein which are far in excess of those thicknesses employed in conventional continuous coatings of the same radiation-sensitive materials.

5 While the depth of the reaction microcells can vary widely, it is generally contemplated that the depth of the reaction microcells will fall within the range of from about 1 to 1000 microns in depth or more. For exceptional radiation-sensitive 10 materials, such as vacuum vapor deposited silver halides, conventional coating thicknesses are typically in the range from 40 to 200 nanometers, and very shallow microcells of a depth of 0.5 micron or less can be employed. In one preferred form, the 15 depth of the reaction microcells is in the range of from about 5 to 20 microns. This is normally sufficient to permit a maximum density to be generated within the area subtended by the reaction microcell corresponding to the maximum density 20 obtainable with continuously coated radiation-sensitive materials of conventional thicknesses, such as silver halide emulsions containing conventional addenda, including dye image-producing components. These preferred depths of the reaction microcells 25 are also well suited to applications where the radiation-sensitive material is intended to fill the entire reaction microcells -- e.g., to have a thickness corresponding to the depth of the reaction microcell.

30 The reaction microcells are located on the support element in a predetermined, controlled relationship to each other. The microcells are relatively spaced in a predetermined, ordered manner to form an array. It is usually desirable and most efficient to form the microcells so that they are aligned along at least one axis in the plane of the support surface. For example, microcells in the configuration of hexagons, preferred for multicolor

applications, are conveniently aligned along three support surface axes which intersect at 120° angles. It is generally preferred that the reaction microcells be positioned to form a regular pattern.

However, it is recognized that adjacent reaction microcells can be varied in spacing to permit alterations in visual effects. Generally it is preferred that adjacent reaction microcells be closely spaced, since this aids the eye in visually

10 combining adjacent image areas and facilitates obtaining higher overall maximum densities. The minimum spacing of adjacent reaction microcells is limited only by the necessity of providing intervening lateral walls in the support elements. Typical

adjacent reaction microcells are laterally spaced a distance (corresponding to lateral wall thickness) of from about 0.5 to 5 microns, although both greater and lesser spacings are contemplated.

Spacing of adjacent reaction microcells can
be approached in another way in terms of the
percentage of each pixel area subtended by the
reaction microcell. This is a function of the size
and peripheral configuration of the reaction microcell and the pixel in which it is contained.

Generally the highest percentages of pixel area subtended by reaction microcell area are achieved when the peripheral configuration of the pixel and the reaction microcell are identical, such as a hexagonal reaction microcell in a hexagonal pixel

30 (as in Figure 1A) or a square reaction microcell in a square pixel (as in Figure 7). For closely spaced patterns it is preferred that the subtended reaction microcell area account for from about 50 to 99 percent of the pixel area, most preferably from 90

to 98 percent of the pixel area. Even with microcell and pixel configurations which do not permit the closest and most efficient spacing the subtended microcell area can readily account for 50 to 80 (preferally 90) percent of the pixel area.

The photographic elements can be formed by one or a combination of support elements which, alone or in combination, are capable of reducing lateral image spread and maintaining spatial

- integrity of the pixels forming the elements. Where the photographic elements are formed by a single support element, the support element performs both of these functions. Where the photographic elements are formed by more than one support element, as in
- 10 Figures 3 and 5, for example, only one of the elements (preferably the first support elements 302 and 502) need have the structural strength to retain the desired spatial relationship of adjacent pixels. The second support elements can be formed
- of relatively deformable materials. They can, but need not, contribute appreciably to the ability of the photographic elements 300 and 500 to be handled as a unit without permanent structural deformation. Illustrative Support Materials
- The support elements of the elements of this invention can be formed of the same types of materials employed in forming conventional photographic supports. Exemplary materials are described in Research Disclosure, Vol. 176, December, 1978, Item 17643, Section XVII.

The second support elements which define the lateral walls of the reaction microcells can be selected from a variety of materials lacking sufficient structural strength to be employed alone as supports. It is specifically contemplated that the second support elements can be formed using conventional photopolymerizable or photocrosslinkable materials—e.g., photoresists. Exemplary conventional photoresists are disclosed by Arcesi et al U.S. Patents 3,640,722 and 3,748,132, Reynolds et al U.S. Patents 3,696,072 and 3,748,131, Jenkins et al

U.S. Patents 3,699,025 and '026, Borden U.S. Patent

3,737,319, Noonan et al U.S. Patent 3,748,133,

Wadsworth et al U.S. Patent 3,779,989, DeBoer U.S. Patent 3,782,938, and Wilson U.S. Patent 4,052,367. Still other useful photopolymerizable and photocrosslinkable materials are disclosed by Kosar,

- Light-Sensitive Systems: Chemistry and Application of Nonsilver Halide Photographic Processes, Chapters 4 and 5, John Wiley and Sons, 1965. It is also contemplated that the second support elements can be formed using radiation-responsive colloid composi-
- 10 tions, such as dichromated colloids--e.g.,
 dichromated gelatin, as illustrated by Chapter 2,
 Kosar, cited above. The second support elements can
 also be formed using silver halide emulsions and
 processing in the presence of transition metal ion
- complexes, as illustrated by Bissonette U.S. Patent 3,856,524 and McGuckin U.S. Patent 3,862,855. The advantage of using radiation-sensitive materials to form the second support elements is that the lateral walls and reaction microcells can be simultaneously
- defined by patterned exposure. Once formed the second support elements are not themselves further responsive to exposing radiation.

Specific illustrations of photopolymers useful in forming the second support elements (i.e., 25 the lateral walls) include bichromate sensitized systems. Such systems include a chromate such as $(NH_4)_2Cr_2O_7$ as the radiation-sensitive component and polymeric materials such as hydrophilic colloids (e.g., gelatin or gelatin deriva-30 tives more specifically described below), poly(vinyl alcohols (such as those commercially available under the trademarks Gelvatol 20/30 available from Shawiningen and Elvanol 50/42 or 72/30M available from Dupont), polyamides (such as those commercially 35 available under the trademarks Nylon 819 and 829 available from Corticelli Ind. and Elvamide 8061 commercially available from Dupont), poly(vinyl

butyral) polymers (such as those available under the

trademarks Butvar B-90 and B-98 commercially available from Monsanto). Hardeners, such as triethanolamine titanium chelate (Tyzor TE available from DuPont), can be useful. Alternatively keto-coumarin 5 sensitized systems can be employed using poly-Polyesters formed from varied proportions of materials such as 1,4-bis-(2-hydroxyethoxy)cyclohexane, diethyl succinate, diethyl 1,4-phenylenebis-(2-acrylate), a salt of dimethyl 5-(4-sulfo-10 phenoxy) isophthalate, a salt of dimethyl 5-(4-sulfocyclohexoxy)-1,3-cyclohexane dicarboxylate, and a salt of dimethyl nitridodisulfonylbis(3-benzoate) are specifically preferred. Specifically preferred sensitizers are illustrated by 3-[(7-diethylamino-

2-oxo-[1]benzopyran-3-yl)carbonyl-7-carboxy[1]benzo-pyran-2-one, sodium salt and l-methyl-3[(7,8,10,-11,12-pentahydro-2-oxo-2H,6H-[1]benzopyrano[6,7,8-y]quinolizin-3-yl)carbonyl]pyridinium fluorosulfate.

It is contemplated that the second support

elements can alternatively be formed of materials commonly employed as vehicles and/or binders in radiation-sensitive materials. The advantage of using vehicle or binder materials is their known compatibility with the radiation-sensitive

25 materials. The binders and/or vehicles can be polymerized or hardened to a somewhat higher degree than when employed in radiation-sensitive materials to insure dimensional integrity of the lateral walls which they form. Illustrative of specific binder

and vehicle materials are those described in Research Disclosure, Item 17643, cited above, Section IX. Vehicle and binder magerials are particularly useful in allowing controlled diffusion between adjacent microcells. Addenda known to be

useful in silver halide emulsion interlayers, such as scavengers, antifoggants, inhibitors, etc., can be incorporated in the vehicle materials.

It is contemplated to employ photoconductive magnetics as second support elements alone or in combination with the other lateral wall forming magnetics described above. Specific photoconductive magnetics are discussed below.

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The light transmission, absorption and reflection qualities of the support elements can be varied for different photographic applications. support elements can be substantially transparent or 10 reflective, preferably white, as are the majority of conventional photographic supports. The support elements can be reflective, such as by mirroring the reaction microcell walls. The support elements can in some applications contain dyes or pigments to 15 render them substantially light impenetrable. Levels of dye or pigment incorporation can be chosen to retain the light transmission characteristics in the thinner regions of the support elements -- e.g., in the microcell bottom wall region -- while rendering 20 the support elements relatively less light penetrable in thicker region--e.g., in the lateral wall regions between adjacent microcells. The support elements can contain neutral colorant or colorant combinations. Alternatively, the support elements . 25 can contain radiation absorbing materials which are selective to a single region of the electromagnetic spectrum--e.g., blue dyes. The support elements can contain materials which alter radiation transmission qualities, but are not visible, such as ultraviolet 30 absorbers. Where two support elements are employed in combination, the light transmission, absorption and reflection qualities of the two support elements can be the same or different. The unique advantages of varied forms of the support elements can be 35 better appreciated by reference to the illustrative embodiments described below.

Where the support elements are formed of conventional photographic support materials they can

be provided with reflective and absorbing materials · by techniques well known by those skilled in the art, such techniques being adequately illustrated in the various patents cited above in relation to 5 support materials. In addition, reflective and absorbing materials can be employed of varied types conventionally incorporated directly in radiationsensitive materials, particularly in second support elements formed of vehicle and/or binder materials 10 or using photoresists or dichromated gelatin. incorporation of relfective and absorbing materials in vehicle materials is illustrated, for example, by Research Disclosure, Item 17643, cited above, Section VIII.

15 <u>Illustrative Materials for Imaging Portions of</u> Elements

The radiation-sensitive portions of conventional silver halide photographic elements are typically coated onto a planar support surface in the form of one or more continuous layers of substantially uniform thickness. The radiation-sensitive portions of the silver halide photographic elements of this invention can be selected from among such conventional radiation-sensitive portions 25 which, when coated as one or more layers of substantially uniform thickness, exhibit the characteristics of undergoing (1) an imagewise change in optical density or mobility in response to imagewise exposure and/or photographic processing, and (2) 30 visually detectable lateral image spreading in translating an imaging exposure to a viewable form. Lateral image spreading has been observed in a wide variety of conventional photographic elements. Lateral image spread can be a product of optical 35 phenomena, such as reflection or scattering of exposing radiation; diffusion phenomena, such as lateral diffusion of radiation-sensitive and/or imaging materials in the radiation-sensitive and/or

imaging layers of the photographic elements; or, most commonly, a combination of both. Lateral image spreading is particularly common where the radiation-sensitive and/or other imaging materials are dispersed in a vehicle or binder intended to be penetrated by exposing radiation and/or processing fluids.

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The radiation-sensitive silver halide containing imaging portions of the photographic 10 elements of this invention can be of a type which contain within a single component, corresponding to a layer of a conventional silver halide photographic element, radiation-sensitive silver halide capable of directly producing or being processed to produce 15 a visible image or a combination of radiation-sensitive silver halide and imaging materials which together produce directly or upon processing a viewable image. The imaging portion can be formed alternatively of two or more components, correspond-20 ing to two or more layers of a conventional photographic element, which together contain radiationsensitive silver halide and imaging materials. Where two or more components are present, only one of the components need contail radiation-sensitive silver halide and only one of the components need be an imaging component. Further, either the radiation-sensitive silver halide containing component or the imaging component of the imaging portion of the element can be primarily responsible for lateral image spreading when conventionally coated as a continuous, substantially uniform thickness layer. In one form the radiation-sensitive silver halide containing portion can be of a type which permits a viewable image to be formed directly therein. 35 another form the image produced is not directly viewable in the element itself, but can be viewed in a separate element. For example, the image can be of a type which is viewed as a transferred image in a separate receiver element.

The radiation-sensitive silver halide containing imaging portions of the photographic elements are comprised of one or more high aspect ratio tabular grain silver halide emulsions.

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As herein defined "high aspect ratio tabular grain silver halide emulsions" are those in which the tabular grains having a thickness of less than 0.5 micrometer (or micron) and a diameter of at least 0.6 micrometer have an average aspect ratio of greater than 8:1 and account for at least 50% of the total projected area of the silver halide grains present in the emulsion.

The preferred high aspect ratio tabular grain silver halide emulsions of the present invention are those wherein the silver halide grains having a thickness of less than 0.3 micron (optimally less than 0.2 micron) and a diameter of at least 0.6 micron have an average aspect ratio of at least 12:1 and optimally at least 20:1. In a preferred form of the invention these silver halide grains satisfying the above thickness and diameter criteria account for at least 70 percent and optimally at least 90 percent of the total projected area of the silver halide grains.

25 It is appreciated that the thinner the tabular grains accounting for a given percentage of the projected area, the higher the average aspect ratio of the emulsion. Typically the tabular grains have an average thickness of at least 0.03 micron, 30 although even thinner tabular grains can in principle be employed--e.g., as low as 0.01 micron, depending on halide content. It is recognized that the tabular grains can be increased in thickness to satisfy specialized applications. For example, this invention contemplates the use of tabular grains having thicknesses up to 0.5 micron, in photographic applications in which enlargement is not normally undertaken. Grain thicknesses of up to 0.5 micron

are also discussed below for recording blue light.

(For such applications all references to 0.3 micron in reference to aspect ratio determinations should be adjusted to 0.5 micron.) However, to achieve high aspect ratios without unduly increasing grain diameters, it is normally contemplated that the tabular grains of the emulsions of this invention will have an average thickness of less than 0.3 micron.

10 The grain characteristics described above of the silver halide emulsions of this invention can be readily ascertained by procedures well known to those skilled in the art. As employed herein the term "aspect ratio" refers to the ratio of the 15 diameter of the grain to its thickness. "diameter" of the grain is in turn defined as the diameter of a circle having an area equal to the projected area of the grain as viewed in a photomicrograph or an electron micrograph of an emulsion 20 sample. From shadowed electron micrographs of emulsion samples it is possible to determine the thickness and diameter of each grain and to identify those tabular grains having a thickness of less than 0.3 micron and a diameter of at least 0.6 micron. From this the aspect ratio of each such tabular grain can be calculated, and the aspect ratios of all the tabular grains in the sample meeting the less than 0.3 micron thickness and at least 0.6 micron diameter criteria can be averaged to obtain 30 their average aspect ratio. By this definition the average aspect ratio is the average of individual tabular grain aspect ratios. In practice it is usually simpler to obtain an average thickness and an average diameter of the tabular grains having a thickness of less than 0.3 micron and a diameter of at least 0.6 micron and to calculate the average aspect ratio as the ratio of these two averages.

Whether the averaged individual aspect ratios or the

averages of thickness and diameter are used to determine the average aspect ratio, within the tolerances of grain measurements contemplated, the average aspect ratios obtained do not significantly 5 The projected areas of the tabular silver differ. halide grains meeting the thickness and diameter criteria can be summed, the projected areas of the remaining silver halide grains in the photomicrograph can be summed separately, and from the two 10 sums the percentage of the total projected area of the silver halide grains provided by the tabular grains meeting the thickness and diameter critera can be calculated.

In the above determinations a reference 15 tabular grain thickness of less than 0.3 micron was chosen to distinguish the uniquely thin tabular grains herein contemplated from thicker tabular grains which provide inferior photographic properties. A reference grain diameter of 0.6 20 micron was chosen, since at lower diameters it is not always possible to distinguish tabular and nontabular grains in micrographs. The term "projected area" is used in the same sense as the terms "projection area" and "projective area" 25 commonly employed in the art; see, for example, James and Higgins, Fundamentals of Photographic Theory, Morgan and Morgan, New York, p. 15.

In a preferred form offering a broad range of observed advantages the present invention employs 30 high aspect ratio silver bromoiodide emulsions. High aspect ratio tabular grain silver bromoiodide emulsions can be prepared by introducing into a conventional reaction microcell for silver halide precipitation equipped with an efficient stirring mechanism dispersing medium. Typically the dispersing medium initially introduced into the reaction microcell is at least about 10 percent by weight based on total weight of the dispersing medium

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present in the silver bromoiodide emulsion at the conclusion of grain precipitation. Since dispersing medium can be removed from the reaction microcell by ultrafiltration during silver bromoiodide grain precipitation, as taught by Mignot U.S. Patent 4,334,012, here incorporated by reference, it is appreciated that the volume of dispersing medium initially present in the reaction microcell can equal or even exceed the volume of the silver 10 bromoiodide emulsion present in the reaction microcell at the conclusion of grain precipitation. The dispersing medium initially introduced into the reaction microcell is preferably water or a dispersion of peptizer in water, optionally containing 15 other ingredients, such as one or more silver halide ripening agents and/or metal dopants, more specifically described below. Additional dispersing medium is added to the reaction microcell with the silver and halide salts and can also be introduced through 20 a separate jet. It is common practice to adjust the proportion of dispersing medium, particularly to increase the proportion of peptizer, after the completion of the salt introductions.

A minor portion of the bromide salt 25 employed in forming the silver bromoiodide grains is initially present in the reaction microcell to adjust the bromide ion concentration of the dispersing medium at the outset of silver bromoiodide precipitation. Also, the dispersing medium in the 30 reaction microcell is initially substantially free of iodide ions. As employed herein, the term "substantially free of iodide ions" as applied to the contents of the reaction microcell means that there are insufficient iodide ions present as 35 compared to bromide ions to precipitate as a separate silver iodide phase. It is contemplated to maintain the pBr of the reaction microcell initially in the range of from at or below 1.6 to at or above

0.6. In the absence or diminished presence of a peptizer such as gelatin higher initial pBr levels can be employed. (As herein employed, pBr is defined as the negative logarithm of bromide ion concentration. pH, pCl, pI, and pAg are similarly defined for hydrogen, chloride, iodide, and silver ion concentrations, respectively.)

During precipitation silver, bromide, and iodide salts are added to the reaction microcell by 10 techniques well known in the precipitation of silver bromoiodide grains. Typically an aqueous silver salt solution of a soluble silver salt, such as silver nitrate, is introduced into the reaction microcell concurrently with the introduction of the 15 bromide and iodide salts. The bromide and iodide salts are also typically introduced as aqueous salt solutions, such as aqueous solutions of one or more soluble ammonium, alkali metal (e.g., sodium or potassium), or alkaline earth metal (e.g., magnesium 20 or calcium) halide salts. The silver salt is at least initially introduced into the reaction microcell separately from the iodide salt. The iodide and bromide salts can be added to the reaction microcell separately or as a mixture.

It is possible to increase the permissible latitude of pBr during concurrent introduction of silver, bromide, and iodide salts. Raising pBr values above 2.2 during tabular grain growth results in thickening of the grains, but can be tolerated in many instances while still realizing an average aspect ratio of greater than 8:1.

As an alternative to the introduction of silver, bromide, and iodide salts as aqueous solutions, it is specifically contemplated to introduce the silver, bromide, and iodide salts, initially or in the growth stage, in the form of fine silver halide grains suspended in dispersing medium. The grains are sized so that they are readily Ostwald

ripened onto larger grain nuclei, if any are present, once introduced into the reaction microcell. The maximum useful grain sizes will depend on the specific conditions within the reaction microcell, such as temperature and the presence of solubilizing and ripening agents. Silver bromide, silver iodide, and/or silver bromoiodide grains can be introduced. (Since bromide and/or iodide are precipitated in preference to chloride, it is also possible to employ silver chlorobromide and silver chlorobromoiodide grains.) The silver halide grains are preferably very fine.

Subject to the pBr requirements set forth above, the concentrations and rates of silver, 15 bromide, and iodide salt introductions can take any convenient conventional form. The silver and halide salts are preferably introduced in concentrations of from 0.1 to 5 moles per liter, although broader conventional concentration ranges, such as from 0.01 20 mole per liter to saturation, for example, are contemplated. Specifically preferred precipitation techniques are those which achieve shortened precipitation times by increasing the rate of silver and halide salt introduction during the run. The 25 rate of silver and halide salt introduction can be increased either by increasing the rate at which the dispersing medium and the silver and halide salts are introduced or by increasing the concentrations of the silver and halide salts within the dispersing 30 medium being introduced. It is specifically preferred to increase the rate of silver and halide salt introduction, but to maintain the rate of introduction below the threshhold level at which the formation of new grain nuclei is favored -- i.e., to avoid 35 renucleation, as taught by Irie U.S. Patent 3,650,757, Kurz U.S. Patent 3,672,900, Saito U.S. Patent 4,242,445, Wilgus German OLS 2,107,118, Teitscheid et al European Patent Application

80102242, and Wey "Growth Mechanism of AgBr Crystals in Gelatin Solution", Photographic Science and Engineering, Vol. 21, No. 1, January/February 1977, p. 14, et. seq. By avoiding the formation of

- additional grain nuclei after passing into the growth stage of precipitation, relatively monodispersed tabular silver bromoiodide grain populations can be obtained. Emulsions having coefficients of variation of less than about 30 percent can be
- prepared. (As employed herein the coefficient of variation is defined as 100 times the standard deviation of the grain diameter divided by the average grain diameter.) By intentionally favoring renucleation during the growth stage of precipita-
- tion, it is, of course, possible to produce polydispersed emulsions of substantially higher coefficients of variation. To reduce the coefficient of variation of tabular grains it is preferred to increase pBr, either gradually or abruptly, such as
- 20 by the gradual or abrupt separate addition of dispersing medium early in the precipitation.

The concentration of iodide in the silver bromoiodide emulsions can be controlled by the introduction of iodide salts. Any conventional

- iodide concentration can be employed. Even very small amounts of iodide--e.g., as low as 0.05 mole percent--are recognized in the art to be beneficial. In their preferred form the emulsions of the present invention incorporate at least about 0.1
- mole percent iodide. Silver iodide can be incorporated into the tabular silver bromoiodide grains up to its solubility limit in silver bromide at the temperature of grain formation. Thus, silver iodide concentrations of up to about 40 mole percent in the tabular silver bromoiodide grains can be achieved at
- 35 tabular silver bromoiodide grains can be achieved at precipitation temperatures of 90°C. In practice precipitation temperatures can range down to near ambient room temperatures--e.g., about 30°C. It is

generally known in the art to optimize iodide concentrations for the specific photographic application.

The relative proportion of iodide and bromide salts introduced into the reaction microcell during precipitation can be maintained in a fixed ratio to form a substantially uniform iodide profile in the tabular silver bromoiodide grains or varied, as by increasing the proportion of iodide in annular 10 or otherwise laterally displaced regions of high aspect ratio tabular grain silver bromoiodide emulsions as compared to central regions of the tabular grains. In a variant form it is specifically contemplated to terminate iodide or bromide 15 and iodide salt addition to the reaction microcell prior to the termination of silver salt addition so that excess halide reacts with the silver salt. This results in a shell of silver bromide being formed on the tabular silver bromoiodide grains. 20 Thus, it is apparent that the tabular silver bromoiodide grains of the present invention can exhibit substantially uniform or graded iodide concentration profiles and that the gradation can be controlled, as desired, to favor higher iodide concentrations

as desired, to favor higher iodide concentrations
25 internally or at or near the surfaces of the tabular silver bromoiodide grains.

High aspect ratio tabular grain silver bromide emulsions lacking iodide can be prepared by the process described above modified to exclude iodide. High aspect ratio tabular grain silver bromide emulsions can alternatively be prepared following procedures previously taught in the art.

The tabular grain silver bromide and bromoiodide emulsions of this invention typically contain {111} crystal planes. Silver bromide tabular grains which appear square or rectangular in projected area have been prepared by ripening seed grains in the substantial absence of nonhalide

silver ion complexing agents in the pAg range of from 5.0 to 8.0. Such tabular grains are believed to be bounded by {100} crystal faces. The tabular grain silver bromide and silver bromoiodide emulsions of this invention can contain tabular grains bounded by {100}, {110}, and {111} crystal faces, and the selection of grain crystal faces can be controlled by selection of grain precipitation and growth conditions.

Certain of the advantages achieved in the practice of this invention, are independent of the halide content of the high aspect ratio tabular grain emulsions. A process of preparing tabular silver chloride grains which are substantially internally free of both silver bromide and silver iodide employs a double-jet precipitation process wherein chloride and silver salts are concurrently introduced into a reaction microcell containing dispersing medium in the presence of ammonia.

20 During chloride salt introduction the pag within the

During chloride salt introduction the pAg within the dispersing medium is in the range of from 6.5 to 10 and the pH in the range of from 8 to 10. The presence of ammonia at higher temperatures tends to cause thick grains to form, therefore precipitation temperatures are limited. The process can be optimized to produce high aspect ratio tabular grain silver chloride emulsions.

A process of preparing tabular grains of at least 50 mole percent chloride having opposed

30 crystal faces lying in {111} crystal planes and, in one preferred form, at least one peripheral edge lying parallel to a <211> crystallographic vector in the plane of one of the major surfaces can be practiced by reacting aqueous silver and

35 chloride-containing halide salt solutions in the presence of a crystal habit modifying amount of an amino-substituted azaindene and a peptizer having a thioether linkage.

halide grains contain chloride and bromide in at least annular grain regions and preferably throughout are contemplated. The tabular grain regions containing silver, chloride, and bromide are formed by maintaining a molar ratio of chloride and bromide ions of from 1.6:1 to about 260:1 and the total concentration of halide ions in the reaction microcell in the range of from 0.10 to 0.90 normal during introduction of silver, chloride, bromide, and, optionally, iodide salts into the reaction microcell. The molar ratio of silver chloride to silver bromide in the tabular grains can range from 1:99 to 2:3.

2:3. 15 High aspect ratio tabular grain emulsions useful in the practice of this invention can have extremely high average aspect ratios. Tabular grain average aspect ratios can be increased by increasing average grain diameters. This can produce sharpness 20 advantages, but maximum average grain diameters are generally limited by granularity requirements for a specific photographic application. Tabular grain average aspect ratios can also or alternatively be increased by decreasing average grain thicknesses. 25 When silver coverages are held constant, decreasing the thickness of tabular grains generally improves granularity as a direct function of increasing aspect ratio. Hence the maximum average aspect ratios of the tabular grain emulsions of this 30 invention are a function of the maximum average grain diameters acceptable for the specific photographic application and the minimum attainable tabular grain thicknesses which can be produced. Maximum average aspect ratios have been observed to 35 vary, depending upon the precipitation technique employed and the tabular grain halide composition. The highest observed average aspect ratios, 500:1,

for tabular grains with photographically useful

average grain diameters, have been achieved by

Ostwald ripening preparations of silver bromide
grains, with aspect ratios of 100:1, 200:1, or even
higher being obtainable by double-jet precipitation

procedures. The presence of iodide generally
decreases the maximum average aspect ratios
realized, but the preparation of silver bromoiodide
tabular grain emulsions having average aspect ratios
of 100:1 or even 200:1 or more is feasible. Average
aspect ratios as high as 50:1 or even 100:1 for
silver chloride tabular grains, optionally containing bromide and/or iodide, can be prepared as taught
above.

Modifying compounds can be present during

15 tabular grain precipitation. Such compounds can be initially in the reaction microcell or can be added along with one or more of the salts according to conventional procedures. Modifying compounds, such as compounds of copper, thallium, lead, bismuth,

20 cadmium, zinc, middle chalcogens (i.e., sulfur, selenium, and tellurium), gold, and Group VIII noble metals, can be present during silver halide precipitation, as illustrated by Arnold et al U.S. Patent 1,195,432, Hochstetter U.S. Patent 1,951,933,

25 Trivelli et al U.S. Patent 2,448,060, Overman U.S.

- Trivelli et al U.S. Patent 2,448,060, Overman U.S. Patent 2,628,167, Mueller et al U.S. Patent 2,950,972, Sidebotham U.S. Patent 3,488,709, Rosecrants et al U.S. Patent 3,737,313, Berry et al U.S. Patent 3,772,031, Atwell U.S. Patent No.
- 4,269,927, and Research Disclosure, Vol. 134, June 1975, Item 13452. Research Disclosure and its predecessor, Product Licensing Index, are publications of Industrial Opportunities Ltd.; Homewell, Havant; Hampshire, PO9 1EF, United Kingdom. The
- 35 tabular grain emulsions can be internally reduction sensitized during precipitation, as illustrated by Moisar et al, <u>Journal of Photographic Science</u>, Vol. 25, 1977, pp. 19-27.

Features of the high aspect ratio tabular grain emulsions not specifically described above can take conventional forms. Conventional silver halide emulsion preparation, washing, sensitization, and addenda features are described, for example, in Research Disclosure, Item 17643, cited above, particularly Sections I through VII, IX, and X.

The foregoing description of specific radiation-sensitive portions of the photographic elements of this invention is recognized to be illustrative only of the varied known photographic materials which can be employed. Similarly the uses and advantages of the photographic elements according to this invention will be apparent and can be generally appreciated from the following illustrative description directed to certain preferred silver halide emulsion photographic elements and their use.

Silver Imaging With Silver Halides

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20 The photographic elements can be imagewise exposed with various forms of energy, which encompass the ultraviolet and visible (e.g., actinic) and infrared regions of the electromagnetic spectrum as well as electron beam and beta radiation, gamma ray, 25 X-ray, alpha particle, neutron radiation and other forms of corpuscular and wave-like radiant energy in either noncoherent (random phase) forms or coherent (in phase) forms, as produced by lasers. Exposures can be monochromatic, orthochromatic or panchro-30 Imagewise exposures at ambient, elevated or reduced temperatures and/or pressures, including high or low intensity exposures, continuous or intermittent exposures, exposure times ranging from minutes to relatively short durations in the milli-35 second to microsecond range and solarizing exposures, can be employed within the useful response ranges determined by conventional sensitometric techniques, as illustrated by T. H. James, The

Theory of the Photographic Process, 4th Ed., Macmillan, 1977, Chapters 4, 6, 17, 18 and 23.

Referring to photographic element 100 in Figures 1A and 1B, in a simple, illustrative form of 5 this invention the support 102 is formed of a reflective material, preferably and hereinafter referred to as a white reflective material, although colored reflective materials are contemplated. radiation-sensitive material 116 is a silver halide 10 emulsion of the type which is capable of producing a viewable image as a result solely of exposure and, optionally, dry processing. Such silver halide emulsions can be of the printout type--that is, they can produce a visible image by the direct action of 15 light with no subsequent action required--or of the direct-print type--that is, they can form a latent image by high intensity imagewise exposure and produce a visible image by subsequent low intensity light exposure. A heat stabilization step can be 20 interposed between the exposure steps. In still another form the silver halide emulsion can be of a type which is designed for processing solely by heat.

The preferred printout emulsions are illustrated by Research Disclosure, Item 17643, Section XXVI: the direct print emulsions by Section XVII, and the heat processing emulsion by Section Photothermographic silver halide systems that are useful are also described in greater detail in Research Disclosure, Vol. 170, June 1978, Item 17029.

It is recognized that silver halide photographic elements can exhibit lateral image spreading solely as a result of lateral reflection of exposing radiation from beneath an emulsion layer. Lateral image spreading of this type is referred to in the 35 art as halation, since the visual effect can be to produce a halo around a bright object, such as an electric lamp, which is photographed. Other objects which are less bright are not surrounded by halos,



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but their photographic definition is significantly reduced by the reflected radiation. To overcome this difficulty conventional photographic elements commonly are provided with layers, commonly referred to as antihalation layers, of light absorbing 5 materials on a support surface which would otherwise reflect radiation to produce halation in an emulsion layer. Such antihalation layers are commonly recognized to have the disadvantage that they must 10 be entirely removed from the photographic element prior to viewing in most practical applications. A more fundamental disadvantage of antihalation layers which is not generally stated, since it is considered inescapable, is that the radiation which 15 is absorbed by the antihalation layer cannot be available to expose the silver halide grains within the emulsion.

Another approach to reducing lateral image spreading attributable to light scatter in silver 20 halide emulsions is to incorporate intergrain absorbers. Dyes or pigments similar to those described above for incorporation in the second support elements are commonly employed for this purpose. The disadvantage of intergrain absorbers 25 is that they significantly reduce the photographic speed of silver halide emulsions. They compete with the silver halide grains in absorbing photons, and many dyes have a significant desensitizing effect on silver halide grains. Like the absorbing materials 30 in antihalation layers, it is also necessary that the intergrain absorbers be removed from the silver halide emulsions for most practical applications, and this can also be a significant disadvantage.

Another approach herein suggested is to

35 coat a high aspect ratio tabular grain or conventional silver halide emulsion on a support as one or more continuous layers. The emulsion layer or layers can thereafter be exposed through a mask,

thereby achieving exposure in a pattern corresponding to a pattern of microcell walls. Development of the exposed silver halide lying in areas corresponding to microcell walls results in the development of 5 silver which in turn increases the density of these microcell wall forming regions. Upon subsequent imagewise exposure of the emulsion layer or layers - radiation that would otherwise be scattered laterally is intercepted by the developed silver in the 10 microcell wall forming regions. In this instance the microcell walls are capable of intercepting laterally deflected exposing radiation, but remain laterally permeable to the lateral migration of incorported addenda or processing materials. 15 migration of materials between developing and nondeveloping areas can occur. Migration between developing and nondeveloping areas can achieve useful photographic effects, such as edge effects, often employed to improve sharpness. In the 20 instance in which a dye image is formed, after imagewise exposure developed silver forming increased density in a microcell wall pattern as well as silver developed as a result of imagewise exposure can be removed by bleaching. By bleaching no microcell wall pattern may be distinguishable in the finally processed element.

When light strikes the photographic element 100 so that it enters one of the microcells 108, a portion of the light can be absorbed immediately by the silver halide grains of the emulsion 116 while the remaining light traverses the reaction microcell without being absorbed. If a given photon penetrates the emulsion without being absorbed, it will be redirected by the white bottom wall 114 of the support 102 so that the photon again traverses at least a portion of the reaction microcell. This presents an additional opportunity for the photon to strike and be absorbed by a silver halide grain.

Since it is recognized that the average photon strikes several silver halide grains before being absorbed, at least some of the exposing photons will be laterally deflected before they are absorbed by 5 silver halide. The white lateral walls 110 of the support act to redirect laterally deflected photons so that they again traverse a portion of the silver halide emulsion within the same reaction microcell. This avoids laterally directed photons being 10 absorbed by silver halide in adjacent reaction microcells. Whereas, in a conventional silver halide photographic element having a continuous emulsion coating on a white support, redirection of photons back into the emulsion by a white support is achieved only at the expense of significant lateral image spreading -- e.g., halation, in the photographic element 100 the white support enhances the opportunity for photon absorption by the emulsion contained within the reaction microcells while at 20 the same time achieving a visually acceptable predefined limit on lateral image spread. result can be seen photographically both in terms of improved photographic speed and contrast as well as sharper image definition. Thus, the advantages 25 which can be gained by employing antihalation layers and intergrain absorbers in conventional photographic elements are realized in the photographic elements of the present invention without their use and with the additional surprising advantages of 30 speed and contrast increase. Further, none of the disadvantages of antihalation layers and intergrain absorbers are encountered. For reasons which will become more apparent in discussing other forms of this invention, it should be noted, however, that 35 the photographic elements of the present invention can employ antihalation layers and intergrain absorbers, if desired, while retaining distinct advantages.

Most commonly silver halide photographic elements are intended to be processed using aqueous alkaline liquid solutions. When the silver halide emulsion contained in the reaction microcell 108 of the element 100 is of a developing out type rather than a dry processed printout, direct-print or thermally processed type, as illustrated above, all of the advantages described above are retained. addition, having the emulsion within reaction microcells offers protection against lateral image spreading as a result of chemical reactions taking place during processing. For example, microscopic inspection of silver produced by development reveals filaments of silver. The silver image in emulsions 15 of the developing out type can result from chemical (direct) development in which image silver is provided by the silver halide grain at the site of silver formation or from physical development in which silver is provided from adjacent silver halide 20 grains or silver or other metal is provided from other sources. Opportunity for lateral image spreading in the absence of reaction microcells is particularly great when physical developmen: is occurring. Even under chemical development condi-25 tions, such as where development is occurring in the presence of a silver halide solvent, extended silver filaments can be found. Frequently a combination of chemical and physical development occurs curing processing. Having the silver developed confined 30 within the reaction microcells circumscribes the areal extent of silver image spreading. specifically contemplated to dedicate a portion of the microcells to developing agent or other addenda, if desired. For example, by dedicating a few 35 recurring microcells in an array so that they contain developing agent, an activating solution can be used for processing. Other uses of dedicated microcells are, of course, possible.

The light-sensitive silver halide contained in the photographic elements can be processed following exposure to form a visible image by conventional means, as illustrated in Research Disclosure, Item 17643, cited above, Sections XIX and XX.

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In one specifically preferred form of the invention the photographic element is infectiously developed. The term "infectious" is employed in the 10 art to indicate that silver halide development is not confined to the silver halide grain which provides the latent image site. Rather, adjacent grains which lack latent image sites are also developed because of their proximity to the 15 initially developable silver halide grain.

Infectious development of continuously coated silver halide emulsion layers is practiced in the art principally in producing high contrast photographic images for exposing lithographic plates. However, care must be taken to avoid unacceptable lateral image spreading because of the infectious development. In practicing the present invention the reaction microcells provide boundaries limiting lateral image spread. Since the microcells control lateral image spreading, the infectiousness or tendency of the developer to laterally spread the image can be as great and is, preferably, greater than in conventional infectious developers. fact, one of the distinct advantages of infectious 30 development is that it can spread or integrate silver image development over the entire area of the reaction microcell. This avoids silver image graininess within the reaction microcell and permits the reaction microcell to be viewed externally as a 35 uniform density unit rather than a circumscribed area exhibiting an internal range of point densities.

The combination of reaction microcells and infectious development permits unique imaging

results. For example, very high densities can be obtained in reaction microcells in which development occurs, since the infectious nature of the development drives the development reaction toward comple-5 tion. At the same time, in other reaction microcells where substantially no development is initiated, very low density levels can be maintained. The result is a very high contrast photographic image. It is known in the art to read out 10 photographic images electronically by scanning a photographic element with a light source and a photosensor. The density sensed at each scanning location on the element can be recorded electronically and reproduced by conventional means, such as 15 a cathode ray tube, on demand. It is well known also that digital electronic computers employed in recording and reproducing the information taken from the picture employ binary logic. In electronically scanning the photographic element 100, each reaction 20 microcell can provide one scanning site. By using infectious development to produce high contrast, the photographic image being scanned provides either a substantially uniform dark area or a light area in each reaction microcell. In other words, the 25 information taken from the photographic element is already in a binary logic form, rather than an analog form produced by continuous tone gradations. The photographic elements are then comparatively simple to scan electronically and are very simple 30 and convenient to record and reproduce using digital electronic equipment.

Techniques for infectious development as well as specific compositions useful in the practice of this invention are disclosed by James, The Theory of the Photographic Process, 4th Ed., Macmillan, pp. 420 and 421 (1977); Stauffer et al, Journal Franklin Institute, Vol. 238, p. 291 (1944); and Beels et al, Journal Photographic Science, Vol. 23, p. 23

(1975). In a preferred form a hydrazine or hydrazide is incorporated in the reaction microcell and/or in a developer and the developer containing a developing agent having a hydroxy group, such as a hydroquinone. Preferred developers of this type are disclosed in Stauffer et al U.S. Patent 2,419,974, Trivelli et al U.S. Patent 2,419,975 and Takada et al Belgian Patent 855,453.

The foregoing discussion of the use and
advantages of the photographic element 100 has been
by reference to preferred forms in which the support
102 is a white, reflection print. It can be used to
form an image to be scanned electronically as has
been described above. The element in this form can
be used also as a master for reflection printing.

It is also contemplated that the support 102 can be transparent. In one specifically preferred form the underlying portion 112 of the support is transparent and colorless while the integral

lateral walls contain a colorant therein, such as a dye, so that a substantial density is presented to light transmission through the lateral walls between the major surfaces 104 and 106 and between adjacent reaction microcells. In this form, the dyed walls

perform the function of an intergrain absorber or antihalation layer, as described above, while avoiding certain disadvantages which these present. For example, since the dye is in the lateral walls and not in the emulsion, dye desensitization of the silver halide emulsion is minimized, if not elimi-

silver halide emulsion is minimized, it not eliminated. At the same time, it is unnecessary to
decolorize or remove the dye, as is normally undertaken when an antihalation layer is provided.

In addition, this form of the support
35 element 102 has unique advantages in use that have
no direct counterpart in photographic elements
having continuous silver halide emulsion layers.
The photographic element when formed with a trans-

parent underlying portion and dyed lateral walls is uniquely suited for use as a master in transmission printing. That is, after processing to form a photographic image, the photographic element can be 5 used to control exposure of a photographic print element, such as a photographic element according to this invention having a white support, as described above, or a conventional photographic element, such as a photographic paper. In exposing the print 10 element through the image bearing photographic element 100 the density of the lateral walls confines light transmission during exposure to the portions of the support 102 underlying the reaction microcells. Where the reaction microcells are 15 relatively transparent -- i.e., minimum density areas, the print exposure is higher and in maximum density areas of the master, print exposure is lowest. effect is to give a print in which highly exposed areas of the print element are confined to dots or 20 spaced microareas. Upon subsequent processing to form a viewable print image the eye can fuse adjacent dots or micro-areas to give the visual effect of a continuous tone image. The effects of the nontransmission of exposing light through the 25 lateral walls has been adequately described further above in connection with the support elements and the materials from which they can be formed. the eye is quite sensitive to small differences in minimum density, it is generally preferred that the lateral walls be substantially opaque. However, it is contemplated that some light can be allowed to penetrate the lateral walls during printing. can have the useful effect, for instance, of bringing up the overall density in the print image. As mentioned above, it is also contemplated to displace the print element with respect to the master during printing so that a continuous print image is produced and any reduced density effect due to

reduced transmission through the lateral walls is entirely avoided. Similarly, when the photographic element in this form is used to project an image, the lateral spreading of light during projection will fuse adjacent microcell areas so that the lateral walls are not seen.

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To illustrate still another variant form of the invention, advantages can be realized when the support element is entirely transparent and color-10 less. In applications where the silver halide emulsion is a developing out emulsion and is intended to be scanned pixel by pixel, as in the infectiously developed electron beam scanned application described above, control of lateral image 15 spreading during development is, of course, independent of the transparency or coloration of the support element. However, even when the lateral walls are transparent and colorless, the protection against light scattering between adjacent microcells 20 can still be realized in some instances, as discussed below in connection with photographic element 200.

The photographic elements 200 through 1000 share structural similarities with photographic elements 100 and are similar in terms of both uses and advantages. Accordingly, the uses of these elements are discussed only by reference to differences which further illustrate the invention.

The photographic element 200 differs from the element 100 in that the reaction microcells 208 have curved walls rather than separate bottom and side walls. This wall configuration is more convenient to form by certain fabrication techniques. It also has the advantage of being more efficient in redirecting exposing radiation back toward the center of the reaction microcell. For example, when the photographic element 200 is exposed from above (in the orientation shown), light striking the

curved walls of the reaction microcells can be reflected inwardly so that it again traverses the emulsion 216 contained in the microcell. When the support is transparent and the element is exposed from below, a higher refraction index for the emulsion as compared to the support can cause light to bend inwardly. This directs the light toward the emulsion 216 within the microcell and avoids scattering of light to adjacent microcells.

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10 A second significant difference in the construction of the photographic element 200 as compared to the photographic element 100 is that the upper surface of the emulsion 216 lies substantially below the second major surface 206 of the support 15 202. The recessed position of the emulsion within the support provides it with mechanical protection against abrasion, kinking, pressure induced defects and matting. Although the emulsion up to the second major surface 106, it also affords protection for 20 the emulsion 116. In all forms of the photographic elements of this invention, at least one component of the radiation-sensitive portion of the element is contained within the reaction microcells and additional protection is afforded against at least 25 abrasion. It is specifically contemplated that the lateral walls of the support can perform the function of matting agents and that these agents can therefore be omitted without encountering disadvantages to use, such as blocking. However, conven-30 tional matting agents, such as illustrated by Research Disclosure, Item 17643, cited above, Section XVI, can be employed, particularly in those forms of the photographic elements more specifically discussed below containing at least one continuous 35 hydrophilic colloid layer overlying the support and

The photographic element 300 differs from photographic element 100 in two principal respects.

the reaction microcells thereof.

First, relatively thin extensions 314 of emulsion can extend between and connect adjacent pixels. Second, the support is made up of two separate support elements 302 and 306. The photographic element 300 can be employed identically as photographic element 100. The imaging effect of the extensions 314 are in most instances negligible and can be ignored in use. In the form of the element 300 in which the first support element 302 is 10 transparent and the second support element 308 is substantially light impenetrable exposure of the element through the first support element avoids exposure of the extensions 314. Where the emulsion is negative-working, this results in no silver 15 density being generated between adjacent reaction microcells. Where the extensions are not of negligible thickness and no steps are taken to avoid their exposure, the performance of the photographic element combines the features of a continuously 20 coated silver halide emulsion layer and an emulsion contained within a reaction microcell.

The photographic element 400 differs from photographic element 100 in two principal respects. First, the reaction microcell 408 is of relatively extended depth as compared with the reaction microcells 108, and, second, the radiation-sensitive portion of the element is divided into two separate components 416 and 418. These two differences can be separately employed. That is, the photographic element 100 could be modified to provide a second component like 418 overlying the second major surface 106 of the support, or the depth of the reaction microcells could be increased. These two differences are shown and discussed together, since in certain preferred embodiments they are particularly advantageous when employed in combination.

While silver halide absorbs light, many photons striking a silver halide emulsion layer pass

through without being absorbed. Where the exposing radiation is of a more energetic form, such as X-rays, the efficiency of silver halide in absorbing the exposing radiation is even lower. While

- increasing the thickness of a silver halide emulsion layer increases its absorption efficiency, there is a practical limit to the thickness of silver halide emulsion layers, since thicker layers cause more lateral scattering of exposing radiation and
- 10 generally result in greater lateral image spreading.

In a preferred form a radiation-sensitive silver halide emulsion forms the component confined within the reaction microcell 408. Thus lateral spreading is controlled not by the thickness of the 15 silver halide or the depth of the microcell, but by the lateral walls of the microcell. It is then possible to extend the depth of the microcell and the thickness of the silver halide emulsion that is presented to the exposing radiation as compared to 20 the thickness of continuously coated silver halide emulsion layers without encountering a penalty in terms of lateral image spreading. For example, the depth of the reaction microcells and the thickness of the silver halide emulsion can both be substan-25 tially greater than the width of the microcells. In

25 tially greater than the width of the microcells. In the case of a radiographic element intended to be exposed directly by X-rays it is then possible to provide relatively deep reaction microcells and to improve the absorption efficiency--i.e., speed, of 30 the radiographic element. As discussed above,

the radiographic element. As discussed above, microcell depths and silver halide emulsion thicknesses can be up to 1000 microns or more. Microcell depths of from about 20 to 100 microns preferred for this application are convenient to form by the same general techniques employed in forming shallower

35 general techniques employed in forming shallower microcells.

In one preferred form, the component 418 is an internally fogged silver halide emulsion. In

this form, the components 416 and 418 can correspond to the surface-sensitive and internally fogged emulsions, respectively, disclosed by Luckey et al U.S. Patents 2,996,382, 3,397,987 and 3,705,858;

- Luckey U.S. Patent 3,695,881; Research Disclosure,
 Vol. 134, June 1975, Item 13452; Millikan et al
 Defensive Publication T-0904017, April 1972 and Kurz
 Research Disclosure, Vol. 122, June 1974, Item
 12233. In a preferred form, the surface-sensitive
- 10 silver halide emulsion contains at least 1 mole percent iodide, typically from 1 to 10 mole percent iodide, based on total halide present as silver halide. The surface-sensitive silver halide is preferably a silver bromoiodide and the internally
- 15 fogged silver halide is an internally fogged converted-halide which is at least 50 mole percent bromide and up to 10 mole percent iodide (the remaining halide being chloride) based on total halide. Upon exposure and development of the iodide
- containing surface-sensitive emulsion forming the component 416 with a surface developer, a developer substantially incapable of revealing an internal latent image (quantitatively defined in the Luckey et al patents), iodide ions migrate to the component
- 418 and render the internally fogged silver halide grains developable by the surface developer. In unexposed pixels surface-sensitive silver halide is not developed, therefore does not release iodide ions, and the internally fogged silver halide
- omulsion component in these pixels cannot be developed by the surface developer. The result is that the silver image density produced by the radiation-sensitive emulsion component 416 is enhanced by the additional density produced by the
- development of the internally fogged silver halide grains without any significant effect on minimum density areas. It is, of course, unnecessary that the component 416 be of extended thickness in order

to achieve an increase in density using the component 418, but when both features are present in combination a particularly fast and efficient photographic element is provided which is excel-

lently suited to radiographic as well as other photographic applications. In variant forms of the invention the surface-sensitive and internally fogged emulsions can be blended rather than coated in separate layers. When blended, it is preferred that the emulsions be located entirely within the

reactive microcells.

In one preferred form of the photographic element 500, the first support element 502 is both transparent and colorless. The second support element 508 is relatively deformable and contains a dye, such as a yellow dye. The components 516 and 518 can correspond to the surface-sensitive and internally fogged silver halide emulsion components 416 and 418, respectively, described above. For this specific embodiment only, the spectral sensitivity of the surface-sensitive emulsion is limited to the blue region of the visible spectrum. The layer 515 can be one or a combination of transparent, colorless conventional subbing layers.

25 Conventional subbing layers and materials are disclosed in the various patents cited above in connection with conventional photographic support materials.

In one exemplary use the radiation-sensitive emulsion component 516 can be exposed through
the transparent first support element 502 and the
underlying portion 512 of the second support element
508. While the second support element contains a
dye to prevent lateral light scattering through the
lateral walls 510, the thickness of the underlying
portion of the second support element is sufficiently thin that it offers only negligible absorption of incident light. As another alternative the

element in this form can be exposed through the second emulsion component 518 instead of the support, if desired.

In an alternative form of the photographic 5 element 500 the emulsion component 516 can correspond to the emulsion component 418 and the emulsion component 518 can correspond to the emulsion compo-In this form the radiation-sensitive nent 416. silver halide emulsion is coated as a continuous 10 layer while the internally fogged silver halide emulsion is present in the microcell 514. Exposure through the support exposes only the portion of the radiation-sensitive emulsion component 518 overlying the microcell, since the dye in the lateral walls 15 510 of the second support element effectively absorbs light while the underlying portion 512 of the second support element is too thin to absorb light effectively. Lateral image spreading in the continuous emulsion component is controlled by 20 limiting its exposure to the area subtended by the microcell. Lateral image spreading by the internally fogged emulsion is limited by the walls of the microcell.

In still another form of the photographic 25 element 500 the first and second support elements can be formed from any of the materials, including colorless transparent, white and absorbing materials. The layer 515 can be chosen to provide a reflective surface, such as a mirror surface. 30 example, the layer 515 can be a vacuum vapor deposited layer of silver or another photographically compatible metal which is preferably overcoated with a thin transparent layer, such as a hydrophilic colloid or a film-forming polymer. The 35 components 516 and 518 correspond to the components 416 and 418, respectively, so that the only radiation-sensitive material is confined within the

microcell 514.

In exposing the element in this form from the emulsion side the reflective surface redirects light within the microcell so that light is either absorbed by the emulsion component 516 on its first pass through the microcell or is redirected so that it traverses the microcell one or more additional times, thereby increasing its chances of absorp-Upon development image areas appear as dark areas on a reflective background. If a dye image is 10 produced, as discussed below, the developed silver and silver mirror can be concurrently removed by bleaching so that a dye image on a typical white reflective or colorless transparent support is produced.

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15 A very high contrast photographic element can be achieved by employing as layer 515 a reactive material, such as a metal or metal compound capable of forming a high density metal sulfide -- e.g., silver oxide, thereby selectively converting the 20 reflecting surface within the reaction microcells to a light absorbing form. For instance, if a developer inhibitor releasing (DIR) coupler of the type which releases an organic sulfide is incorporated in the emulsion within the reaction microcells 25 and development is undertaken with a color developing agent, the color developing agent can react with exposed silver halide to form silver and oxidized color developing agent. The oxidized color developing agent can then couple with the DIR coupler to 30 release an organic sulfide which is capable of reacting with oxidized silver provided by the reactive material layer 515 in the microcells to convert silver oxide to a black silver sulfide. This increases the maximum density obtainable in the 35 microcells while leaving the reactive material unaffected in minimum density areas. increased contrast can be achieved by this approach. Specific DIR couplers and color developing agents are described below in connection with dye imaging. Metals and metal compounds other than silver oxide which will react with the released organic sulfide to form a metal sulfide can be alternatively employed.

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In the foregoing discussion of elements 400 and 500 two component radiation-sensitive means 416 and 418 or 516 and 518 are described in which the components work together to increase the maximum 10 density obtainable. In another form the components can be chosen so that they work together to minimize the density obtained in areas where silver halide is the radiation-sensitive component developed. For example, if one of the components is a light-sensi-15 tive silver halide emulsion which contains a DIR coupler and the other component is a spontaneously developable silver halide emulsion (e.g., a surface or internally fogged emulsion) imagewise exposure and processing causes the light-sensitive emulsion 20 to begin development as a function of light exposure. As this emulsion is developed it produces oxidized developing agent which couples with the DIR coupler, releasing development inhibitor. The inhibitor reduces further development of adjacent portions of the otherwise spontaneously developable emulsion. The spontaneously developable emulsion develops to a maximum density in areas where development inhibitor is not released. By using a relatively low covering power light-sensitive 30 emulsion (e.g., a relatively coarse, high-speed emulsion) and a high covering power spontaneously developable emulsion, it is possible to obtain images of increased contrast. The DIR coupler can be advantageously coated in the microcells or as a 35 continuous layer overlying the microcells along with the radiation-sensitive emulsion, and the spontaneously developable emulsion can be located in the alternate position. In this arrangement the layer

515 is not one which is darkened by reaction with an inhibitor, but can take the form, if present, of a subbing layer, if desired. The radiation-sensitive emulsion can be either a direct-positive or negative-working emulsion. The developer chosen is one which is a developer for both the radiation-sensitive and spontaneously developable emulsions.

Instead of being coated in a separate layer, the two emulsions can be blended, if desired, and both coated in the reaction microcells.

It is conventional to form photographic elements with continuous emulsion coatings on opposite surfaces of a planar transparent film support. For example, radiographic elements are 15 commonly prepared in this form. In a typical radiographic application fluorescent screens are associated with the silver halide emulsion layers on opposite surfaces of the support. Part of the X-rays incident during exposure are absorbed by one 20 of the fluorescent screens. This stimulates emission by the screen of light capable of efficiently producing a latent image in the adjacent emulsion layer. A portion of the incident X-rays pass through the element and are absorbed by the remain-25 ing screen causing light exposure of the adjacent emulsion layer on the opposite surface of the support. Thus two superimposed latent images are formed in the emulsion layers on the opposite surfaces of the support. When light from a screen 30 causes exposure of the emulsion layer on the opposite surface of the support, this is referred to in the art as crossover. Crossover is generally minimized since it results in loss of image definition.

The photographic element 900 is well suited for applications employing silver halide emulsion layers on opposite surfaces of a transparent film support. The alignment of the reaction microcells

908A and 908B allows two superimposed photographic images to be formed.

As an optional feature to reduce crossover, selective dying of the lateral walls 910A and 910B 5 can be employed as described above. This can be relied upon to reduce scattering of light from one reaction microcell to adjacent reaction microcells on the same side of the support and adjacent, nonaligned reaction microcells on the opposite side 10 of the support. Another technique to reduce crossover is to color the entire support 902 with a dye which can be bleached after exposure and/or processing to render the support substantially transparent and colorless. Bleachable dyes suited to this application are illustrated by Sturmer U.S. Patent 4,028,113 and Krueger U.S. Patent 4,111,699. A conventional approach in the radiographic art is to undercoat silver halide emulsion layers to reduce crossover. For instance Stappen U.S. Patent 20 3,923,515 teaches to undercoat faster silver halide emulsion layers with slower silver halide emulsion layers to reduce crossover. In applying such an approach to the present invention a slower silver halide emulsion 916 can be provided in the reaction 25 microcells. A faster silver halide emulsion layer can be positioned in an overlying relationship either in the reaction microcells or continuously coated over the reaction microcells on each major surface 904 and 906 of the support. Instead of 30 employing a slower silver halide emulsion in the reaction microcells an internally fogged silver halide emulsion can be placed in the reaction microcells as is more specifically described above. The internally fogged silver halide emulsion is 35 capable of absorbing crossover exposures while not being affected in its photographic performance,

since it is not responsive to exposing radiation.

To illustrate a diverse photographic application, the photographic element 900 can be formed so that the silver halide emulsion in the reaction microcells 908B as an imaging emulsion 5 while another silver halide emulsion can be incorporated in the reaction microcells 908A. The two emulsions can be chosen to be oppositely working. That is, if the emulsion in the microcells 908B is negative-working, then the emulsion in the micro-10 cells 908A is positive-working. Using an entirely transparent support element 902, exposure of the element from above, in the orientation shown in Figure 9, results in forming a primary photographic latent image in the emulsion contained in the 15 microcells 908B. The emulsion contained in the microcells 908A is also exposed, but to some extent the light exposing it will be scattered in passing through the overlying emulsion, microcells and support portions. Thus, the emulsion in the micro-20 cells 908B in this instance can be used to form an unsharp mask for the overlying emulsion. In one optional form specifically contemplated an agent promoting infectious development can be incorporated in the emulsion providing the unsharp mask. 25 allows image spreading within the microcells, but the lateral walls of the microcells limits lateral image spreading. Misalignment of the microcells 908A and 908B can also be relied upon to decrease sharpness in the underlying emulsion. An additional 30 approach is to size the microcells 908A so that they are larger than the microcells 908B. Any combination of these three approaches can, if desired, be used. Instead of employing oppositely working emulsions in the microcells 908A and 908B, the 35 emulsions can both be negatively working, for example. The emulsion in the microcells 908A and B differ in speed (or spectral sensitivity), however, so that the emulsion in microcells 908B is imagewise

exposed and processed without producing an image in the microcells 908A. Thereafter exposure of the emulsion in microcells 908A through the image present in the microcells 908B, followed by process-

- ing produces an unsharp mask in the microcells 908A. It is recognized in the art that unsharp masking can have the result of increasing image sharpness, as discussed in Mees and James, The Theory of the Photographic Process, 3rd Ed.,
- 10 Macmillan, 1966, p. 495. Where the photographic element is used as a printing master, any increase in minimum density attributable to masking can be eliminated by adjustment of the printing exposure.

In the photographic element 1000 the

15 lenticular surface 1004 can have the effect of
obscuring the lateral walls 1010 separating adjacent
reaction microcells 1008. Where the lateral walls
are relatively thick, as where very small pixels are
employed, the lenticular surface can laterally

- spread light passing through the microcell portion of each pixel so that the walls are either not seen or appear thinner than they actually are. In this use the support 1002 is colorless and transparent, although the lateral walls 1010 can be dyed, if
- desired. It is, of course, recognized that the use of lenticular surfaces on supports of photographic elements having continuously coated radiation-sensitive layers have been employed to obtain a variety of effects, such as increased speed, color separa-
- tion, restricted exposure and stereography, as illustrated by Cary U.S. Patent 3,316,805, Brunson et al U.S. Patent 3,148,059, Schwan et al U.S. Patent 2,856,282, Gretener U.S. Patent 2,794,739, Stevens U.S. Patent 2,543,073 and Winnek U.S. Patent
- 2,562,077. The photographic element 1000 can also provide such conventional effects produced by lenticular surfaces, if desired.

The foregoing description of employing this invention to form silver images using silver halide emulsions is believed adequate to suggest to those skilled in the art variant element forms and imaging techniques which are too numerous to discuss individually.

Dye Imaging With Silver Halide

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The photographic elements and the techniques described above for producing silver images
can be readily adapted to provide a colored image
through the use of dyes. In perhaps the simplest
approach to obtaining a projectable color image a
conventional dye can be incorporated in the support
of the photographic element, and silver image
formation undertaken as described above. In areas
where a silver image is formed the element is
rendered substantially incapable of transmitting

- rendered substantially incapable of transmitting light therethrough, and in the remaining areas light is transmitted corresponding in color to the color of the support. In this way a colored image can be
- of the support. In this way a colored image can be readily formed. The same effect can also be achieved by using a separate dye filter layer or element with a transparent support element. Where the support element or portion defining the lateral
- walls is capable of absorbing light used for projection, an image pattern of a chosen color can be formed by light transmitted through microcells in inverse proportion to the silver present therein.

The silver halide photographic elements can 30 be used to form dye images therein through the selective destruction or formation of dyes. Conventional techniques are illustrated by Research Disclosure, Item 17643, cited above, Section VII.

In the photographic elements described

35 above the dye image supplements or replaces the silver image by employing in combination with the photographic elements conventional color photographic element components and/or processing steps.

For example, dye images can be produced in the microcells of the elements 100 through 1000 or in the imaging components 418 and 518 by modifying the procedures for use described above in view of current knowledge in the field of color photography. Accordingly, the following detailed description of dye image formation is directed to certain unique, illustrative combinations, particularly those in which the radiation-sensitive portion of the photographic element is divided into two components.

In one highly advantageous form of the invention having unique properties the photographic element 400 can be formed so that a radiation-sensi-15 tive silver halide emulsion component 416 is contained within the reaction microcell while a dye image providing component 418 overlies the reaction The dye image providing component is chosen from among conventional components capable of forming or destroying a dye in proportion to the amount of silver developed in the microcell. Preferably the dye image providing component contains a bleachable dye useful in a silver-dyebleach process or an incorporated dye-forming 25 coupler. In an alternative form the bleachable dye or dye-forming coupler can be present in the emulsion component 416, and the separate imaging component 418 can be omitted.

When a photon is absorbed by a silver

halide grain a hole-electron pair is created. Both
the electron and hole can migrate through the
crystal lattice, but they are generally precluded in
an emulsion from migrating to an adjacent silver
halide grain. While holes are employed in surface

fogged emulsions to provide direct-positive images,
in the more typical negative-working silver halide
emulsions which are initially unfogged the electrons
generated by the absorbed photons are relied upon to

produce an image. The electrons provide the valence electrons given up by silver in the crystal lattice to form metallic silver. It has been postulated that when four or more metallic silver atoms are formed at one location within the crystal a developable latent image site is created.

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It is known in silver halide photography and is apparent from the mechanism of latent image formation described above that the speed of silver 10 halide emulsions generally increases as a function of the average silver halide grain size. It is also known that larger silver halide grains produce images exhibiting greater graininess. Ordinary silver halide photographic elements employ silver 15 halide grains whose size is chosen to strike the desired balance between speed and graininess for the intended end use. For example, in forming photographic images intended to be enlarged many times, graininess must be low. On the other hand, radio-20 graphic elements generally employ coarse silver halide grains in order to achieve the highest possible speeds consistent with necessary image resolution. It is further known in the photographic arts that techniques which increase the speed of a 25 photographic element without increasing image graininess can be used to decrease image graininess or can be traded off in element design to improve some combination of speed and graininess. Conversely, techniques which improve image graininess 30 without decreasing photographic speed can be used to improve speed or to improve a combination of speed and graininess.

It has been recognized and reported in the art that some photodetectors exhibit detective

35 quantum efficiencies which are superior to those of silver halide photographic elements. A study of the basic properties of conventional silver halide photographic elements shows that this is largely due

to the binary, on-off nature of individual silver halide grains, rather than their low quantum sensitivity. This is discussed, for example, by Shaw, "Multilevel Grains and the Ideal Photographic

- Detector", Photographic Science and Engineering, Vol. 16, No. 3, May/June 1972, pp. 192-200. What is meant by the on-off nature of silver halide grains is that once a latent image site is formed on a silver halide grain, it becomes entirely develop-
- 10 able. Ordinarily development is independent of the amount of light which has struck the grain above a threshold, latent image forming amount. The silver halide grain produces exactly the same product upon development whether it has absorbed many photons and
- 15 formed several latent image sites or absorbed only the minimum number of photons to produce a single latent image site.

The silver halide emulsion component 416 can employ very large, very high speed silver halide 20 grains. Upon exposure by light or X-rays, for instance, latent image sites are formed in and on the silver halide grains. Some grains may have only one latent image site, some many and some none. However, the number of latent image sites formed 25 within a single reaction microcell 408 is related to the amount of exposing radiation. Because the silver halide grains are relatively coarse, their speed is relatively high. Because the number of latent image sites within each microcell is directly 30 related to the amount of exposure that the microcell has received, the potential is present for a high detective quantum efficiency, provided this information is not lost in development.

In a preferred form each latent image site 35 is then developed to increase its size without completely developing the silver halide grains. This can be undertaken by interrupting silver halide development at an earlier than usual stage, well

before optimum development for ordinary photographic applications has been achieved. Another approach is to employ a DIR coupler and a color developing agent. The inhibitor released upon coupling can be 5 relied upon to prevent complete development of the silver halide grains. In a preferred form of practicing this step selfinhibiting developers are employed. A self-inhibiting developer is one which initiates development of silver halide grains, but 10 itself stops development before the silver halide grains have been entirely developed. Preferred developers are self-inhibiting developers containing p-phenylenediamines, such as disclosed by Neuberger et al, "Anomalous Concentration Effect: An inverse Relationship Between the Rate of Development and Developer Concentration of Some p-Phenylenediamines", Photographic Science and Engineering, Vol. 19, No. 6, Nov-Dec 1975, pp. 327-332. Whereas with interrupted development and development in the 20 presence of DIR couplers silver halide grains having a longer development induction period than adjacent developing grains can be entirely precluded from development, the use of a self-inhibiting developer has the advantage that development of an individual

After development enhancement of the latent image sites, there is present in each microcell a plurality of silver specks. These specks are

30 proportional in size and number to the degree of exposure of each microcell. The specks, however, present a random pattern within each microcell and are further too small to provide a high density. The next objective is to produce in each pixel a dye density which is substantially uniform over the entire area of its microcell. Inasmuch as the preferred self-inhibiting developers contain color developing agents, the oxidized developing agent

silver halide grain is not inhibited until after

some development of that grain has occurred.

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produced can be reacted with a dye-forming coupler to create the dye image. However, since only a limited amount of silver halide is developed, the amount of dye which can be formed in this way is 5 also limited. An approach which removes any such limitation on maximum dye density formation, but which retains the proportionality of dye density in each pixel to the degree of exposure is to employ a silver catalyzed oxidation-reduction reaction using 10 a peroxide or transition metal ion complex as an oxidizing agent and a dye-image-generating reducing agent, such as a color developing agent, as illustrated by the patents cited above of Bissonette, Travis, Dunn et al, Matejec and Mowrey and the 15 accompanying publications. In these patents it is further disclosed that where the silver halide grains form surface latent images the latent images can themselves provide sufficient silver to catalyze a dye image amplification reaction. Accordingly, 20 the step of enhancing the latent image by development is not absolutely essential, although it is preferred. In the preferred form any visible silver remaining in the photographic element after forming the dye image is removed by bleaching, as is conven-25 tional in color photography.

The resulting photographic image is a dye image in which each pixel in the array exhibits a dye density which is internally uniform and proportional to the amount of exposing radiation which has been supplied to the pixel. The regular arrangement of the pixels serves to reduce the visual sensation of graininess. The pixels further supply more information about the exposing radiation than can be obtained by completely developing the silver halide grains containing latent image sites. The result is that the detective quantum efficiency of the photographic element is quite high. Both high photographic speeds and low graininess are readily

obtainable. Where the dye is formed in the microcells rather than in an overcoat, as shown, further protection against lateral image spreading is obtained. All of the advantages described above in connection with silver imaging are, of course, also obtained in dye imaging and need not be described again in detail. Further, while this preferred process of dye imaging has been discussed referring specifically to the photographic element 400, it is 10 appreciated that it can be practiced with any of the photographic elements shown and described above.

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Referring to the photographic element 500, in one preferred form the component 518 can be a silver halide emulsion layer and the component 516 15 can be a dye image-forming component. In conventional color photographic elements the radiationsensitive portion of the element is commonly formed of layer units, each comprised of a silver halide emulsion layer and an adjacent hydrophilic colloid 20 layer containing an incorporated dye-forming coupler or bleachable dye. The components 518 and 516 in terms of composition can be identical to these two conventional color photographic element layer unit coatings.

25 A significant difference between the photographic element 500 and a photographic element having a continuously coated dye image component is that the reaction microcell 514 limits lateral image spreading of the imaging dye. That is, it can 30 laterally limit the chemical reaction which is forming the dye, where a coupler is employed, or bleaching the dye, in the case of a silver-dyebleach process. Since the silver image produced by exposing and developing the element can be bleached 35 from the element, it is less important to image definition that silver development is not similarly laterally restrained. Further, it is recognized by those skilled in the art that greater lateral

spreading typically occurs in dye imaging than when forming a silver image in a silver halide photographic element. It is apparent that the advantages of this component relationship is also applicable to photographic element 400.

Additive Multicolor Imaging

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It has been recognized in the art that additive multicolor images can be formed using a continuous, panchromatically sensitized silver 10 halide emulsion layer which is exposed and viewed through an array of additive primary (blue, green and red) filter areas. Exposure through an additive primary filter array allows silver halide to be selectively developed, depending upon the pattern of 15 blue, green and red light passing through the overlying filter areas. If a negative-working silver halide emulsion is employed, the multicolor image obtained is a negative of the exposure image, and if a direct-positive emulsion is employed, a 20 positive of the exposure image is obtained. Additive primary multicolor images can be reflection viewed, but are best suited for projection viewing, since they require larger amounts of light than conventional subtractive primary multicolor images 25 to obtain comparable brightness.

Dufay U.S. Patent 1,003,720 teaches forming an additive multicolor filter by alternately printing two-thirds of a filter element with a greasy material to leave uncovered an array of areas. An additive primary dye is imbibed into the filter element in the uncovered areas. By repeating the sequence three times the entire filter area is covered by an interlaid pattern of additive primary filter areas. Rogers U.S. Patent 2,681,857 illustrates an improvement on the Dufay process of forming an additive primary multicolor filter by printing. Rheinberg U.S. Patent 1,191,034 obtains essentially a similar effect by using subtractive

primary dyes (yellow, magenta and cyan) which are allowed to laterally diffuse so that two subtractive primaries are fused in each area to produce an additive primary dye filter array.

More recently, in connection with semiconductor sensors, additive primary multicolor filter layers have been developed which are capable of defining an interlaid pattern of areas of less than 100 microns on an edge and areas of less than 10⁻⁴ cm². One approach is to form the filter layer so that it contains a dye mordant. In this way when an interlaid pattern of additive primary dyes is introduced to complete the filter, mordanting of the dyes reduces lateral dye spreading. Filter layers comprised of mordanted dyes and processes for their preparation are disclosed by Whitmore U.S. Patents 4,312,806 and 4,375,507.

Another approach to forming an additive primary multicolor filter array is to incorporate

20 photobleachable dyes in a filter layer. By exposure of the element with an image pattern corresponding to the filter areas to be formed dye can be selectively bleached in exposed areas leaving an interlaid pattern of additive primary filter areas. The dyes can thereafter be treated to avoid subsequent bleaching. Such an approach is disclosed by Research Disclosure, Vol. 177, January 1979, Item 17735.

In addition to any one or combination of
the various additive primary materials described
above, virtually any known additive primary dye or
pigment can, if desired, be selected for use in the
multicolor filters. For example, the additive
primary dyes and pigments mentioned in the Colour
Index, Volumes I and II, Second Edition, are
generally useful in the practice of at least one
form of the present invention.

While it is recognized that conventional additive primary multicolor filter layers can be employed in connection with the photographic elements 100 through 1000 to form additive multi-5 color images in accordance with this invention, it is preferred to form additive primary multicolor filters comprised of an interlaid pattern of additive primary dyes or pigments in an array of microcells. The microcells offer the advantages of 10 providing a physical barrier between adjacent additive primary dye areas thus avoiding lateral spreading, edge co-mingling of the dyes and similar disadvantages. The microcells can be identical in size and configuration to those which have been 15 described above.

In Figures 11A and 11B an exemplary filter element 1100 of this type is illustrated which is similar to the photographic element 100 shown in Figures 1A and 1B, except that instead of radia-20 tion-sensitive material being contained in the microcells 1108, an interlaid pattern of green, blue and red dyes or pigments is provided, indicated by the letters G, B and R, respectively. The dashed line 1120 surrounding an adjacent triad of green, 25 blue and red containing microcells defines a single pixel of the filter element which is repeated to make up the interlaid pattern of the element. It can be seen that each microcell of a single pixel is equidistant from the two remaining microcells 30 thereof. Looking at an area somewhat larger than a pixel, it can be seen that each microcell containing one color is surrounded by microcells containing the remaining two colors. Thus, it is easy for the eye to fuse the colors of the adjacent microcells or, 35 during projection, for light passing through adjacent microcells to fuse. The underlying portion 1112 of the support 1102 must be transparent to permit projection viewing. While the lateral walls

1110 of the support can be transparent also, they are preferably opaque (e.g., dyed), particularly for projection viewing, as has been discussed above in connection with element 100. Placing the red, green and blue additive primary dyes in microcells offers a distinct advantage in achieving the desired lateral relationship of individual filter areas. Although lateral dye spreading can occur in an individual microcell which can be advantageous in providing a uniform dye density within the microcell, gross dye spreading beyond the confines of the microcell lateral walls is prevented.

An exemplary filter element has been illustrated as a variant of photographic element 15 100, but it is appreciated that corresponding filter element variants of photographic elements 200 through 1000 are also contemplated. Figure 11D illustrates an alternative form of filter element 1150. In section the element of Figure 11D can 20 appear identical to the section shown in Figure In this instance the microcells are diamond shaped rather than being hexagonal. However, an interlaid pattern of red, green, and blue filter segments is retained. The major axes of the 25 diamond-shaped microcells are oriented in three different directions which intersect at 60° angles. An equal number of each of the blue, green, and red filter segments are oriented in each of the three major axes directions. Thus, the elongation of 30 individual microcells imparted by the diamond shape, the filter retains an overall balance of red, green, and blue filter segments in each major axis direc-The diamond-shaped microcells can, of course, compatible with other microcell applications herein 35 described as an alternative to use in forming a filter element.

It is, of course, recognized that other interlaid patterns of microcells are possible. For

example, instead of being interlaid in the manner shown, the blue, green and red filter areas can form separate rows of microcells. For instance, a row of filter areas of one color can be interposed between two filter area rows, one of each of the two remaining additive primary colors. Different interlaid patterns can also occur as a result of devoting unequal numbers of microcells to the different filter colors. For example, it is recognized that 10 the human eye obtains most of its information from the green portion of the spectrum. Less information is obtained from the red portion of the spectrum, and the least amount of information is obtained from the blue portion of the spectrum. Bayer U.S. Patent 15 3,971,065 discloses an interlaid additive primary multicolor filter area pattern in which the green areas occupy half of the total filter area, with red and blue filter areas each occupying one half of the remaining area of the filter. Still other filter 20 area patterns can be employed, if desired.

In Figure 11C the use of filter element 1100 in combination with photographic element 100 is illustrated. The photographic element contains in the reaction microcells 108 a panchromatically 25 responsive radiation-sensitive imaging means 116, such as a panchromatically sensitized silver halide The microcells 1108 of the filter element emulsion. are aligned (registered) with the microcells of the photographic element. Exposure of the photographic element occurs through the blue, green and red filter areas of the aligned filter element. filter element and the photographic element can be separated for processing and subsequently realigned for viewing or further use, as in forming a photo-35 graphic print. The second alignment can be readily accomplished by viewing the image during the alignment procedure. It is possible to join the filter element and photographic element by attachment along

one or more edges so that, once positioned, the alignment between the two elements is subsequently preserved. Where the filter and photographic elements remain in alignment, processing fluid can 5 be dispensed between the elements in the same manner as in-camera image transfer processing. In order to render less exacting the process of initial alignment of the filter and photographic element microcells, the microcells of the filter element can be 10 substantially larger in area than those of the photographic element and can, if desired, overlie more than one of the microcells of the photographic element. Complementary edge configurations, not shown, can be provided on the photographic and 15 filter elements to facilitate alignment. A variant form which insures alignment of the silver halide and the additive primary filter microcells is achieved by modifying element 900 so that silver halide remains in microcells 908A, but additive 20 primary dyes or pigments are present in microcells 908B.

By combining the functions of the filter and photographic elements in a single element any inconveniences of registering separate filter and 25 photographic element microcells can be entirely obviated. In perhaps the simplest approach, the filter element 1100 can be modified by incorporating in the blue, green, and red filter material containing microcells blue, green, and red spectral sens-30 tizing dyes respectively. Blue spectral sensitizing dye is not essential, since silver halides, particularly silver bromide and silver bromoiodide, have significant levels of native blue sentivity. sensitizing dyes are chosen to be capable of wander-35 ing. Over the major surface of the element 1100 toward which the microcells open a silver halide emulsion is coated which is not initially spectrally sensitized. The emulsion is coated to contact the

contents of the microcells. Following coating, spectral senstizing dye can wander from the microcells into the emulsion. Absorption of sensitizing dye by the silver halide grains immobilizes the dye 5 on the grains lying adjacent the microcell. In this way, the emulsion layer becomes selectively responsive to blue, green, and red light adjacent the microcells containing blue, green, and red filter materials, respectively. This arrangement is highly 10 advantageous in that the microcells and differing senstivity regions of the microcells are self-registering. Where the emulsion layer possesses limited native blue sensitivity and a blue spectral sensitizing dye is employed, the emulsion layer can be 15 exposed either directly or through the filter materials contained in the microcells.

Photographic elements 1200, 1300 and 1400 illustrate forms of the invention in which both radiation-sensitive imaging (hereinafter described by references to a preferred imaging material, a silver halide emulsion) and filter materials are positioned in the same element microcells. These elements appear in plan view identical to element 1100 in Figure 11A. The views of elements 1200, 1300 and 1400 shown in Figures 12, 13 and 14, respectively, are sections of these elements which correspond to the section shown in Figure 11B of the element 1100.

The photographic element 1200 is provided
with microcells 1208. In the bottom of each microcell is provided a filter portion, indicated by the letters B, G and R. A panchromatically sensitized silver halide emulsion 1216 is located in the microcells so that it overlies the filter portion
contained therein. Alternatively the emulsion can be blue, green, and red sensitized by spectral sensitizing dye migration from the filter materials as described above.

The photographic element 1300 is provided with microcells 1308. In the microcells designated B a blue filter material is blended with a blue sensitized silver halide emulsion. Similarly in the 5 microcells designated G and R a green filter material is blended with a green sensitized silver halide emulsion and a red filter material is blended with a red sensitized silver halide emulsion. respectively. In this form the silver halide 10 emulsion is preferably chosen so that it has negligible native blue sensitivity, since the blended green and red filter materials offer substantial, but not complete, filter protection against exposure by blue light of the emulsions with which they are 15 associated. In a preferred form silver chloride emulsions are employed, since they have little native sensitivity to the visible spectrum.

The photographic element 1400 is provided with a transparent first support element 1402 and a 20 yellow second support element 1408. The microcells B extend from the outer major surface 1412 of the second support element to the first support element. The microcells G and R have their bottom walls spaced from the first support element. 25 contents of the microcells can correspond to those of the photographic element 1300, except that the silver halide emulsions need not be limited to those having negligible blue sensitivity in order to avoid unwanted exposure of the G and R microcells. 30 example, iodide containing silver halide emulsions, such as silver bromoiodides, can be employed. yellow color of the second support element allows blue light to be filtered so that it does not reach the G and R microcells in objectionable amounts when the photographic element is exposed through the 35 support. The yellow color of the support can be imparted and removed for viewing using materials and techniques conventionally employed in connection

with yellow filter layers, such as Carey Lea silver and bleachable yellow filter dye layers, in multilayer multicolor photographic elements. The yellow color of the support can also be incorporated by employing a photobleachable dye. Photobleaching is 5 substantially slower than imaging exposure so that the yellow color remains present during imagewise exposure, but after processing handling in roomlight or intentional uniform light exposure can be 10 relied upon to bleach the dye. Photobleachable dyes which can be incorporated into supports are disclosed, for example, by Jenkins et al U.S. Reissue Patent 28,225 and the Sturmer and Kruegor U.S. Patents cited above. The optimum approach for 15 imparting and removing yellow color varies, of course, with the specific support element material chosen.

Instead of relying on wandering sensitizing dye to sufficiently sensitize the emulsion layer 20 coated on element 1100 as described above, the filter element 1100 can be overcoated with a panchromatically sensitized silver halide emulsion layer. In the photographic elements 1200, 1300 and 1400 it is specifically contemplated that the 25 radiation-sensitive portion of the photographic element can be present as two components, one contained in the microcells and one in the form of a layer overlying the microcells, as has been specifically discussed above in connection with photo-30 graphic elements 400 and 500. In the interest of succinctness element features are not discussed which are identical or clearly analogous to features which have been previously discussed in detail.

In one preferred additive primary multi-35 color imaging application one or a combination of bleachable leuco dyes are incorporated in the silver halide emulsion or a contiguous component. Suitable bleachable leuco dyes useful in silver-dye-bleach processes have been identified above in connection with dye imaging. The leuco dye or combination of leuco dyes are chosen to yield a substantially neutral density. In a specifically preferred form the leuco dye or dyes are located in the reaction microcells. The silver halide emulsion that is employed in combination with the leuco dyes is a negative-working emulsion.

Upon exposure of the silver halide emulsion 10 through the filter element silver halide is rendered developable in areas where light penetrates the The silver halide emulsion can be filter elements. developed to produce a silver image which can react with or catalyze a separate reaction with the dye to 15 destroy it using silver-dye-bleach processes, described above. Upon contact with alkaline developer solution, the leuco dyes are converted to a colored form uniformly within the element. silver-dye-bleach step causes the colored dyes to be 20 bleached selectively in areas where exposed silver halide has been developed to form silver. developed silver which reacts with dye is reconverted into silver halide and thereby removed. every case subsequent silver bleaching can be 25 undertaken, if desired. The colored dye which is not bleached is of sufficient density to prevent light from passing through the filter elements with which it is aligned.

When exposure and viewing occur through an additive primary filter array, the result is a positive additive primary multicolor dye image. It is surprising and advantageous that a direct-positive multicolor image is obtained with a single negative-working silver halide emulsion. Having the dye in its leuco form during silver halide exposure avoids any reduction of emulsion speed by reason of competing absorption by the dye. Further, the use of a negative-working emulsion permits very high

emulsion speeds to be readily obtained. By placing both the imaging and filter dyes in the microcells registration is assured and lateral image spreading is entirely avoided.

5 Another preferred approach to additive primary multicolor imaging is to use as a redox catalyst an imagewise distribution of silver made available by silver halide emulsion contained in the reaction microcells to catalyze a neutral dye image 10 producing redox reaction in the microcells. formation of dye images by such techniques are described above in connection with dye imaging. This approach has the advantage that very low silver coverages are required to produce dye images. The 15 silver catalyst can be sufficiently low in concentration that it does not limit transmission through the filter elements. An advantage of this approach is that the redox reactants can be present in either the photographic element or the processing solutions 20 or some combination thereof. So long as redox catalyst is confined to the microcells lateral image spreading can be controlled, even though the dye-forming reactants are coated in a continuous layer overlying the microcells. In one form a blend 25 of three different subtractive primary dye-forming reactants are employed. However, only a single subtractive primary dye need be formed in a microcell in order to limit light transmission through the filter and microcell. For example, forming a 30 cyan dye in a microcell aligned with a red filter element is sufficient to limit light transmission.

To illustrate a specific application, in any one of the arrangements illustrated in Figures 11C, 12, 13 and 14, the silver halide emulsion contained in the microcells is exposed through the filter elements. Where the silver halide emulsion forms a surface latent image, this can be enough silver to act as a redox catalyst. It is generally

preferred to develop the latent image to form additional catalytic silver. The silver, acting as a redox catalyst, permits the selective reaction of a dye-image-generating reducing agent and an oxidiz-5 ing agent at its surface. If the emulsion or an adjacent component contains a coupler, for example, reaction of a color developing agent, acting as a dye-image-generating reducing agent, with an oxidizing agent, such as a peroxide oxidizing agent (e.g., 10 hydrogen peroxide) or transition metal ion complex (e.g., cobalt(III) hexammine), at the silver surface can result in a dye-forming reaction occurring. this way a dye can be formed in the microcells. image formation can occur during and/or after silver 15 halide development. The transition metal ion complexes can also cause dye to be formed in the course of bleaching silver, if desired. In one form the microcells each contain a yellow, magenta or cyan dye-image-generating reducing agent and the 20 blue, green and red filter areas are aligned with the microcells so that subtractive and additive primary color pairs can be formed in alignment capable of absorbing throughout the visible spectrum.

In the foregoing discussion additive 25 primary multicolor imaging is accomplished by employing blue, green and red filter dyes or pigments preferably contained in microcells. It is also possible to produce additive multicolor images according to the present invention by employing 30 subtractive primary dyes or pigments in combination. For example, it is known that if any two subtractive primary colors are mixed the result is an additive primary color. In the present invention, if two microcells in transparent supports are 35 aligned, each containing a different subtractive primary, only light of one additive primary color can pass through the aligned microcells. For example, a filter which is the equivalent of filter

1100 can be formed by employing in the microcells 908A and 908B of the element 900 subtractive primary dyes rather than silver halide. Only two subtractive primary dyes need to be supplied to a side to provide a multicolor filter capable of transmitting red, green and blue light in separate areas. modifying the elements 1100, 1200, 1300 and 1400 so that aligned microcells are present on opposite surfaces of the support, it is possible to obtain 10 additive primary filter areas with combinations of subtractive primary colors.

Subtractive Multicolor Imaging

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Multicolor images formed by laterally displaced green, red and blue additive primary pixel 15 areas can be viewed by reflection or, preferably, projection to reproduce natural image colors. is not possible using the subtractive primariesyellow, magenta and cyan. Multicolor subtractive primary dye images are most commonly formed by 20 providing superimposed silver halide emulsion layer units each capable of forming a subtractive primary dye image.

Photographic elements according to the present invention capable of forming multicolor 25 images employing subtractive primary dyes can be in one form similar in structure to corresponding conventional photographic elements, except that in place of at least the image-forming layer unit nearest the support, at least one image-forming 30 component of the layer unit is located in the reaction microcells, as described above in connection with dye imaging. The microcells can be overcoated with additional image-forming layer units according to conventional techniques.

35 It is possible in practicing the present invention to form each of the three subtractive dye images which together form the multicolor dye image in the reaction microcells. By one preferred

approach this can be achieved by employing three silver halide emulsions, one sensitive to blue exposure, one sensitive to green exposure and one sensitive to red exposure. Silver halide emulsions can be employed which have negligible native sensitivity in the visible portion of the spectrum, such as silver chloride, and which are separalely spectrally sensitized. It is also possible to employ silver halide emulsions which have substantial 10 native sensitivity in the blue region of the spectrum, such as silver bromoiodide. Red and green spectral sensitizers can be employed which substantially desensitize the emulsions in the blue region of the spectrum. The native blue sensitivity can be 15 relied upon to provide the desired blue response for the one emulsion intended to respond to blue exposures or a blue sensitizer can be relied upon. blue, green and red responsive emulsions are blended, and the blended emulsion introduced into 20 the reaction microcells. The resulting photographic element can, in one form, be identical to photographic element 100. The silver halide emulsion 116 can be a blend of three emulsions, each responsive to one third of the visible spectrum. By employing 25 spectral sensitizers which are absorbed to the silver halide grain surfaces and therefore nonwandering any tendency of the blended emulsion to become panchromatically sensitized is avoided.

Following imagewise exposure, the photo30 graphic element is black-and-white developed. No
dye is formed. Thereafter the photographic element
is successively exposed uniformly to blue, green and
red light, in any desired order. Following monochromatic exposure and before the succeeding expo35 sure, the photographic element is processed in a
developer containing a color developig agent and a
soluble coupler capable of forming with oxidized
color developing agent a yellow, magenta or cyan

dye. Developed silver is removed by bleaching. The result is that a multicolor image is formed by subtractive primary dyes confined entirely to the microcells. Suitable processing solutions, including soluble couplers, are illustrated by Mannes et al U.S. Patent 2,252,718, Schwan et al U.S. Patent 2,950,970 and Pilato U.S. Patent 3,547,650, cited above. In the preferred form negative-working silver halide emulsions are employed and positive multicolor dye images are obtained.

In another form of the invention mixed packet silver halide emulsions can be placed in the reaction microcells to form subtractive primary dye multicolor images. In mixed packet emulsions blue 15 responsive silver halide is contained in a packet also containing a yellow dye-forming coupler, green responsive silver halide in a packet containing a magenta dye-forming coupler and red responsive silver halide in a packet containing a cyan 20 dye-forming coupler. Imaging exposure and processing with a black-and-white developer is performed as described above with reference to the blended emulsions. However, subsequent exposure and processing is comparatively simpler. The element is 25 uniformly exposed with a white light source or chemically fogged and then processed with a color developer. In this way a single color developing step is required in place of the three successive color developing steps employed with soluble couplers. A suitable process is illustrated by the Ektachrome E4 and E6 and Agfa processes described in British Journal of Photography Annual, 1977, pp. 194-197, and British Journal of Photography, August 1974, pp. 668-669. Mixed packet silver halide 35 emulsions which can be employed in the practice of this invention are illustrated by Godowsky U.S. Patents 2,698,974 and 2,843,488 and Godowsky et al U.S. Patent 3,152,907, the disclosures of which are

here incorporated by reference. Silver Transfer Imaging

It is well recognized in the art that transferred silver images can be formed. 5 typically accomplished by developing an exposed silver halide photographic element with a developer containing a silver halide solvent. The silver halide which is not developed to silver is solubilized by the solvent. It can then diffuse to a 10 receiver bearing a uniform distribution of physical development nuclei or catalysts. Physical development occurs in the receiver to form a transferred silver image. Conventional silver image transfer elements and processes (including processing solu-15 tions) are generally discussed in Chapter 12, "One Step Photography", Neblette's Handbook of Photography and Reprography Materials, Processes and Systems, 7th Ed. (1977) and in Chapter 16, "Diffusion Transfer and Monobaths", T. H. James, The 20 Theory of the Photographic Process, 4th Ed. (1977), the disclosures of which are here incorporated by reference.

The photographic elements 100 through 1000 described above in connection with silver imaging 25 can be readily employed for producing transferred silver images. Illustrative of silver halide solvent containing processing solutions useful in providing a transferred silver image in combination with these photographic elements are those disclosed 30 by Rott U.S. Patent 2,352,014, Land U.S. Patents 2,543,181 and 2,861,885, Yackel et al U.S. Patent 3,020,155 and Stewart et al U.S. Patent 3,769,014. The receiver to which the silver image is transferred is comprised of a conventional photographic 35 support (or cover sheet) onto which is coated a reception layer comprised of silver halide physical developing nuclei or other silver precipitating agents. In a preferred form the receiver and

photographic element are initially related so that the emulsion and silver image-forming surfaces of the photographic element and receiver, respectively, are juxtaposed and the processing solution is contained in a rupturable pod to be released between the photographic element and receiver after imagewise exposure of the silver halide emulsion. photographic element and receiver can be separate elements or can be joined along one or more edges to 10 form an integral element. In a common preferred separate element or peel-apart form the photographic element support is initially transparent and the receiver is comprised of a reflective (e.g., white) support. In a common integral format both the 15 receiver and photographic element supports are transparent and a reflective (e.g., white) background for viewing the silver image is provided by overcoating the silver image-forming reception layer of the receiver with a reflective pigment layer or 20 incorporating the pigment in the processing solution.

A wide variety of nuclei or silver precipitating agents can be utilized in the reception layers used in silver halide solvent transfer processes. Such nuclei are incorporated into conventional photographic organic hydrophilic colloid layers such as gelatin and polyvinyl alcohol layers and include such physical nuclei or chemical precipitants as (a) heavy metals, especially in colloidal form and salts of these metals, (b) salts, the anions of which form silver salts less soluble than the silver halide of the photographic emulsion to be processed, and (c) nondiffusible polymeric materials with functional groups capable of combining with and insolubilizing silver ions.

Typical useful silver precipitating agents include sulfides, selenides, polysulfides, polyselenides, thiourea and its derivatives, mercaptans, stannous halides, silver, gold, platinum, palladium,

mercury, colloidal silver, aminoguanidine sulfate, aminoguanidine carbonate, arsenous oxide, sodium stannite, substituted hydrazines, xanthates, and the like. Poly(vinyl mercaptoacetate) is an example of a suitable nondiffusing polymeric silver precipitant. Heavy metal sulfides such as lead, silver, zinc, aluminum, cadmium and bismuth sulfides are useful, particularly the sulfides of lead and zinc alone or in an admixture or complex salts of these with thioacetamide, dithiooxamide or dithiobiuret. The heavy metals and the noble metals particularly in colloidal form are especially effective. Other silver precipitating agents will occur to those skilled in the present art.

15 Instead of forming the receiver with a hydrophilic colloid layer containing the silver halide precipitating agent, it is specifically contemplated to form the receiver alternatively with microcells. The microcells can be formed of the 20 same size and configuration as described above. For example, referring to Figure 11C, if instead of employing red, green and blue filter areas in the microcells 1108, silver precipitating agent suspended in a hydrophilic colloid is substituted, 25 an arrangement useful in silver image transfer results. The same alignment considerations discussed above in connection with Figure 11C also apply. In this form the support 1102 is preferably reflective (e.g., white) rather than transparent as 30 shown, although both types of supports are useful. By confining silver image-forming physical development to the microcells protection against lateral image spreading is afforded.

In another variation of the invention it is contemplated that a conventional photographic element containing at least one continuous silver halide emulsion layer can be employed in combination with a receiver as described above in which the

silver precipitating agent is confined within microcells. Where the silver precipitating agent is confined in the microcells, their depth can be the same as or significantly less than the depth of microcells which contain a silver halide emulsion, since the peptizers, binders and other comparatively bulky components characteristic of silver halide emulsions can be greatly reduced in amount or eliminated. Generally reaction microcell depths as low as those contemplated for vacuum vapor deposited imaging materials, such as silver halide, described above, can be usefully employed also to contain the silver precipitating agents.

Dye Transfer Imaging

15 A variety of approaches are known in the art for obtaining transferred dye images. The approaches can be generally categorized in terms of the initial mobility of the dyes or dye precursors, hereinafter also referred to as dye image providing 20 compounds. (Initial mobility refers to the mobility of the dye image providing compounds when they are contacted by the processing solution. Initially mobile dye image providing compounds as coated do not migrate prior to contact with processing solu-25 tion). Dye image providing compounds are classified as either positive-working or negative-working. Positive-working dye image providing compounds are those which product a positive transferred dye image when employed in combination with a conventional, negative-working silver halide emulsion. Negativeworking dye image providing compounds are those which produce a negative transferred dye image when employed in combination with conventional, negative-working silver halide emulsions. Image trans-35 fer systems, which include both the dye image providing compounds and the silver halide emulsions, are positive-working when the transferred dye image is positive and negative-working when the transferred dye image is negative. When a retained dye image is formed, it is opposite in sense to the transferred dye image. (The foregoing definitions assume the absence of special image reversing techniques, such as those referred to in Research Disclosure, Vol. 176, December 1978, Item 17643, paragraph XXIII-E).

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A variety of dye image transfer systems have been developed and can be employed in the practice of this invention, such as those described in Whitmore U.S. Patents 4,362,806 and 4,375,507.

Any one of the conventional systems for forming transferred dye images can be readily employed in the practice of this invention. Photo-15 graphic elements according to this invention capable of forming transferred dye images are comprised of at least one image-forming layer unit having at least one component located in the reacion microcells, as described above in connection with dye 20 imaging. The receiver can be in a conventional form with a dye image providing layer coated continuously on a planar support surface, or the dye image providing layer of the receiver can be segmented and located in microcells, similarly as described in 25 connection with silver image transfer. The dye not transferred to the receiver can, of course, also be employed in most of the systems identified to form a retained dye image, regardless of whether an image is formed by transfer. For instance, once an 30 imagewise distribution of mobile and immobile dye is formed in the element, the mobile dye can be washed and/or transferred from the element to leave a retained dye image. It is also specifically contemplated to form multiple transferred dye images 35 employing a single microcellular support containing an imagewise distribution of mobile dye or dye precursor. The microcells can act as wells providing more transferable image dye or dye precursor

than is needed for a single transferred image.

A preferred image transfer film unit capable of forming multicolor transferred dye images according to the present invention is illustrated in 5 Figure 15. The image transfer film unit 1500 preferably is of the integral format type. A transparent support 1502 is provided which can be identical to transparent support 1102 described above. The support is provided with reaction 10 microcells 1508 separated by lateral walls 1510. The lateral walls are preferably dyed or opaque for reasons which have been discussed above. microcell there is provided a negative-working silver halide emulsion containing a filter dye. reaction microcells form an interlaid pattern, preferably identical to that shown in Figure 11A, of a first set of reaction microcells containing redsensitized silver halide and a red filter dye, a second set of reaction microcells containing green-20 sensitized silver halide and a green filter dye and a third set of reaction microcells containing blue-sensitized or blue sensitive silver halide and a blue filter dye. (In an alternative form, not shown, a panchromatically sensitized silver halide 25 emulsion can be coated over the microcells rather than incorporating silver halide within the microcells.) In each of the emulsions there is also provided an initially mobile subtractive primary dye precursor. In the red-sensitized emulsion containing microcells R, the green-sensitized emulsion containing microcells G and the blue-sensitized emulsion containing microcells B are provided mobile cyan, magenta and yellow dye precursors, respectively. The support 1502 and emulsions together 35 form the image-generating portion of the image

An image-receiving portion of the image transfer film unit is comprised of a transparent

transfer film unit.

support (or cover sheet) 1550 on which is coated a conventional dye immobilizing layer 1552. A reflection and spacing layer 1554, which is preferably white, is coated over the immobilizing layer. A silver reception layer 1556, which can be identical to that described in connection with silver image transfer, overlies the reflection and spacing layer.

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In the preferred integral construction of the image transfer film unit the image-generating 10 and image-receiving portions are joined along their edges and lie in face-to-face relationship. After imagewise exposure a processing solution is released from a rupturable pod, not shown, integrally joined to the image-generating and receiving portions along one edge thereof. A space 1558 is indicated between the image-generating and receiving portions to indicate the location of the processing solution when present after exposure. The processing solution contains a silver halide solvent, as has been described above in connection with silver image transfer. A silver halide developing agent is contained in either the processing solution or a processing solution permeable layer which is contacted by the processing solution upon its 25 release from the rupturable pod, for example. developing agent or agents can be incorporated in the silver halide emulsions. Incorporation of developing agents has been described above.

The image transfer film unit 1500 is

30 preferably a positive-working image transfer system in which dyes are not initially present (other than the filter dyes), but are formed by reactions occurring in the image generating portion or receiver of the image transfer film unit during

35 processing following exposure, described above in connection with Dye Image Transfer.

The image transfer film unit 1500 is imagewise exposed through the transparent support

1502. The red, green and blue filters do not interfere with imagewise exposure, since they absorb in each instance primarily only outside that portion of the spectrum to which the emulsion with which

they are associated is sensitized. The filters can, however, perform a useful function in protecting the emulsions from exposure outside the intended portion of the spectrum. For instance, where the emulsions exhibit substantial native blue sensitivity, the red 10 and green filters can be relied upon to absorb light so that the red- and green-sensitized emulsions are not imaged by blue light. Other approaches which have been discussed above for minimizing blue

sensitivity of silver halide emulsions can also be

15 employed, if desired.

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Upon release of processing solution between the image-forming and receiving portions of the element, silver halide development is initiated in the reaction microcells containing exposed silver 20 halide. Silver halide development within a reaction microcell results in a selective immobilization of the initially mobile dye precursor present. preferred form the dye precursor is both immobilized and converted to a subtractive primary dye. 25 residual mobile imaging dye precursor, either in the form of a dye or a precursor, migrates through the silver reception layer 1556 and the reflection and spacing layer 1554 to the immobilizing layer 1552. In passing through the silver reception and spacing 30 layers the mobile subtractive primary dyes or precursors are free to and do spread laterally. Referring to Figure 11A, it can be seen that each reaction microcell containing a selected subtractive primary dye precursor is surrounded by microcells 35 containing precursors of the remaining two subtractive primary dyes. It can thus be seen that lateral spreading results in overlapping transferred dye

areas in the immobilizing layer of the receiver when

mobile dye or precursor is being transferred from adjacent microcells. Where three subtractive primary dyes overlap in the receiver, black image areas are formed, and where no dye is present, white areas are viewed due to the reflection from the spacing layer. Where two of the subtractive primary dyes overlap at the receiver an additive primary image area is produced. Thus, it can be seen that a positive multicolor dye image can be formed which can be viewed through the transparent support 1550. The positive multicolor transferred dye image so viewed is rightreading.

The present invention offers a distinct advantage over conventional multicolor transfer

15 systems in terms of reduced diffusion times required to permit a transferred image to be seen. The three color forming units forming the multicolor transferred image are not superimposed, as in most color image transfer systems, and therefore permit a shorter diffusion path for all mobile dyes or dye precursors.

It is recognized in forming multicolor dye images in conventional photographic elements having superimposed color forming layer units that oxidized 25 color developing agent produced in one layer can, unless restrained, wander to an adjacent layer unit to produce undesirable interimage effects. Accordingly, it is conventional practice to incorporate oxidized developing agent scavengers in interlayers 30 between adjacent color-forming layer units. Such scavengers include ballasted or otherwise nondiffusing (immobile) antioxidants, as illustrated by Weissberger et al U.S. Patent 2,336,327, Loria et al U.S. Patent 2,728,659, Vittum et al U.S. Patent 2,360,290, Jelley et al U.S. Patent 2,403,721 and Thirtle et al U.S. Patent 2,701,197. To avoid autooxidation the scavengers can be employed in combination with other antioxidants, as illustrated

by Knechel et al U.S. Patent 3,700,453.

In the multicolor image transfer film units according to this invention the risk of unwanted wandering of oxidized developing agent is substantially reduced, since the lateral walls of the support element prevent direct lateral migration between adjacent reaction microcells. Nevertheless, the oxidized developing agent in some systems can be mobile and can migrate with the mobile dye or dye 10 precursor toward the receiver. It is also possible for the oxidized developing agent to migrate back to an adjacent microcell. To minimize unwanted dye or dye precursor immobilization prior to its transfer to the immobilizing layer of the receiver, it is 15 preferred to incorporate in the silver reception layer 1556 a conventional oxidized developing agent scavenger. Specific oxidized developing agent scavenger as well as appropriate concentrations for use are set forth in the patents cited above as 20 illustrating conventional oxidized developing agent scavengers, the disclosures of which are here incorporated by reference.

Since the processing solution contains silver halide solvent, the residual silver halide 25 not developed in the reaction microcells is solubilized and allowed to diffuse to the adjacent silver reception layer. The dissolved silver is physically developed in the silver reception layer. In addition to providing a useful transferred silver image this performs an unexpected and useful func-Specifically, solubilization and transfer of the silver halide from the reaction microcells operates to limit direct or chemical development of silver halide occurring therein. It is well recog-35 nized by those skilled in the art that extended contact between silver halide and a developing agent under development conditions (e.g., at an alkaline pH) can result in an increase in fog levels.

solubilizing and transferring the silver halide a mechanism is provided for terminating silver halide development in the reaction microcells. In this way production of oxidized developing agent is terminated and immobilization of dye in the microcells is also terminated. Thus, a very simple mechanism is provided for terminating silver halide development and dye immobilization.

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It is, of course, recognized that other
conventional silver halide development termination
techniques can be employed in lieu of or in combination with that described above. For example, a
conventional polymeric acid layer can be overcoated
on the cover sheet 1550 and then overcoated with a
timing layer prior to coating the dye immobilizing
layer 1552. Illustrative acid and timing layer
arrangements are disclosed by Cole U.S. Patent
3,635,707 and Abel et al U.S. Patent 3,930,684. In
variant forms of this invention it is contemplated
that such conventional development termination
layers can be employed as the sole means of terminating silver halide development, if desired.

In addition to obtaining a viewable transferred multicolor positive dye image a useful 25 negative multicolor dye image is obtained. reaction microcells where silver halide development has occurred an immobilized subtractive primary dye is present. This immobilized imaging dye together with the additive primary filter offers a substan-30 tial absorption throughout the visible spectrum, thereby providing a high neutral density to these reaction microcells. For example, where an immobilized cyan dye is formed in a microcell also containing a red filter, it is apparent that the 35 cyan dye absorbs red light while the red filter absorbs in the blue and the green regions of the The developed silver present in the spectrum. reaction microcell also increases the neutral

density. In reaction microcells in which silver halide development has not occurred, the mobile dye precursor, either before or after conversion to a dye, has migrated to the receiver. The sole color present then is that provided by the filter. It is a distinct advantage in reducing minimum density to employ the silver reception layer 1556 to terminate silver halide development as described above rather than to relie on other development termination 10 alternatives. If the image-generating portion of the image transfer film unit 1500 is separated from the image-receiving portion, it is apparent that the image-generating portion forms in itself an additive primary multicolor negative of the exposure image. 15 The additive primary negative image can be used for either transmission or reflection printing to form right-reading multicolor positive images, such as enlargements, prints and transparencies, by conventional photographic techniques. By obtaining a 20 useful multicolor negative, the transferred multicolor image need not be of the usual large size,

since the negative is available to produce an enlarged print, if desired. Accordingly, the format of the image transfer element can be small and less expensive, also permitting a smaller, more compact camera to be employed than is needed when the transferred print is the primary photographic product obtained.

subtractive primary positive images and retained multicolor additive primary negative images can also be obtained as described above by employing direct-positive silver halide emulsions in combination with negative-working dye image providing compounds. Dye precursors are initially present in the reaction microcells, and dyes are formed by reactions occurring in the image-forming or image-receiving portion following exposure, as described above in connection

with dye image transfer.

As can be readily appreciated from the foregoing description, the image transfer film unit 1500 possesses a number of unique and unexpected 5 advantages. In comparing the image-generating portion of the image transfer film unit to those of Land and Rogers discussed above it can be seen that this portion of the image transfer film unit is of a simple construction and thinner than the image-10 receiving portion of the element, which is the opposite of conventional integral receiver multicolor image transfer photographic elements. emulsions contained in the microcells all lie in a common plane and they do not present an uneven or 15 nonplanar surface configuration either to the support or the image-receiving portion of the element. The emulsions are not wasted by being in overlapping arrangements, and they are protected against lateral image spreading by being uniformly 20 laterally confined. Further, the microcells confining the emulsions can be of identical configuration so that any risk of dye imbalances due to differing emulsion configurations are avoided. Whereas Land and Rogers obtain a wrong-reading retained dye pattern which is at best of questionable utility for reflection imaging, the image-generating portion of the image transfer film unit of this invention provides a right-reading multicolor additive primary retained image which can be conveniently used for 30 either reflective or transmission photographic applications.

Instead of incorporating subtractive primary dye precursors in the reaction microcells, as described above, it is possible to use subtractive primary dyes directly. If the dye is blended with the emulsion, a photographic speed reduction can be expected, since the subtractive primary dye is competing with the silver halide grains in

absorbing red, green or blue light. This disadvantage can be obviated, however, by forming the image-generating portion of the image transfer film unit so that the filter material and silver halide 5 emulsion are blended together and located in the lower portion of the reaction microcells while the subtractive primary dye, preferably distributed in a suitable vehicle, such as a hydrophilic colloid, is located in the reaction microcells to overlie the 10 silver halide emulsion. In this way when the image transfer film unit is exposed through the support 1502, exposing radiation is received by the emulsion and competitive absorption by the subractive primary dye of direct incident radiation is not possible.

- It is also specifically contemplated that instead of mixing the filter material with the emulsion the filter material can be placed in the reaction microcells before the emulsion, as is illustrated in Figure 12. The advantages of such an arrangement
- have been discussed in connection with photographic element 1200. Finally, it is contemplated that the reaction microcells can be filled in three distinct tiers, with the filter dyes being first introduced, the emulsions next and the subtractive primary dyes
- overlying the emulsions. It is recognized that preformed image dyes can in still another variant form be shifted in hue so that they do not compete with silver halide in absorbing light to which silver halide in the same microcell is responsive.
- The dyes can shift back to their desired image hue upon contact with processing solution. It is thus apparent that any of the conventional positive-working or negative-working image transfer systems which employ preformed subtractive primary dyes, described above in connection with dye image transfer, can be
- above in connection with dye image transfer, can be employed in the image transfer film unit 1500. If the filter materials are omitted, no retained image is produced which can be directly viewed.

Figure 16 illustrates a image transfer film unit 1600 which can be substantially simpler in construction than the image transfer film unit 1500. The image-generating portion of the image transfer film unit 1600 can be identical to the image-generating portion of the image transfer film unit 1500. Reference numerals 1602, 1608 and 1610 identify structural features which correspond to those identified by reference numerals 1502, 1508 and 1510, respectively. In a simple preferred form the reaction microcells 1608 contain silver halide emulsions and filter materials as described in connection with image transfer film unit 1500, but they do not contain an imaging dye or dye precursor.

The image-receiving portion of the image transfer film unit 1600 is comprised of a transparent support 1650 onto which is coated a silver reception layer 1656 which can be identical to silver reception layer 1556. A reflective layer 1654 is provided on the surface of the silver reception layer remote from the support 1650. The reflection layer is preferably thinner than the imaging and spreading layer 1554, since it is not called upon to perform an intentional spreading function. The reflection layer is preferably white.

upon exposure through the support 1602 negative-working silver halide is rendered developable in the exposed microcells. Upon introducing a processing solution containing a silver halide developing agent and a silver halide solvent in the space 1658 indicated between the image-receiving and image-generating portions, silver halide development is initiated in the exposed reaction microcells and silver halide solubilization is initiated in the unexposed microcells. The solubilized silver halide is transferred through the reflection layer 1654 and forms a silver image at the silver reception layer 1656. In viewing the silver image in the silver

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reception layer through the support 1650 against the background provided by the reflection layer a right-reading positive silver image is provided. The photographer is thus able to judge the photo-5 graphic result obtained, although a multicolor positive image is not immediately viewable. The image-generating portion of the image transfer film unit, however, contains a multicolor additive primary negative image. This image can be used to provide multicolor positive images by known photographic techniques when the image-generating portion is separated from the image-receiving portion. image transfer film unit 1600 offers the user advantage of rapid information as to the photo-15 graphic result obtained, but avoids the complexities and costs inherent in multicolor dye image transfer.

As described above the image transfer film unit 1600 relies upon silver halide development in the reaction microcells to provide the required 20 increase in neutral density to form a multicolor additive primary negative image in the image-generating portion of the element. Since it is known that silver reception layers can produce silver images of higher density than those provided by 25 direct silver halide development, it is possible that at lower silver halide coating coverages a satisfactory transferred silver image can be obtained, but a less than desired silver density obtained in the reaction microcells. The neutral 30 density of the reaction microcells can be increased by employing any one of a variety of techniques. For example redox processing of the image-generating portion of the image transfer film unit after separation from the image-receiving portion can be 35 undertaken. In redox processing the silver developed in the reaction microcells acts as a catalyst for dye formation which can increase the neutral density of the microcells containing silver

or can be employed as a catalyst for physical development to enhance the neutral density of the silver containing microcells. These techniques have been discussed above in greater detail in connection with multicolor additive primary imaging.

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In the foregoing discussion of the image transfer film unit 1500 silver halide emulsion is positioned in the reaction microcells 1508 and silver precipitating agent is located in the silver reception layers 1556. Unique and unexpected advantages can be achieved by reversing this relationship. For example, the layer 1556 can be comprised of a panchromatically sensitized silver halide emulsion while the microcells 1508 (or a layer overlying the microcells, not shown) can contain a silver precipitating agent, the remaining components of the microcells being unchanged.

Assuming for purposes of illustration a negative-working silver halide emulsion in a posi-20 tive-working image transfer system, upon imagewise exposure through the support 1502, silver halide is rendered developable in the lightstruck areas of the emulsion layer. Upon release of the aqueous alkaline processing solution containing silver halide 25 solvent, unexposed silver halide is solubilized and migrates to the adjacent microcells where silver precipitation occurs. In the image transfer film unit 1500 a projectable positive additive primary image is obtained in the support 1502 (which is now 30 an image-receiving rather than the image-generating portion of the element). A portion of the imaging dye can be retained in the microcells to supplement the precipitated silver in providing a neutral density in the unexposed microcells. The portion of 35 the imaging dye not retained in the microcells is, of course, immobilized by the layer 1552 and forms a multicolor subtractive primary positive transferred dye image. Oxidized developing agent scavenger is

preferably located in the microcells 1508 to reduce dye stain and facilitate dye transfer. The emulsion layer 1556, the support 1502 and the contents of the microcells together form the image-generating portion of the element.

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One advantage of continuously coating the silver halide emulsion is that a single, panchromatically sensitized silver halide emulsion can be employed since the emulsion is entirely located 10 behind the filter dyes during exposure. Another important advantage is that the microcells in the support 1502 contain no light-sensitive materials in this form. This allows the relatively more demanding steps of filling the microcells to be performed in roomlight while the more conventional fabrication step of coating the emulsion as a continuous layer is performed in the dark. It is also apparent that the reaction microcells can be shallower when they do not contain silver halide emulsion, although this 20 is not essential.

Numerous additional structural modifications of the image transfer film units 1500 and 1600 are possible. For example, while the supports 1502 and 1602 have been shown, it is appreciated that 25 specific features of other support elements described above containing microcells can also be employed in combination, particularly pixels of the type shown in Figures 2, 3, 4 and 5, microcell arrangements as shown in Figures 6 and 7 and 30 lenticular support surfaces, as shown in Figure 10. Instead of the image-receiving portion disclosed in connection with element 1500 any convnetional image-receiving portion can be substituted which contains a spacing layer to permit lateral diffusion 35 of mobile subtractive primary dyes, such as those of the Land and Rogers patents, cited above. Instead of the image-receiving portion disclosed in connection with unit 1600 an image-receiving portion from

any conventional silver image transfer photographic element can be substituted. The dye immobilizing layer 1552 and the silver reception layer 1656 can both be modified so that the materials thereof are 5 located in microcells, if desired. In one specific form the layers 1552 and 1554 can both be present in microcells formed by the support 1550. microcells can be sized to overlie a plurality of the microcells 1508, thereby concurrently allowing 10 limited lateral image spreading while preventing uncontrolled lateral image spreading from occurring. For example the microcells in the support 1550 can correspond to the configuration of pixels The aqueous alkaline processing solution can 15 be introduced at any desired location between the supports 1502 and 1550 or 1602 and 1650, and one or more the layers associated with support 1550 or 1650 can be associated with support 1502 or 1602 instead. Any of the image transfer film units 20 discussed above in connection with Dye Transfer Imaging can be adapted to transfer multicolor dye images by overcoating the one image-forming layer unit required and specifically described with one or, preferably, two additional image-forming layer 25 units each capable of transferring a different subtractive primary dye. Any of the image transfer systems described above in connection with Dye Transfer Imaging can be employed in Multicolor Transfer Imaging, as herein described. The patents 30 cited in connection with Dye Transfer Imaging generally describe Multicolor Transfer Imaging as well. Finally, it is recognized that numerous specific features well known in the photographic arts can be readily applied or adapted to the 35 practice of this invention and for this reason are not specifically redescribed.

The multicolor image transfers systems of this invention can be further illustrated by refer-

ence to certain preferred dye image transfer systems. In one specific, illustrative form the image transfer film unit 1500 can contain (1) in a first set of microcells a blue filter dye or pigment and an initially colorless, mobile yellow dye-forming coupler, (2) in a second, interlaid set of microcells a green filter dye or pigment and an initially colorless, mobile magenta dye-forming coupler and (3) in a third, interlaid set of micro-10 cells a red filter dye or pigment and an initially colorless, mobile cyan dye-forming coupler. filter dyes and pigments can be selected from among any of those described above. The initially colorless, mobile dye-forming couplers can be selected 15 from those disclosed by Yutzy U.S. Patent 2,756,142, Greenhalgh et al U.K. Patents 1,157,501-'506 and Land U.S. Patents 2,559,643, 2,647,049, 2,661,293, 2,698,244 and 2,698,798, cited above. In a preferred form a panchromatically sensitized negative-20 working silver halide emulsion (not shown in Figure 15) is coated over the microcells. The layer 1556 contains a silver precipitating agent and an oxidized developing agent scavenger, the composition of which can take any of the forms described above.

The reflection and spacing layer 1554 can be a conventional titanium oxide pigment containing layer. The dye immobilizing layer 1552 contains an immobile oxidizing agent of the type described above.

The image transfer film unit 1500 so

constituted is first exposed imagewise through the transparent support 1502. Thereafter a processing composition containing a color developing agent and a silver halide solvent is released and uniformly spread in the space 1558. In exposed areas silver halide is developed producing oxidized color developing agent which couples with the dye forming coupler present to form an immobile dye. The filter dye or pigment, the immobile dye formed, and the

developed silver thus together increase the optical density of the microcells which are exposed.

In areas not exposed, the undeveloped silver halide is solubilized by the silver halide solvent and migrates to the layer 1556 where it is reduced to silver. Any oxidized developing agent produced in reducing the silver halide to silver immediately cross-oxidizes with the scavenger which is present with the silver precipitating agent in the layer 1556.

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At the same time mobile coupler is wandering from microcells which were not exposed. mobile coupler does not react with oxidized color developing agent in the layer 1556, since any 15 oxidized color developing agent present preferentially reacts with the scavenger. The coupler thus migrates through layer 1556 unaffected and enters reflection and spreading layer 1554. Because of the thickness of this layer, the mobile coupler is free 20 to wander laterally to some extent. Upon reaching the immobilizing layer 1552, the coupler reacts with oxidized color developing agent. The oxidized color developing agent is produced uniformly in this layer by interaction of oxidizing agent with the color 25 developing agent. Due to lateral diffusion in the spreading layer, superimposed immobile yellow, magenta and cyan dye images are formed in the immobilizing layer and can be viewed as a multicolor image through the transparent support (or cover 30 sheet) 1550 with the layer 1554 providing a white reflective background. At the same time, since only filter dye or pigment remains in the unexposed microcells, a useable additive primary negative transparency is formed by the support 1502.

To illustrate a variant system, a image transfer film unit as described immediately above can be modified by substituting for the initially colorless, mobile dye forming couplers initially

mobile dye developers. The dye developers are shifted in hue, so that the dye developer present in the microcells containing red, green and blue filters do not initially absorb light in the red,

- green and blue regions of the spectrum, respectively. Suitable shifted dye developers can be selected from among those disclosed by Rogers U.S. Patents 2,774,668 and 2,983,606, Idelson et al U.S. Patent 3,307,947, Dershowitz et al U.S. Patent
- 3,230,085, Cieciuch et al U.S. Patent 3,579,334, Yutzy U.S. Patent 2,756,142, Harison Defensive Publication T-889,017 and Bush et al U.S. Patent 3,854,945, cited above. A dye mordant as well as an oxidant can be present in the dye immobilizing layer
- 15 1552. Since the dye image forming material is itself a silver halide developing agent, a conventional activator solution can be employed (preferably containing an electron transfer agent). The remaining features can be identical to those
- 20 described in the preceding embodiment.

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Upon imagewise exposure and release of the activator solution, dye developer reacts with exposed silver halide to form an immobile subtractive primary dye which is a complement of the

- additive primary filter material in the exposed microcell. Thus the optical density of exposed microcells is increased, and a negative multicolor additive primary image can be formed in the support 1502 by the filter materials. Silver halide
- development is terminated by transfer of solubilized silver halide as has already been described. In unexposed areas unoxidized dye developer migrates to the immobilizing layer 1552 where it is immobilized to form a multicolor positive image. During
- processing the dye developers shift in hue so that they form subtractive primaries complementary in hue to the additive primary filter materials with which they are initially associated in the microcells.

That is, the red, green and blue filter material containing microcells contain dye developers which ultimately form cyan, magenta and yellow image dyes. Hue shifts can be brought about by the higher pH of processing, mordanting or by associating the image dye in the receiver with a chelating material.

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Instead of using shifted dye developers as described above, initially mobile leuco dyes can be employed in combination with electron transfer 10 agents to produce essentially similar results. Since the leuco dyes are initially colorless, hue shifting does not have to be undertaken to avoid competing light absorption during imagewise exposure. The leuco dyes are converted to subtractive primary imaging dyes upon oxidation in the dye immobilizing layer. Mordant in the layer 1552 holds the dyes in place. Suitable initially mobile leuco dyes can be selected from among those disclosed by Lestina et al U.S. Patents 3,880,658, 3,935,262 and 20 3,935,263, Cohler et al U.S. Patent 2,892,719, Corley et al U.S. Patent 2,992,105 and Rogers U.S. Patents 2,909,430 and 3,065,074, cited above. The remaining features can be identical to those described in the preceding embodiment.

25 Instead of employing initially mobile dyes or dye precursors as described above, it is possible to employ initially immobile materials. specific preferred form benzisoxazolone precursors of hydroxylamine dye-releasing compounds are 30 employed of the type disclosed by Hinshaw et al U.K. Patent 1,464,104 and Research Disclosure, Vol. 144, April 1976, Item 14447. Upon crossoxidation in the microcells with oxidized electron transfer agent produced by development of exposed silver halide, release of mobile dye is prevented. In areas in which silver halide is not exposed and no oxidized electron transfer agent is produced mobile dye release occurs. The dye image providing compounds

are preferably initially shifted in hue to avoid competing absorption during imagewise exposure. Mordant immobilizes the dyes in the layer 1552. No oxidant is required in this layer in this embodiment. Except as indicated, this element and its function is similar to the illustrative embodiments described above.

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Each of the illustrative embodiments described above employ positive-working dye image 10 providing compounds. To illustrate a specific embodiment employing negative-working dye image providing compounds, a first set of microcells 1508 can contain a blue filter dye or pigment, a silver precipitating agent and a redox dye-releaser 15 containing a yellow dye which is shifted in hue to avoid absorption in the blue region of the spectrum prior to processing. In like manner a second, interlaid set of microcells contain a green filter dye or pigment, the silver precipitating agent and a 20 redox dye-releaser containing an analogously shifted magenta dye, and a third, interlaid set of microcells containing a red filter dye or pigment, the silver precipitating agent and a redox dye-releaser containing an analogously shifted cyan dye. 25 microcells are overcoated with a panchromatically sensitized silver halide emulsion layer containing an oxidized developing agent scavenger (not shown in Figure 15). The silver precipitating layer 1556 shown in Figure 15 is not present. The reflection 30 and spreading layer is a white titanium oxide pigment layer. The dye immobilizing layer 1552 contains a mordant. In a preferred form the redox dye-releasers are compounds containing a dye linked through an oxidizable sulfonamido group, such as 35 those illustrated by Fleckenstein U.S. Patents 3,928,312 and 4,053,312, Fleckenstein et al U.S. Patent 4,076,529, Melzer et al U.S. Patent 4,100,113, Degauchi U.S. Patent 4,199,892, Koyama et

al U.S. Patent 4,055,428, Vetter et al U.S. Patent . 4,198,235 and Kestner et al Research Disclosure, Vol. 151, November 1976, Item 15157, cited above. Any of the techniques described above for shifting the hue of the dye can be employed.

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The image transfer film unit is imagewise exposed through the transparent support 1502. A processing solution containing an electron transfer agent and a silver halide solvent is spread between 10 the image generating and the image receiving portions of the element. In a preferred form the pH of the processing solution causes the redox dye-releasers to shift to their desired image-forming hues. In areas in which silver halide is 15 exposed oxidized electron transfer agent produced by development of exposed silver halide immediately cross-oxidizes with the scavenger. Thus, in microcells corresponding to exposed silver halide the redox dye-releasers remain in their initially 20 immobile form. In areas in which silver halide is not exposed, silver halide solvent present in the processing solution solubilizes silver halide allowing it to wander into the underlying microcells. In the microcells physical devlopment of 25 solubilized silver halide occurs producing silver and oxidized electron transfer agent. The oxidized electron transfer agent interacts with the redox dye-releaser to release mobile dye which is transferred to the layer 1552and immobilized by the 30 mordant. A multicolor positive transferred image is produced in the layer 1552 comprised of yellow, magenta and cyan transferred dyes. A multicolor positive retained image can also be produced, since (1) the silver density produced by chemical develop-35 ment in the emulsion layer is small compared to the silver density produced by physical development in the microcells and (2) with the image-generating

portion separated from the image-receiving portion

the redox dye-releasers remaining in their initial condition in the microcells can be uniformly reacted with an oxidizing agent to release mobile dye which can be removed from the microcells by washing.

5 In presently commercially available color image transfer image transfer film units, the image transfer film unit is ejected from the camera before formation of the color image is completed. image transfer film units 1500 and 1600 in the 10 variant forms disclosed above can be ejected from a camera before internal processing is complete only if they are protected from room light. For example, the transparent supports 1502 and 1602 can have a black layer associated therewith to permit early 15 room light handling. The layers 1554 and 1654, which prevent light exposure from occurring through the transparent cover sheets 1550 and 1650, can optionally be supplemented by a black layer located behind the white reflecting layer. When so 20 protected, the elements can produce transferred multicolor images which are accessible in very short time periods, since the dye diffusion paths are short as compared with conventional image transfer element diffusion paths. The transferred image can 25 in one form be viewed through a window provided in a camera while protecting the support containing the

camera while protecting the support containing the microcells from light exposure while processing is being completed.

Whereas presently commercially available

whereas presently commercially available
color image transfer film units are of comparatively
large format, thereby requiring that the cameras be
rather large and bulky, the present image transfer
film units, though useful in these large formats,
are particularly suited for smaller formats, such as
the 110 and 135 film sizes. In employing the image
transfer film units of this invention in small
formats, the retained image, which is preferably a
negative image, is the primary photographic image of

interest. The retained negative image can be readily employed to produce multicolor enlarged positive prints. The small format transferred multicolor positive image can be employed primarily to give the photographer instant assurance that he or she has obtained the desired photographic image. Because of the small format, the added cost of providing transferred multicolor image in addition to a useful negative multicolor image is relatively small.

The multicolor image transfer elements of this invention can be employed in either peel apart or integral forms. In one specifically contemplated form, the image receiving portion of each element 15 can be peeled from the image generating portion in the camera. The image generating portion is retained for later use and/or silver reclamation. The image receiving portion can have the appearance of a conventional color print. For instance, the 20 receiving portion support can be white resin coated paper support bearing a mordant or oxidant containing layer which provides the multicolor dye image. The image generating portion will then contain any required silver reception layer and any lateral 25 image spreading layer as well as the support containing the microcells and any overcoated radiation-sensitive emulsion layer.

Intracell Multicolor Transfer Imaging

In Figures 15 and 16 image transfer film

units are illustrated in which some, but not all of the imaging components are present in microcells. There are advantages to be realized by confining all of the components contributing to forming an image within each pixel area within a separate microcell.

Such an arrangement can be illustrated in Figure 17 by image transfer film unit 1700. A support is shown formed of a planar transparent first support element 1702 and a second support element 1704. The

first support element forms the bottom walls 1706 of a plurality of microcells 1708 while the second support element forms the lateral walls 1710 of the microcells.

5 Within each microcell adjacent the bottom wall is located a mordant layer 1712. A permeable reflecting layer 1714 overlies the mordant layer. Red, green, and blue recording silver halide emulsion layer units 1716, 1718, and 1720, respectively, 10 overlie the reflecting layer. The red, green, and blue recording emulsion layer units are each capable of releasing a corresponding cyan, magenta, or yellow dye as a function of exposure. The emulsion layer units, including the dye associated therewith, 15 can be constructed similarly as in any conventional multicolor dye image transfer film unit. At least one of the emulsion layer units and preferably all employ high aspect ratio tabular grain silver halide emulsions.

20 In use the image transfer film unit can be imagewise exposed through the transparent cover sheet 1750 or with the transparent cover sheet removed. Processing liquid is then released between the cover sheet and the support elements. At this 25 time the cover sheet is pressed against the upper surface of the lateral walls 1710. In the form shown the lateral walls extend sufficiently above the uppermost emulsion unit to form a reservoir for the processing liquid. Depending upon the rate at 30 which the processing liquid is capable of penetrating the emulsion units, this may or may not be necessary. By confining the processing liquid within each microcell lateral migration of mobile dye or other materials between adjacent microcells 35 is prevented, thereby contributing to image sharpness. Mobile dye migrates from the emulsion units to the mordant layer as a function of exposure and can be viewed through the transparent first support

element. Although not shown, timing layers to terminate development can also be included. For example, a timing layers can be coated on the major face of the cover sheet adjacent the support.

It can be seen that the image transfer film unit 1700 is in reality made up of a large number of independent image transfer film units each corresponding to one microcell or pixel of the total unit. The effect is to limit lateral spreading 10 effects that can interfere with image definition in units wherein imaging dyes migrate beyond individual microcells. It is recognized that image transfer film unit 1700 is only illustrative of a variety of variant units which can be constructed sharing at 15 least some of the advantages of unit 1700. Although unit 1700 is intended to form transferred dye images, it is realized that a similar approach can be taken also in forming transferred silver images.

While the foregoing is intended to point 20 out certain illustrative embodiments of the invention, it is appreciated that numerous additional variant forms of the invention will readily occur to those skilled in the art.

Preparation Techniques

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25 One preferred technique according to this invention for preparing microcell containing supports is to expose a photographic element having a transparent support in an imagewise pattern, such as illustrated in Figures 1A, 6, 7 and 8. 30 preferred form the photographic element is negative-working and exposure corresponds to the areas intended to be subtended by the microcell areas while the areas intended to be subtended by the lateral walls are not exposed. By conventional 35 photographic techniques a pattern is formed in the element in which the areas to be subtended by the microcells are of a substantially uniform maximum density while the areas intended to be subtended by

the lateral walls are of a substantially uniform minimum density.

The photographic element bearing the image pattern is next coated with a radiation-sensitive 5 composition capable of forming the lateral walls of the support element and thereby defining the side walls of the microcells. In a preferred form the radiation-sensitive coating is a negative-working photoresist or dichromated gelatin coating. coating can be on the surface of the photographic element bearing the image pattern or on the opposite surface--e.g., for a silver halide photographic element, the photoresist or dichromated gelatin can be coated on the support or emulsion side of the 15 element. The photoresist or dichromated gelatin coating is next exposed through the pattern in the photographic element, so that the areas corresponding to the intended lateral walls are exposed. results in hardening to form the lateral wall 20 structure and allowing the unexposed material to be removed according to conventional procedures well known to those skilled in the art. For instance, these procedures are fully described in the patents cited above in connection with the description of 25 photoresist and dichromated gelatin support materials.

The image pattern is preferably removed before the element is subsequently put to use. For example, where a silver halide photographic element is exposed and processed to form a silver image pattern, the silver can be bleached by conventional photographic techniques after the microcell structure is formed by the radiation-sensitive material.

If a positive-working photoresist is

35 employed, it is initially in a hardened form, but is
rendered selectively removable in areas which
receive exposure. Accordingly, with a positiveworking photoresist or other radiation-sensitive

material either a positive-working photographic . element is employed or the sense of the exposure pattern is reversed. If an exposure blocking pattern is present in or on the support correspond-5 ing to the lateral walls forming the microcells, this pattern need not be removed for many applications and can even take the place of increasing the optical density of the lateral walls forming the microcells in many instances. Instead of coating 10 the radiation-sensitive material onto a support bearing an image pattern, such as an image-bearing photographic element, the radiation-sensitive material can be coated onto any conventional support and imagewise exposed directly rather than through 15 an image pattern. It is, of course, a simple matter to draw the desired pixel pattern on an enlarged or macro-scale and then to photoreduce the pattern to the desired scale of the microcells for purposes of exposing the photoresist.

20 Another technique which can be used to form the microcells in the support is to form a plastic deformable material as a planar element or as a coating on a relatively nondeformable support element and then to form the microcells in the 25 relatively deformable material by embossing. An embossing tool is employed which contains projections corresponding to the desired shape of the microcells. The projections can be formed on an initially plane surface by conventional techniques, 30 such as coating the surface with a photoresist, imagewise exposing in a desired pattern and removing the photoresist in the areas corresponding to the spaces between the intended projections (which also correspond to the configuration of the lateral walls 35 to be formed in the support). The areas of the embossing tool surface which are not protected by photoresist are then etched to leave the projections. Upon removal of the photoresist overlying

the projections and any desired cleaning step, such as washing with a mild acid, base or other solvent, the embossing tool is ready for use. In a preferred form the embossing tool is formed of a metal, such as copper, and is given a metal coating, such as by vacuum vapor depositing chromium or silver. The metal coating results in smoother walls being formed during embossing.

Still another technique for preparing 10 supports containing microcells is to form a planar element, such as a sheet or film, of a material which can be locally etched by radiation. material can form the entire element, but is preferably present as a continuous layer of a thickness 15 corresponding to the desired depth of the microcells to be formed, coated on a support element which is formed of a material which is not prone to radiation etching. By irradiation etching the planar element surface in a pattern corresponding to the microcell 20 pattern, the unexposed material remaining between adjacent microcell areas forms a pattern of interconnecting lateral walls. It is known that many dielectric materials, such as glasses and plastics, can be radiation etched. Cellulose nitrate and 25 cellulose esters (e.g., cellulose acetate and cellulose acetate butyrate) are illustrative of plastics which are particularly preferred for use. For example, coatings of cellulose nitrate have been found to be virtually insensitive to ultraviolet and 30 visible light as well as infrared, beta, X-ray and gamma radiation, but cellulose nitrate can be readily etched by alpha particles and similar fission fragments. Techniques for forming cellulose coatings for radiation etching are known in the art 35 and disclosed, for example, by Sherwood U.S. Patent 3,501,636, here incorporated by reference.

The foregoing techniques are well suited to forming transparent microcell containing supports, a

variety of transparent materials being available satisfying the requirements for use. Where a white support is desired, white materials can be employed or the transparent materials can be loaded with 5 white pigment, such as titania, baryta and the like. Any of the whitening materials employed in conjunction with conventional reflective photographic supports can be employed. Pigments to impart colors other than white to the support can, 10 of course, also be employed, if desired. Pigments are particularly well suited to forming opaque supports which are white or colored. Where it is desired that the support be transparent, but tinted, dyes of a conventional nature are preferably incor-15 porated in the support forming materials. For example, in one form of the support described above the support is preferably yellow to absorb blue light while transmitting red and green.

above the portion of the support forming the bottom walls of at least one set of microcells, generally all of the microcells, is transparent, and the portion of the support forming the lateral walls is either opaque or dyed to intercept light trans
25 mission therethrough. As has been discussed above, one technique for achieving this result is to employ different support materials to form the bottom and lateral walls of the supports.

A preferred technique for achieving dyed

1 lateral walls and transparent bottom walls in a support formed of a single material is as follows: A transparent film is employed which is initially unembossed and relatively nondeformable with an embossing tool. Any of the transparent film-forming materials more specifically described above and known to be useful in forming conventional photographic film supports, such as cellulose nitrate or ester, polyethylene, polystyrene, poly(ethylene)

terephthalate) and similar polymeric films, can be employed. One or a combination of dyes capable of imparting the desired color to the lateral walls to be formed is dissolved in a solution capable of softening the transparent film. The solution can be a conventional plasticizing solution for the film. As the plasticizing solution migrates into the film from one major surface, it carries the dye along with it, so that the film is both dyed and softened along one major surface. Thereafter the film can be embossed on its softened and therefore relatively deformable surface. This produces microcells in the film support which have dyed lateral walls and transparent bottom walls.

15 Instead of solvent embossing as described above, thermal embossing can be undertaken. According to this procedure a layer formed of a thermoplastic material, such as polymer, is heated to its glass transition temperature and then embossed. 20 thermoplastic material can contain a dye or pigment to impart the desired density to the lateral walls of the microcells so formed. The layer of thermoplastic material can form the entire support, being embossed to a depth less than its original thickness. Preferably the thermoplastic material layer is coated over a separate bottom wall forming support material layer. In a specifically preferred form the bottom wall forming support material is a photoconductive material as exemplified below. In 30 this case the thermoplastic material is chosen to have a glass transition temperature in the range of from about 40 to 120°C. Optimization of thermal embossing for specific thermoplastic materials and microcell sizes can be achieved by routine inves-35 tigation.

In some forms of the invention described above it is desirable for the walls of the microcells to be reflective. This can be achieved by

coating the embossing tool with reflective material. Upon embossing the reflective material transfers from the embossing tools to the support. In a specific illustrative form, a silver amalgam, such as employed in silvering mirrors, can be coated on the embossing tool and transferred to the walls of the microcells.

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Once the support with microcells therein is formed, material forming the radiation-sensitive 10 portion of the photographic element, or at least one component thereof, can be introduced into the microcells by doctor blade coating, solvent casting or other conventional coating techniques. Identical or analogous techniques can be used in forming 15 receiver or filter elements containing microcells. Other, continuous layers, if any, can be coated over the microcells, the opposite support surface or other continuous layers, employing conventional techniques, including immersion or dip coating, 20 roller coating, reverse roll coating, air knife coating, doctor blade coating, gravure coating, spray coating, extrusion coating, bead coating, stretch-flow coating and curtain coating. High speed coating using a pressure differential is 25 illustrated by Beguin U.S. Patent 2,681,294. Controlled variation in the pressure differential to facilitate coating starts is illustrated by Johnson U.S. Patent 3,220,877 and to minimize splicing disruptions is illustrated by Fowble U.S. Patent 30 3,916,043. Coating at reduced pressures to accelerate drying is illustrated by Beck U.S. Patent 2,815,307. Very high speed curtain coating is illustrated by Greiller U.S. Patent 3,632,374. or more layers can be coated simultaneously, as 35 illustrated by Russell U.S. Patent 2,761,791, Wynn U.S. Patent 2,941,898, Miller et al U.S. Patent 3,206,323, Bacon et al U.S. Patent 3,425,857, Hughes

U.S. Patent 3,508,947, Herzhoff et al U.K. Patent

1,208,809, Herzhoff et al U.S. Patent 3,645,773 and Dittman et al U.S. Patent 4,001,024. In simultaneous multilayer coating varied coating hoppers can be used, as illustrated by Russell et al U.S. Patent 2,761,417, Russell U.S. Patents 2,761,418 and 3,474,758, Mercier et al U.S. Patent 2,761,419, Wright U.S. Patent 2,975,754, Padday U.S. Patent 3,005,440, Mercier U.S. Patent 3,627,564, Timson U.S. Patents 3,749,053 and 3,958,532, Jackson U.S.

Patent 3,993,019 and Jackson et al U.S. Patent 3,996,885. Silver halide layers can also be coated by vacuum evaporation, as illustrated by Lu Valle et al U.S. Patents 3,219,444 and 3,219,451. Materials to facilitate coating and handling can be employed

in accordance with conventional techniques, as illustrated by Research Disclosure, Vol. 176, December 1978, Item 17643, paragraphs XI and XII.

In some of the embodiments of the invention described above a multicolor photographic element or filter element is to be formed which requires an interlaid pattern of microcells which are filled to differ one from the other. Usually it is desired to form an interlaid pattern of at least three different microcell confined materials. In order to fill one microcell population with one type of material while filling another remaining microcell population with another type of material at least two separate coating steps are usually employed and some form of masking is employed to avoid filling the remaining microcell population with material intended for only the first microcell population.

One technique that has been proposed for filling three separate sets of microcells each with a different material is to form the separate sets of microcells one at a time and fill that set of microcells before forming another set. For example, a planar support in which it is intended to form interlaid first, second, and third sets of micro-

cells containing first, second, and third imaging materials, respectively, is first embossed to form only the first set of microcells. Thereafter the first set of microcells is filled with the first imaging material. There is no risk of including first imaging material in other microcells, since they are not yet formed. If desired, the first set of microcells can be sealed after being loaded with the first imaging material to assure that no migra-10 tion of this material occurs. A thin hydrophilic colloid coating can perform the sealing function.

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The second set of microcells is then embossed in the support interlaid with but offset from the first set of microcells. The second set of 15 microcells is then loaded with the second imaging material. Since only the second set of microcells is empty to receive the second imaging material, there is no difficulty in directing this material to this set of microcells. If desired, third or even 20 additional sets of microcells can be similarly formed and loaded. Care must, of course, be exercised to register second and subsequent embossings with prior embossings so that they are properly laterally related.

25 One preferred technique for selectively filling microcells to form an interlaid pattern of two or more differing microcell populations is to fill the microcells on at least one major surface of the support with a material which can be selectively 30 removed by localized exposure without disturbing the material contained in adjacent microcells. A preferred material for this purpose is one which will undergo a phase change upon exposure to light and/or heating, preferably a material which is 35 readily sublimed upon moderate heating to a temperature well below that at which any damage to the support occurs. Sublimable organic materials, such as naphthalene, and para-dichlorobenzene are well

suited for this use. Certain epoxy resins are also recognized to be suitable. However, it is not necessary that the material sublime. For example, the support microcells can be initially filled with water which is frozen and selectively thawed. It is also possible to fill the microcells with a positive-working photoresist which is selectively softened by exposure. The softened photoresist can be washed out of the microcells on development.

10 Another approach for selectively emptying one set of microcells to permit selective loading involves the selective mechanical removal of an initially present material from one set of microcells to be loaded. This can be accomplished by initially introducing into all of the microcells a fluid material, such as a finely particulate or liquid material, and thereafter fusing the material into a solid mass by radiation exposure and/or heating. Selective removal of material from the 20 microcells containing either fused or unfused material can then be achieved by applying an adhesive cover sheet to the major face of the support toward which the microcells open. By proper choice of materials it is possible (1) to have the fused 25 material adhere to the adhesive cover sheet in preference to the microcell walls while the unfused material remains in the microcells or (2) to have the unfused material adhere to the cover sheet while the fused material adheres to the microcell walls. 30 In the former instance repetition of the process can

30 In the former instance repetition of the process can be undertaken to remove fused material to fill second and third sets of microcells in sequence. In the latter instance an alternative approach must be employed for removing the fused material to permit loading of the microcells in which it is contained and the microcells containing unfused material have been emptied by stripping the cover sheet and selectively loaded with imaging material. Thus, a

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wide range of materials which sublime, melt or exhibit a marked reduction in viscosity upon exposure can be employed.

According to a preferred exposure technique 5 a laser beam is sequentially aimed at the microcells forming one population of the interlaid pattern. This is typically done by known laser scanning techniques, such as illustrated by Marcy U.S. Patent 3,732,796, Dillon et al U.S. Patent 3,864,697 and 10 Starkweather et al U.S. published patent application B309,860. According to one specific, preferred technique two lasers are employed. One of the lasers is of sufficient intensity to provide the desired alteration with the microcells. The second 15 laser is used only to position accurately the first laser and can differ in wavelength and can be of lesser intensity. The first and second laser beams are laterally displaced in the plane of the support by an accurately determined distance. By employing 20 a photodetector to receive light transmitted through or reflected from the support from the second laser, it can be determined when a microcell or a lateral wall is aligned with the second laser beam. preferred form, in which the support bottom walls 25 are substantially transparent and the lateral walls are dyed, a substantial change in light intensity sensed by the photodetector will occur as a function of the relative position of the support and laser In other instances differences in reflection 30 or refraction between the bottom and lateral walls forming the microcells can be relied upon to provide information to the photodetector. Once the position of the second laser with respect to a microcell is ascertained, the position of the first laser with 35 respect to a microcell can also be ascertained, since the spacing between the lasers and the center-to-center widths of the microcells are known. Depending upon the pattern and accuracy of

exposure desired, indexing with the second laser can

be undertaken before exposing each microcell with
the first laser, only once at the beginning of
exposure of one microcell population, or at selected
intermediate intervals, such as before each row of
microcells of one population is exposed.

When a first laser scan is completed, the support is left with one exposed microcell population while the remaining microcells are substantially undisturbed. Instead of sequentially laser exposing the microcells in the manner indicated, exposure through a mask can be undertaken, as is well known. Laser scanning exposure offers the advantages of eliminating any need for mask preparation and alignment with respect to the support prior to exposure.

Where sublimable material is employed as an initial filler, the microcells are substantially emptied during their exposure. Where the filler 20 material is converted to a liquid form, the exposed microcells can be emptied after exposure with a vacuum pickup. The empty microcell population can be filled with imaging and/or filter materials using conventional coating techniques, as have been 25 described above. The above exposure and emptying procedure is then repeated at least once, usually twice, on different microcells. Each time the microcells emptied are filled with a different material. The result is two, usually three, or more 30 populations of microcells arranged in an interlaid pattern of any desired configuration. An illustrative general technique, applied to filling microcells in a gravure plate, is described in an article by D. A. Lewis, "Laser Engraving of Gravure 35 Cylinders", Technical Association of the Graphic Arts, 1977, pp. 34-42, here incorporated by reference.

One alternative specifically preferred method of introducing imaging materials on the supports at the desired locations is to move the support past a coating zone at a substantially constant velocity. At the same time a stream (or jet) of substantially equally sized and spaced drops of liquid containing imaging material is directed to the support.

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It is desirable, for stable drop formation 10 break-up of the liquid jet, that photographic liquids utilized in accordance with the present invention have a relatively high surface tension characteristic and a relatively low viscosity characteristic. Thus aqueous solutions or suspen-15 sions are one preferred form of photographic liquid for use in the present invention. However other liquids, e.g. containing organic liquids can be utilized if system parameters such as liquid surface tension, liquid density, liquid viscosity and liquid 20 jet diameter are properly adjusted. That is, higher liquid surface tension and larger jet diameters facilitate the use of more viscous liquids. Temperature of the photographic liquid also can be regulated to control liquid viscosities. It is prefer-25 red that liquid viscosity be below about 5 centipoise; however, high viscosity liquids are useful in systems particularly designed to accommodate them. Also, in embodiments of the invention employing electrically charged liquid drops, it is desirable 30 that the liquid have resistivity in the range of about 100 to 5000 ohm-cm. However, other liquid resistivities are useful. Further background regarding useful parameters of the kind described above can be found in the literature pertaining to 35 inks for ink jet printing.

Referring now to Fig. 18, next will be described preferred modes for depositing such photographic liquids on such photographic supports

in accordance with the present invention. Figure 18 illustrates a web of support material 30 having many discrete microcells, covering its upper surface (only three are shown). The support material 30 is moving in the direction indicated, from an upstream position to coating zones that are located under liquid jet generator means, denoted generally 31, 32 and 33.

The jet generator means, in general, can be

10 one of the many kinds now known in the art of ink
 jet printing, which is currently in active develop ment. Typically such generator means fall in one of
 two broad classes, "on-demand" or "continuous."

On-demand generators can be of an electrostati
15 cally-gated type wherein a drop is formed at a
 nozzle under low pressure (so that surface tension
 forces retain it) and released by application of a
 high voltage between the drop meniscus and a gating
 electrode (see e.g. U.S. Patent 2,600,129).

20 On-demand generators also can be of the pressure pulsed type which utilize a transducer element, e.g.
 a piezoelectric crystal, that is selectively ener gized to generate compressive force on a body of

gized to generate compressive force on a body of liquid to thus propel a drop of the liquid through an orifice to a deposition zone. Exemplary pressure-pulsed generators are disclosed e.g. in U.S. Patents 3,840,758 and 3,857,049. Although the on-demand jet generators are useful in accordance with the present invention, the "continuous" type jet generator is preferred and generator means 31, 32 and 33 shown in Fig. 18 are of this continuous type.

In general, continuous drop stream generators comprise a nozzle, or array of nozzles,

through which liquid is forced under pressure in a cylindrical jet. Such a cylindrical jet is unstable and will break up into a series of drops. If the jet is subject to a vibration of frequency near that

corresponding to the fastest growing natural disturbance within the jet (Rayleigh calculated this to be $\lambda = 4.51 \times \text{the jet diameter}$), the jet can be broken up by this vibration. In this mode the jet forms a series of drops, each of volume equal to a cylindrical section of the jet, which will be the length of the impressed vibration wavelength.

Thus drop stream generators 31, 32 and 33 each respectively comprise a manifold and nozzle array (35, 36 and 37), an electro-mechanical transducer (41, 42 and 43) for impressing vibrations on the nozzle array and a supply (45, 46 and 47) of pressurized photographic imaging liquid for coating on the support 30. Exemplary configurations useful for such droplet generators are shown in more detail in U.S. Patents 3,373,437; 3,596,275; 3,586,907; 3,701,476; 3,701,998; 3,714,928; 3,739,393; 3,805,273 and 3,836,913.

In the usual ink jet generators, including

those described in the previously cited patents, an electrostatic charge is impressed on drops as they break from the stream, and electrical deflection fields are provided along the drop stream path to guide the charged drops to the desired destination.
In the Fig. 18 embodiment, voltage sources V₁, V₂ and V₃ provide potential to charge the drops, and lines L₁, L₂ and L₃ selectively energize deflector plates under the control of logic unit 40. Although drop charging and field deflection are utilized in the subsequently described liquid jet coating method, it will be understood that in other preferred embodiments according to the present

Thus, support 30 is moved, as indicated in Fig. 18, at substantially constant velocity past the coating stations beneath drop generators 31, 32 and 33, in the direction D indicated in Figs. 1 and 3. As successive portions of the support move sequen-

invention, drop deflection is not required.

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tially past the coating stations, drop streams are directed onto predetermined sites of those portions, i.e. into predetermined microcells within those portions. That is, the rate of drop generation, the sequence of drop deflection and the velocity of movement of the support past the coating zone are synchronized so that drops from generator 31 are deposited in a first set of microcells of the support, the drops from generator 32 are deposited in a second set of microcells of the support and the drops from generator 33 are deposited in a third set of microcells of the support.

More specifically, consider the drop stream from generator 31, which is supplied with photo-15 graphic coating liquid from supply 45. The orifices of the nozzle array and liquid pressure (thus jet velocity) are chosen so that the drop size and rate are compatible with the size and pitch P of the first set of microcells of the support and the selected velocity of web movement. Logic unit 40 will therefore impress a frequency on the array causing drop generation at a rate "r" that is equal to the support velocity V divided by the intercell pitch of the microcells in the direction of support 25 movement D. Drop generators 32 and 33 function under control of logic unit 40 in a similar manner to deposit other photographic coating liquids in the remaining microcell groups of the support 30.

To obtain proper synchronization of the

transducers 41, 42 and 43 with the microcells on the
moving support 30 (and to maintain synchronization
in the event of microcell pitch variation or support
velocity fluctuation), a control unit 50 is located
upstream from the coating zones. In its simplest

form unit 50 can comprise a detector which identifies microcell positions and signals of the logic
unit 40 dynamically in accord therewith. As illustrated in Fig. 18, the control unit 50 comprises a

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laser 51 whose light beam is scanned by acoustooptic deflector 52 across the surface of a lens array 53 (e.g. fiber optics) adapted to direct light through the support to collector array 54. The collector array directs the scanned light to detector 55 which thus provides logic unit 40 with the microcell line positions and indications of any deviation in microcell position transversely across the support. If desired, selected logic corrections can be applied to individual deflector plates of the generator arrays to correct for transverse variations.

To further enhance the precision of drop deposit in the microcells, several additionally 15 preferred modes of operation can be utilized in cooperation with the method just described. at a location upstream from the coating zones electrostatic charging station 60 can provide a charge (of the same polarity as the droplet charge) 20 on the top surface of the microcell walls. In the illustrated embodiment station 60 comprises conductive rollers 61 and 62 and voltage source 63 for creating a potential of proper polarity on roller Thus e.g. a negative charge on cell wall tops 25 will deflect the negatively charged drops toward the center of the microcell. This electrostatic guidance is further enhanced by creating a positive bias on the microcell bottoms which attracts the positively charged drops. Positively biased rollers 30 65, 66, 67 provide this effect.

Another preferred droplet guidance enhancement procedure, useful in cooperation with the present invention, is illustrated by pre-coating station 70. There a roller 71 applies to the top of the cell walls, from supply 72, a layer of material to which the photographic coating liquids are hydrophobic. Thus, the photographic coating drops seek the relatively hydrophilic microcell interiors

in preference to the tops of cell walls. One skilled in the art will appreciate that if the photographic coating liquid "prefers" a hydrophobic surface, the microcells can be relatively hydrophobic.

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To avoid unwanted disturbance of the droplet's flight, it is preferred in accordance with the present invention to evacuate the atmosphere along the path from generators 31, 32 and 33 to the support. This can be accomplished by conventional means (not shown).

One skilled in the art will appreciate that various modifications of the specifically disclosed procedure are within the scope of the invention.

15 For example, it would be equivalent to move the drop generator instead of the support or to move both to provide a predetermined relative velocity. Also it will be appreciated that the present invention has utility in coating supports which do not have cell walls.

Another specifically preferred approach for loading one set of mircrocells or microcells with one imaging material while loading a second set of microcells with another imaging material is to place 25 a physical closure over the microcells and thereafter selectively remove the closure from one set of microcells so that it can be loaded. When the first set of microcells is entirely filled by loading, the closure can be removed and the remaining microcells 30 loaded without any other step being required. Alternatively, when the first set of microcells are not entirely filled or when three or more sets of microcells are to be each filled with differing imaging materials, then the steps of closing and 35 selectively opening the microcells can be repeated.

Figures 19A through 19D illustrate the application of this method to the manufacture of an element containing three interlaid sets of micro-

cells each containing a different material or combination of materials.

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In Figure 19A the support 1902 is shown similar to supports described above. Adjacent the first major surface 1904 of the support is a membrane 1906. The membrane overlies and closes the microcells 1908 of the support. The membrane is comprised of or entirely formed of a film-forming organic polymer and is thin as compared to the 10 lateral walls 1910 of the support. The membrane is preferably of a thickness of from about 5 to 50 percent that of the lateral walls. The microcells preferably initially contain a readily removable thermal insulator, such as air, although any readily 15 removable material could be initially present.

While any convenient conventional technique can be employed for forming the membrane and locating it in the position shown in Figure 19A, in most instances the membrane will be about 0.2 to 1 micron 20 in thickness so that many approaches useful in forming thicker membranes will not be useful in forming or positioning the membrane 1906. In one specific preferred approach the membrane is formed by casting a film-forming polymer in a volatile 25 solvent on the surface of a liquid in which the polymer does not readily dissolve, such as water, contained in a reservoir. The film is allowed to at least partially set by solvent evaporation. protect the film from disturbances a floating frame 30 can be laid on the film, if desired. By slowly raising the support 1902 from within the reservoir to the surface of the water, the membrane can be positioned on the first major surface of the support in the desired position without endangering the integrity of the membrane. Any water initially trapped in the microcells will evaporate if the element is allowed to stand for a period of time.

The minimal thickness of the membrane allows both

air and water vapor to diffuse therethrough, so that in a period of time an element is produced as shown in Figure 19A having only air in the microcells. is appreciated that other volatile or highly

thermally nonconductive liquids can be substituted for water in providing a casting surface, if Instead of raising the support through the desired. water, the support can be simply laid on the dry upper surface of the membrane with the first major 10 surface of the support contacting the membrane.

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The next step of the process is to selectively open the microcells intended to form one of the interlaid sets. Any technique which allows one set of microcells to be opened selectively can be 15 employed. It is preferred to employ radiation striking the membrane to open the set of microcells. Any of the various techniques disclosed by Whitmore, such as the use of masks, can be employed. According to a preferred technique a 20 laser beam is sequentially aimed at the microcells forming one interlaid set. This is typically done by known laser scanning techniques, such as illustrated by Marcy U.S. Patent 3,732,796, Dillon et al U.S. Patent 3,864,697 and Starkweather et al

25 U.S. published patent application B309,860.

Following a specific, preferred technique two lasers are employed. One of the lasers is of sufficient intensity to provide the desired alteration of the membrane overlying the microcells. 30 second laser is used only to position accurately the first laser and can differ in wavelength and can be of lesser intensity. The first and second laser beams are laterally displaced in the plane of the membranes by an accurately determined distance. By employing a photodetector to receive light transmitted through or reflected from the support from the second laser, it can be determined when a microcell or a lateral wall is aligned with the

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second laser beam. In the illustrated preferred form, in which the support bottom walls are substantially transparent and the lateral walls are dyed, a substantial change in light intensity sensed by the 5 photodetector will occur as a function of the relative position of the support and laser beam. other instances differences in reflection or refraction between the bottom and lateral walls forming the microcells can be relied upon to provide infor-10 mation to the photodetector. Once the position of the second laser with respect to a microcell is ascertained, the position of the first laser with respect to a microcell can also be ascertained, since the spacing between the lasers and the center-to-center spacings of the microcells are known. Depending upon the pattern and accuracy of exposure desired, indexing with the second laser can be undertaken before exposing each microcell with the first laser, only once at the beginning of 20 exposure of one microcell set, or at selected intermediate intervals, such as before each row of microcells of one set is exposed.

When a first laser scan is completed, the support is left with one open microcell set while

25 the remaining interlaid microcell sets are substantially undisturbed. Instead of sequentially laser exposing the microcells in the manner indicated, exposure through a mask can be undertaken, as is well known. Laser scanning exposure offers the

30 advantages of eliminating any need for mask preparation and alignment with respect to the microcells prior to opening one microcell set.

When radiant energy from a laser or other source impinges on the membrane in one or more areas corresponding to one microcell or microcell set, the membrane is locally heated. It is specifically preferred to impinge radiant energy selectively over that portion of the membrane lying at or near the

center of the underlying microcell. Since the membrane is extremely thin, its heat capacity is low. That is, very little heat energy is required to raise its temperature. Thus, a laser beam, for 5 example, can quickly raise the temperature of the organic membrane to its decomposition point in a selected area overlying a microcell. Since the membrane is no more than half the thickness of the lateral walls and usually of much less thickness, 10 the lateral walls do not rise in temperature to the same extent as the membrane, even when both the membrane and support are formed of the same material. Being thicker, the lateral walls have a higher heat capacity, slowing their increase in 15 temperature. Second, if the radiant energy is confined to the area near the center of the underlying microcell, heat must be conducted laterally by the membrane to the lateral walls; but being very thin, the membrane is an inefficient thermal 20 conductor. Selective thermal destruction of the membrane can be enhanced by forming the support of a more thermally stable material, so that if the membrane and support should approach the same temperature, the membrane will still be selectively

It is specifically contemplated to employ a radiant energy source and membrane in combination which allows the membrane to absorb efficiently the radiant energy. The film-forming polymer composition can be modified by incorporating an ultraviolet absorber, dye, or infrared absorber. Independently, an absorption promoting material can be coated over the membrane once it is formed in place. For example, the membrane can receive a deposit of lamp black by being passed over an open flame to increase its absorption of radiant energy. In addition to increasing the radiant energy absorption by the membrane, the support can be chosen so that it is

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destroyed.

relatively nonabsorbing in the spectral region of the radiant energy.

From the foregoing it is apparent that, by selectively addressing areas of the membrane over-5 lying one set of microcells, it is possible to open selectively one set of microcells without affecting adjacent sets of microcells and without damaging the Thereafter, the opened set of microcells can be filled by any convenient conventional technique without filling the remaining microcells. This is illustrated by reference to Figure 19B, in which the membrane 1906 has been modified by the introduction of apertures 1912 corresponding to one underlying set of microcells. For purposes of illustration, the open set of microcells is shown to be filled with material forming the blue filter segments B.

In filling the open set of microcells, a technique is preferably chosen which places minimal 20 physical stress on the membrane. For example, in the form illustrated, an aqueous solution of blue dye or suspension of blue pigment can be introduced into the open set of microcells while placing only minimal stress on the remaining membrane. Upon 25 evaporation of water, the blue dye or pigment is left in the open set of microcells. Filling can be repeated, if desired, until the desired optical density of blue dye or pigment is obtained in the open microcells. This approach can be practiced 30 with any material or combination of materials desired to be placed in the microcells and any compatible volatile liquid. By proper choices of materials and liquids layering can be achieved within the microcells, if desired. In an alterna-35 tive form the filling material can take the form of a fine particulate which is gently brushed into the The particles, of course, have mean microcells. diameters substantially less than the width of the

microcells. The particles can, if desired, be fused in place. For example, many particulate materials will fuse simply by standing under conditions of high humidity. Fusion by mild heating is also contemplated.

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In Figure 19C a second, interlaid set of microcells is shown opened and filled to form green filter segments G. The techniques described above for opening and filling the first set of microcells can be repeated unchanged, except for the substitution of green filter material. When this stage of the process is reached, only discrete segments 1914 of the original membrane remain overlying the third, interlaid set of microcells.

To permit the third, interlaid set of microcells to be filled, the techniques described above for opening the first and second sets of microcells can be repeated, except that a red filter material is substituted. The product, as shown in Figure 19D, is the multicolor filter element 1102.

It will be apparent that the last set of microcells can be filled by a broader selection of techniques than the first and any intermediate sets of microcells. In opening the last set of micro-25 cells the techniques employed for removing the membrane need not be areally selective. example, in the specific embodiment illustrated, since the membrane can be entirely destroyed in opening the last set of microcells, it is not 30 necessary to address the membrane segments 1914 selectively with radiant energy. Rather, the element as shown in Figure 19C can be uniformly exposed to radiant energy to destroy the membrane segments 1914. Alternatively, the membrane segments 35 remaining can be removed by laminating it to a support to which it adheres in preference to the first major surface 104 and then simply lifting the membrane segments from the first major surface.

Adhesion of the membrane segments to another support can be accomplished by any one of a wide variety of conventional laminant transfer techniques.

It is not even necessary to remove the

membrane segments 1914 before filling. By employing filling techniques which are in themselves capable of destroying the membrane segments, the steps of opening and filling the last set of microcells can be combined. For example, by doctor blade coating the element as shown in Figure 19C with a red filter material, the membrane segments can be collapsed into the underlying microcells while leaving room for the red filter material to also enter the third set of microcells.

15 The foregoing microcell filling technique is particularly well suited to applications in which the microcells of each set, except the last, are intended to be substantially entirely filled. Thus, any material intended to be placed in a subsequent 20 set of microcells after the first set has been opened and filled cannot enter the first set of microcells, since material filling these microcells prevents additional material from entering. Any slight amount of material that may deposit above the 25 first, filled set of microcells in filling the second or subsequent sets can in many applications be ignored. Alternatively, the additional surface material can be removed by gently abrading the first major surface 104 of the support after all of the 30 microcells have been filled. For example, the major surface 1904 of the support can be swabbed or skived with a doctor blade to remove any materials over and above those which are contained in the microcells.

In a variant approach, which is particu
larly applicable to only partially filling the
microcells or maintaining a high degree of separation of materials being placed in separate sets of
microcells, after the first set of microcells are

opened and partially filled to the extent desired, a . second membrane is positioned over the first major surface of the support. If desired, the first membrane can be entirely removed before positioning the second membrane, as by using the laminant or destruction techniques described above. Where the membranes are comparatively thin, so that the multiple layers of membrane can still be thermally destroyed selectively without damaging the support 10 lateral walls, the second membrane can be positioned over the first, now apertured, membrane. and second membranes are then selectively destroyed in areas overlying the second set of microcells, so that these microcells can be at least partially 15 filled through the resulting apertures. Placement of the third membrane, if employed, follows the same techniques and considerations as for the first and second membranes. It is usually preferred that the last set of microcells be opened by the overlying 20 membrane or membranes being selectively addressed, thereby preserving the closure of the sets of microcells previously at least partially filled. Depending upon the desired application, any membrane(s) remaining after the last set of micro-25 cells have been selectively filled to the extent desired can either be left in place, destroyed, or transferred to a separate support, as has been described above.

In an alternative to the processes of

differentially filling microcells in interlaid sets described above, it is contemplated to place in all of the microcells prior to closure by a membrane at least one material that permanently remains in at least one interlaid set of microcells. The membrane closing the microcells is removed by any of the specific techniques described above in all areas, except those corresponding to the set of microcells in which initially present material is intended to

remain. Initially present material is then removed from the opened microcells. For example, a soluble material can be removed merely by bringing the element into contact with a solvent, as by spraying with or immersion in the solvent. Once at least one set of microcells have been emptied, a second material or combination of materials is placed in the emptied set of microcells.

The general procedure described above can 10 be illustrated by reference to forming the multicolor filter element 1102. A removable blue filter material, such as a blue filter dye that can be solubilized is initially introduced into microcells 1908 of the support 1902. The microcells are then 15 closed with a membrane 1906 so that the element appears similar to that of Figure 19A, but with the microcells each containing blue filter material. Thereafter, the interlaid second and third sets of microcells intended to contain green and red filter 20 materials, respectively, are opened by using any of the selective membrane removal techniques described above. Membrane segments similar to 1914 now overlie only the microcells in which the filter material is to be retained. The element can be 25 contacted with a solvent for the blue filter material, permitting it to be removed from the open second and third sets of microcells. The second and third sets of microcells can be now at least partially filled with a green filter material which 30 can be solubilized, and the second and third sets of microcells are closed with a second membrane. segments of the first membrane can be first removed or, preferably, left in place, since they do not affect the process. Using an essentially repetitive 35 procedure, the portions of the second membrane overlying the third set of microcells is selectively removed, and the green filter material is removed from the third set of microcells. The second

membrane remains intact closing the first and second sets of microcells, and the blue and green filter materials remain in place in these microcells. Red filter material can now be introduced into the third set of microcells.

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It is to be noted that, since the membranes protect the microcells containing the material desired to be retained, the green and blue microcells can be entirely or only partially filled with 10 material without any variation in the process. It is immaterial whether the red filter material can be solubilized or whether the red filter material entirely or partially fills the third set of microcells, since this has no effect on the process 15 steps. Once the third set of microcells are filled to the extent desired, any portion of the membrane left in place can be removed, if desired, depending upon the intended application for the element. Since air is an exceptionally good thermal insu-20 lator, it is preferred that the microcells be only partially filled with the blue and green filter materials to leave an air gap in the microcells separating the filter materials from the membranes; however, if the filter materials are good thermal 25 insulators, the increase in laser energy required in addressing entirely filled microcells can be tolerated.

The membranes positioned to close the microcells of the support are comprised of any 30 material which can be selectively destroyed or removed over an area corresponding to that subtended by an underlying microcell (or, in some instances, an underlying cluster of microcells). In general the membranes can be most conveniently formed of organic film-forming polymers. The membranes can be identical in composition to conventional photographic film supports. Typical film-forming polymers useful in forming membranes are cellulose

nitrate and cellulose esters, such as cellulose triacetate and diacetate, polyamides, homo- and co-polymers of styrene, acrylates and methacrylates. vinyl chloride, poly(vinyl acetal), and olefins, 5 such as ethylene and propylene. Where the membranes are intended to be thermally destroyed, as by impingement with a laser beam, the less thermally stable film-forming polymers used in preparing photographic film supports are preferred. Merely 10 heating the membranes to their thermal decomposition temperature is not, however, the only way of destroying the membranes. Cellulose coatings and particularly cellulose nitrate can be selectively destroyed in exposed areas by alpha particles and similar fusion fragments, as taught by Sherwood U.S. Patent 3,501,636, here incorporated by reference. It is also specifically contemplated to employ electron beams to destroy the membrane in selected areas.

20 Although the foregoing description is directed to certain preferred embodiments of this invention, it is appreciated that a variety of modifications can be undertaken. In one form of the membrane described above it is contemplated to 25 incorporate a dye in the membrane to increase its heat absorption characteristics. This offers the advantage of rendering the membrane capable of adsorbing more energy upon laser addressing and thereby making more efficient use of the laser beam 30 employed for opening the microcells. On the other hand, remnants of the membrane which are not thermally destroyed in opening the microcells can impart coloration to the support which may be objectionable for certain applications. Therefore it is specifi- 35 cally contemplated to incorporate in the membrane a bleachable dye. For example, a heat and/or light bleachable dye can be incorporated in the membrane. This will permit the membrane to more readily adsorb light during laser addressing, but permits any remnants of the membrane remaining in the completed product to be converted to a form exhibiting little or no coloration. Both heat and light bleachable dyes are well known in the art, as illustrated by Sturmer U.S. Patents 3,984,248, 3,988,154, and 3,988,156, Heseltine et al U.S. Reissue Patent 29,168, Krueger U.S. Patent 4,111,699, and Wise et al U.S. Patent 3,769,019.

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10 When the membrane is located on the support, in most instances there is sufficient adhesion to hold the membrane securely in position. Nevertheless, it is not necessary to rely solely on adhesion to retain the position of the membrane. It 15 is specifically contemplated to place the membrane on the support in an atmosphere containing a gas more membrane-permeable than air. For example, the unfilled microcells can be covered by the membrane in a helium atmosphere. Upon standing in air the 20 helium will slowly diffuse through the membrane into the admosphere, but air, having a lower rate of permeation of the membrane, will not diffuse through the membrane sufficiently to replace the helium thus escaping. The result is that a pressure below 25 atmospheric will develop within the microcells. This pressure differential serves to hold the membrane in position closing the microcells. Other techniques of holding the membrane in position on the support can be employed also in combination with 30 those techniques described above or alone.

In most instances the membrane remains flexible as positioned on the support. If desired, the membrane can be treated once positioned on the support to increase its rigidity and strength. The exact treatment chosen will depend upon the specific composition of the membrane, but, in general, the membranes are formed of polymeric materials which can be increased in rigidity and strength by cross-

linking. Effective cross-linking agents can be chosen from among those generally known in the art, including photographic hardeners, such as those disclosed in Research Disclosure, Vol. 176, December 1978, Item 17643. For cellulose and cellulose derivative membranes preferred cross-linking agents are epoxides, as illustrated by Allen et al U.S. Patent 3,047,394, Burness U.S. Patent 3,189,459, and Birr German Patent 1,085,663. A particularly effective epoxide cross-linking agent is 1,4-butanediol diglycidyl ether, available under the trademark Acryldite.

In still an additional method of selectively introducing differing imaging materials into interlaid sets of microcells both the composition of the support and the composition of the imaging material is modified. The portion of the support forming at least the bottom walls of the microcells is formed of a photoconductive material. The imaging material is then prepared as an electrographic composition. By using xerographic imaging techniques the electrographic imaging composition can be selectively placed in the desired set of microcells. Such an approach to selectively loading the microcells can best be appreciated by reference to an illustrative embodiment.

A specific preferred support 2000 is schematically illustrated in Figure 20. The support is comprised of a photoconductive portion 2002 which has substantially parallel first and second major surfaces 2004 and 2006. The photoconductive portion defines a plurality of microcells (or microvessels) 2008, which open toward the first major surface. The microcells are defined in the photoconductive portion by an interconnecting network of dyed lateral walls 2010 which are integrally joined to a substantially transparent underlying portion 2012 so that the photoconductive portion acts as a barrier

between adjacent microcells. The underlying portion defines the bottom wall 2014 of each microcell. The lateral walls need not be photoconductive. They can alternatively be formed identically to the separate second support elements previously described.

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In addition to the photoconductive portion, the support is formed by a thin, transparent conductive layer 2016 and a transparent film base 2018. Along at least one lateral edge of the support, not 10 shown, the film base and the conductive layer can extend laterally beyond the photoconductive portion to facilitate attachment of an external conductor to the support. A charge control barrier layer, not shown, can be interposed between the conductive 15 layer and the photoconductive portion. Depending on the choice of conductive materials employed, electrical biasing of a particular polarity can, in some instances, result in charge injection from the conductive layer into the photoconductive portion 20 rendering it conductive. The function of the charge control barrier layer is to intercept and trap injected charge--i.e., electrons or holes. Charge control barrier layers are well known in the art, as illustrated by Dessauer et al U.S. Patent 2,901,348,

25 Gramza et al U.S. Patent 3,554,742, Humphris et al U.S. Patent 3,640,708, and Hodges German OLS 1,944,025, the disclosures of which are here incorporated by reference.

Although the support is shown to be

comprised of the photoconductive portion, the
conductive layer, and the film base, it is appreciated that it may be formed of only the photoconductive portion. For instance, once the microcells are filled to the extent desired, the conductive

layer and/or film base can be stripped from the photoconductive portion, leaving it as a separate element. Alternatively, the photoconductive portion can form the entire support and be brought into

contact, as required, with an electrode which forms no part of the support. Although the support is shown to be transparent with dyed lateral walls, it can be entirely transparent or entirely reflec-

tive--e.g., white. The photoconductive portion can be transparent, and the film base replaced with a conventional photographic paper support. Other variant forms will be readily apparent.

The electrostatic charge method of micro10 cell loading of the present invention is generally applicable to the formation of elements containing in a first set of microcells a first imaging composition and in at least one other, interlaid set of microcells a different imaging composition.

- Broadly, this method can be practiced with any microcellular support in which the portion forming the microcells is sufficiently insulative to permit an electrostatic charge to be selectively associated with one set of microcells. For example, the
- remaining, interlaid microcells can be uncharged or bear an opposite polarity electrostatic charge. The support with a charge pattern corresponding to the distribution of the one set of microcells is brought into contact with a carrier vehicle containing
- dispersed therein particles of an electrographic imaging composition. As defined herein the term "electrographic" as applied to the imaging composition means that it is capable of forming an image on a support exhibiting an electrostatic charge
- pattern. By placing an electrostatic charge on the one set of microcells which is opposite in polarity to the charge exhibited by the dispersed particles of the electrographic imaging composition, the charged particles are selectively attracted into the
- one set of microcells in preference to the remaining set of microcells. One or more differing imaging compositions can be introduced into the remaining microcells by repeating the procedures described

above or by any other convenient conventional . technique.

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A specific, preferred embodiment of the process of this invention is described by reference to Figures 21A through 21D. In Figure 21A the support 200 is shown with the photoconductive portion 2002 bearing on its outer surface a positive electrostatic charge, applied in a nonimagewise manner to provide a substantially uniform charge 10 distribution. It is to be noted that the positive charge not only covers the bottom walls 2014 of the microcells, but also covers the upper edges of the lateral walls 2010. As is well understood by those skilled in the art, the electrostatic charge can be 15 conveniently applied by passing the support through a corona discharge.

The next step of the process is to remove the electrostatic charge selectively from the bottom walls of a first, interlaid set of microcells 20 without disturbing the electrostatic charge in other areas of the support. This is accomplished by rendering the photoconductive portion 2002 of the support conductive in areas corresponding to the bottom walls of the first set of microcells. 25 grounding or negatively biasing the conductive layer 2016, electrostatic charge can be conducted through the conductive areas of the photoconductive portion leaving the bottom walls of the first set of microcells substantially discharged, as shown in Figure 21B.

The photoconductive portion can be rendered conductive in areas corresponding to the first set of microcells by supplying radiant energy to which the photoconductive portion is responsive to these 35 areas. According to a preferred technique a laser beam of a wavelength to which the photoconductive portion is sensitive is sequentially aimed at the microcells forming the first set. This can be done

by known laser scanning techniques, such as illustrated by Marcy U.S. Patent 3,732,976, Dillon et al U.S. Patent 3,864,697, and Starkweather et al U.S. published patent application B309,860. The width of the laser beam can be adjusted to expose a plurality of adjacent microcells, but it is preferably less than the width of a single microcell, so that the microcells can be individually addressed.

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Following a specific, preferred technique 10 two lasers are employed. One of the lasers is chosen to provide the desired alteration in conductivity. The second laser is used only to position accurately the first laser . It is preferably of a wavelength to which the photoconductive portion is 15 less responsive and can be of lesser intensity. first and second laser beams are laterally displaced in the plane of the support by an accurately determined distance. By employing a photodetector to receive light transmitted through or reflected 20 from the support from the second laser, it can be determined when a microcell or a lateral wall is aligned with the first laser beam. In the illustrated preferred form, in which the microcell bottom walls are substantially transparent and the lateral 25 walls are dyed, a substantial change in light intensity sensed by the photodetector will occur as a function of the relative position of the support and laser beam. In other instances differences in reflection or refraction between the bottom and 30 lateral walls forming the microcells can be relied upon to provide information to the photodetector. Once the position of the second laser with respect to a microcell can also be ascertained, the position of the first laser with respect to a microcell can 35 also be ascertained, since the spacing between the lasers and the center-to-center spacings of the microcells are known. Depending upon the pattern and accuracy of exposure desired, indexing with the

second laser can be undertaken before exposing each microcell with the first laser, only once at the beginning of exposure of one microcell set, or at selected intermediate intervals, such as before each row of microcells of one set is exposed.

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When a first laser scan is completed, the support is left with one uncharged microcell set while the remaining interlaid microcell set are substantially undisturbed. Instead of sequentially laser exposing the microcells in the manner indicated, exposure through a mask can be undertaken by well known techniques. Laser scanning exposure offers the advantages of eliminating any need for mask preparation and alignment with respect to the microcells.

To introduce a first imaging composition selectively into the first set of microcells, a development procedure can be employed as illustrated in Figure 21C. A direct current source 2102 is 20 connected between a development electrode 2104 and the conductive layer 2016 of the support so that the development electrode is positively biased with respect to the conductive layer 2016. An electrographic developer containing a carrier liquid 2106 25 and dispersed positively charged particles 2108 of an electrographic imaging composition is interposed between the development electrode and the support 2000 so that it can enter the microcells. positive bias on the development electrode can be 30 viewed as induceing a negative electrostatic charge on the bottom walls of the first set of microcells. (See Schaffert, Electrophotography, John Wiley & Sons, New York, p. 16.) The positively charged dispersed particles of electrographic imaging 35 composition are therefore selectively attracted into the first set of microcells while being concurrently repelled from the remaining microcells, which contain a positive electrostatic charge. Since it

is preferred to attract the electrographic imaging composition to the bottom walls of the microcells, it is appreciated that it is advantageous to form the lateral walls 1020 of a nonphotoconductive material. This avoids having the imaging material attracted to the lateral walls. In Figure 21D a first set of microcells of the support 2000 are shown partially filled with a green electrographic imaging composition.

10 To complete the preparation of an element containing green, red, and blue imaging compositions in first, second, and third interlaid sets of microcells, the procedure described above can be twice repeated, except that the second and third 15 sets of microcells are selectively laser addressed in second and third repetitions and a different electrographic imaging composition is employed in each instance. Where the first and second sets of microcells are substantially filled, the third set of microcells can be filled by any of the techniques for filling microcells with a single imaging composition, such as doctor blade coating, for example, since the third imaging composition cannot enter the first and second sets of microcells in any signifi-25 cant quantity. The second and third sets of microcells can be filled also by using any of the other filling procedures disclosed.

It is an unexpected advantage of the present invention that when the procedure of this invention described above is repeated second and subsequent electrographic imaging compositions do not enter the set or sets of microcells which have already received an electrographic imaging composition. Surprisingly, this is true even if the first set of microcells is not entirely filled and even if the first set of microcells is again exposed to radiation, either intentionally or inadvertently, in rendering the photoconductive portion conductive in

the areas of the second and subsequent sets of microcells. This effect is hereinafter referred to as the exclusion effect. Hercock et al U.S. Patent 3,748,125 reports exclusion effects for xerographic toners of specific compositions applied to planar 5 photoconductive surfaces. The exclusion effect observed in the practice of this process does not appear related to any specific choice of electrographic imaging compositions. Without wishing to be 10 bound by any particular theory to account for the exclusion effect observed, it may result from photoconductive surface masking by the already deposited imaging compositions, field gradient or fringing effects (influenced to a degree by the 15 nonplanar configuration of the photoconductive surface), or, most probably, some combination of these effects.

The exclusion effect facilitates the formation of interlaid patterns without introducing 20 more than one electrographic imaging composition into any one set of microcells. This can be illustrated by reference to Figure 22. The multicolor filter 2200 can be formed by introducing into a first set of microcells a green electrographic 25 imaging composition, as has been described above in connection with Figures 21A through 21D. It is to be noted that the microcells labeled G, which each contain a green filter segment lie in alternate rows of microcells. This offers the advantage of allow-30 ing uninterrupted laser scanning of entire rows of microcells rather than addressing individual microcells, as required for the pattern of Figure 2A, for example. After introducing the green electrographic imaging composition, rotating the support 60°, and again nonimagewise electrostatically charging the photoconductive portion of the support, the laser can uninterruptedly scan alternate rows of microcells. During this second laser scan, the laser

beam crosses the microcells already containing the green electrographic imaging composition. Because of the exclusion effect, however, during development with a red electrographic imaging composition, only 5 the microcells which are both laser addressed and free of the first, green imaging composition receive the red electrographic imaging composition. introduce the third, blue imaging composition into the microcells remaining forming the third set, the 10 laser scanning procedure employed for the second laser scan is repeated addressing now the alternate rows skipped during the second scan. Following development with a blue electrographic imaging composition, the result is the filter segment 15 pattern shown in Figure 22. It is to be noted than an interlaid pattern is obtained in which both red and blue filter segments are entirely surrounded by filter segments of the remaining two sets. Yet this result is obtained with only uninterrupted linear 20 scanning by the laser, thereby significantly decreasing the amount of laser indexing which would be required in the absence of the exclusion effect.

It is to be appreciated that the description of the process of this invention by reference 25 to Figures 21A through 21D and 22 is merely illustrative of certain preferred embodiments. Numerous variations will readily occur to those skilled in the art of electrophotography, once the invention is appreciated. For example, the polarity of charge on 30 the photoconductive portions, electrographic imaging composition particles, and development electrode can be reversed without the exercise of invention. use of a development electrode is not required. Reversal development through field fringing is known 35 to be obtainable for small areas, such as line Further, it is possible to choose the polarity of the electrographic imaging composition particles so that it is opposite that of the

electrostatic charge on the photoconductive portion and therefore attracted to the remaining charged microcells not exposed rather than the microcells which are exposed. In such an alternative, initial laser scanning covers the entire surface of the 5 photoconductive portion, except the area represented by the first set of microcells. Any conventional electrographic imaging composition particle size capable of entering the individual microcells can be 10 employed. It is preferred to employ particle sizes of less than about 25 percent of the width of the microcells. Although electrographic developers containing liquid carrier vehicles are preferred, since smaller particle sizes compatible with the 15 widths of the microcells are more readily employed, any conventional electrographic development technique, such as the use of aerosols and dry toners, can be employed. Liquid electrographic developers are particularly preferred which require no separate 20 fusing step to hold the electrographic imaging composition particles in place in the microcells. A separate fusing step can be employed where all of the components of the electrographic imaging composition are intended to remain permanently in the 25 microcells, as in a simple multicolor filter, such as 2200, but it is preferred to avoid a separate fusing step intended to produce a high degree of fusing where one or more materials are to be removed from the microcells. Conventional biasing voltages 30 are generally suitable for the practice of this process.

Preferred electrographic imaging compositions are comprised of a colorant portion, which can include pigments, dyes, and/or dye precursors for producing filters or transferred or retained dye images, as described above, and from 0.1 to 10 (preferably 0.3 to 3.0) parts by weight per part of the colorant portion of a resinous portion capable

of forming a particulate dispersion with the colorant portion in a liquid carrier vehicle having a
dielectric constant of less than 3.0 and a resistivity of at least 10¹⁶ ohm-cm. At least one of
the colorant and resinous portions is chosen to
impart an electrostatic charge of a selected
polarity to the particulate dispersion in the liquid
carrier.

In one specific illustrative form the 10 colorant portion of the preferred electrographic imaging compositions is additionally comprised of at least one immobile additive primary colorant or a combination of immobile colorants capable of collectively providing a desired additive primary color 15 further in combination with a positive or negativeworking dye image providing compound of the type used in producing a transferred dye image. Unlike the subtractive primary dyes and dye precursors, the immobile additive colorants which provide an addi-20 tive primary color should remain immobile at all times and should not wander from the microcells either before, during, or after a photographic image is obtained. Suitable immobile colorants can be selected from among a variety of materials, such as 25 dyes and pigments, but are most preferably pigments, since these can be more readily obtained in highly immobile forms. Useful immobile colorants can be selected from the Color Index, 2nd Edition, 1956, Vols. I and II. Useful immobile polymeric dyes are 30 illustrated by Goldman et al U.S. Patent 3,743,503. Specific preferred immobile pigments are disclosed in Research Disclosure, Vol. 109, May 1973, Item 10938, Paragraph IX-C-2. Exemplary of preferred green, red, and blue immobile pigments are Monolite 35 Green GN, Red Violet MR* (Hoechst), Pyrazalone Red (Harmon), Alkali Blue MG (Sherwin-

Williams), and Monolite Blue® (ICI). Exemplary of useful green, red, and blue substantially immobile

dyes are Renazol Brilliant Green 6B, Red Dye R3G (Drimarene Scarlet) (Sandoz), and MX-G Procion Blue (ICI). The proportions of the subtractive primary dye or dye precursor to the immobile addi-5 tive primary colorant can be varied as desired to achieve an intended imaging result without the exercise of invention. The proportions will vary, depending upon the specific materials selected. For most materials ratios of subtractive primary dye or 10 dye precursor to immobile additive colorant in the range of from about 1:10 to 10:1, most commonly 1:2 to 2:1, are operative, although optimum color balancing for a specific application requires individual adjustment by empirical procedures well 15 known to those skilled in the art.

The resinous portion which together with the colorant portion forms dispersed particles in the liquid electrographic developer is preferably insoluble in the liquid carrier vehicle or only 20 slightly soluble therein. Resinous materials acting as binders appear to form a coating around the colorants and thus facilitate dispersion in the liquid carrier. Examples of useful resins are: alkyd resins as described in Australian Patent 25 254,001; acrylic resins described, for example, in U.S. Patents 3,671,646 and 3,334,047; alkylated polymers described, for example, in U.S. Patents 3,542,681 and '682; rosins described, for example in U.S. Patent 3,399,140; polystyrene as described, for 30 example in Australian Patent 253,986 and U.S. Patent 3,296,140; addition polymers containing a polar moiety as described, for example, in U.S. Patent 3,788,995; ethyl cellulose described in U.S. Patent 3,703,400; cellulosic polymers as described, for 35 example, in U.S. Patent 3,293,183; polyamides, shellac as described, for example, in U.S. Patent 2,899,335; waxes or rubber-modified polystyrenes as described, for example, in U.S. Patent 3,419,411;

rosin-modified as described, for example, in U.S. Patent 3,220,830; silica aerogels as described, for example, in U.S. Patent 2,877,133; halogenated polyethylenes described, for example, in U.S. Patent 2,891,911; graft copolymers described, for example, in U.S. Patent 3,623,986; cyclized rubbers described, for example, in U.S. Patent 3,640,863; vinyl polymers described, for example, in U.S. Patent 3,585,140 as well as coumaroneindene resins; ester gum resins; and polymerized blends of certain soluble monomers, polar monomers and, if desired, insoluble monomers as described in Belgian Patent 784,367.

In order to exhibit electrographic proper-15 ties, the imaging composition must have an electrostatic charge when dispersed as particles in a liquid carrier. The colorants can themselves impart the desired electrostatic charge to the dispersed particles. The colorants are selected to exhibit a 20 single polarity of charge to insure the lowest possible minimum densities. The electrostatic charge polarity of the dispersed particles can be enhanced or controlled by the selection of resinous binder materials and/or suitable charge control 25 agents. Illustrative charge control agents are the polyoxyethylated alkyl surfactants such as polyoxyethylated alkylamine, polyoxyethylene palmitate, and polyoxyethylene stearate. Other useful materials are magnesium and heavier metal soaps of fatty and 30 aromatic acids as described in U.S. Patents 3,417,019, 3,032,432, 3,290,251, 3,554,946, 3,528,097, and 3,639,246. Useful metal soaps include cobalt naphthenate magnesium naphthenate and manganese naphthenate, zinc resinate, calcium 35 naphthenate, zinc linoleate, aluminum resinate, isopropyltitanium stearate, aluminum stearate, and others many of which are also described in Matkan U.S. Patent 3,259,581. Typically, the amount of

such materials used is less than about 2 percent by weight based on the weight of the imaging composition. In certain instances, the resinous binder materials per se can function as the charge control 5 agent as disclosed, for example, in U.S. Patent 3,788,995, cited above. A dispersing aid can also be added as shown, for example in U.S. Patent 3,135,695. This patent shows an electrographic liquid developer prepared by surrounding or dispers-10 ing electrographic-type pigment particles with a suitable resinous binder envelope and treating the pigment-binder combination with a small amount of an alkylaryl compound before suspending the combination in a liquid aliphatic carrier. This type of liquid 15 electrographic developer is especially useful due to its relatively high stability. Other addenda may include: a phospholipid charge stabilizing material, e.g., lecithin, as described in U.S. Patents 3,220,830, 3,301,677, 3,301,698, 3,241,957, 3,668,126, and 3,674,693, and U.K. Patent 1,337,325; noble metal salts as described in French Patent 1,354,520, isocyanate compounds as described in U.K. Patent 654,977, and U.S. Patent 3,383,316; magnetic particles as described in U.S. Patent 3,155,531; 25 conductive materials as described in U.S. Patents 3,300,410 and 3,409,358; fatty acid esters as described in U.S. Patent 3,692,520; manganese salts as described in U.S. Patent 3,438,904; antistain agents as described in U.S. Patent 3,681,243; and

Conventionally, the liquid carrier vehicle used in liquid electrographic developers has a low dielectric constant less than about 3.0 and a resistivity of at least about 10° ohm-cm, preferably at least 10° ohm-cm. These requirements automatically eliminate water and most alcohols. However, a number of liquids still are available to

30 hydroxy-stearins as described in U.S. Patent

3,701,731.

satisfy the above-noted requirements and have been found to function as effective carrier vehicles for liquid developers. Among the various useful liquid carrier vehicles are alkylaryl materials such as the 5 xylenes, benzene, alkylated benzenes and other alkylated aromatic hydrocarbons such as are described in U.S. Patent 2,899,335. Other useful liquid carrier vehicles are various hydrocarbons and halogenated hydrocarbons such a cyclohexane, cyclo-10 pentane, n-pentane, n-hexane, carbon tetrachloride, fluorinated lower alkanes, such as trichloromonofluorane and trichlorotrifluorethane, typically having a boiling range of from about 2°C to about 55°C. Other useful hydrocarbon liquid carrier 15 vehicles are the paraffinic hydrocarbons, for example, the isoparaffinic hydrocarbon liquids having a boiling point in the range of 145°C to 185°C (sold under the trademark Isopar by Exxon) as well as alkylated aromatic hydrocarbons having a 20 boiling point in the rage of from 157° to 177°C (sold under the trademark Solvesso 100 by Exxon). Various other petroleum distillates and mixtures thereof may also be used as liquid carrier vehicles. Additional carrier liquids which may be 25 useful in certain situations include polysiloxane oils such as dimethyl polysiloxane as described in U.S. Patents 3,053,688 and 3,150,976; Freon carriers as described in Canadian Patent 701,875 and U.S. Patent 3,076,722; mixtures of polar and nonpolar 30 solvents as described in U.S. Patent 3,256,197; aqueous conductive carriers such as described in U.S. Patent 3,486,922; nonflammable liquid carriers such as described in U.S. Patent 3,058,914; polyhydric alcohols such as described in U.S. Patent 35 3,578,593; and emulsified carriers such as described in U.S. Patents 3,068,115 and 3,507,794. Electrographic imaging composition can be dispersed in the liquid carrier vehicle in any convenient conventional concentration, typically in the range of from 0.01 to 10 percent by weight based on total weight. Conventional techniques for dispersing the electrographic imaging composition can be employed, as disclosed, for example, in <u>Research Disclosure</u>, Item 10938, cited above, Paragraph IX-E and F.

Any conventional photoconductive material or combination of photoconductive materials can be employed in the microcellular supports of this 10 invention. Suitable photoconductive materials are disclosed, for example, in Research Disclosure, Vol. 109, May 1973, Item 10938, Paragraph IV. ductive materials which in themselves are capable of forming microcells can be employed alone, as in the 15 case of polymeric organic photoconductors which are plastically deformable. The photoconductive material is preferably incorporated in a separate insulative binder to form a microcellular structure, as disclosed by Wiegel, U.S. Patent 3,561,358. 20 Preferred photoconductive supports and support portions can be formed as taught by Contois et al, Research Disclosure, Vol. 108, April 1979, Item 10823. Other suppport portions, such as the conductive layers and base portions, can take any conven-25 tional form, exemplary materials being disclosed in Research Disclosure, Item 10938, cited above, Paragraphs II Supports and III Interlayers. When, as is preferred, the lateral walls are formed of a nonphotoconductive material, the various second 30 support element materials described above can be employed. Poly(vinyl butyral), because of its adhesion to the exemplified photoconductive materials is a preferred lateral wall forming

In a specific preferred form at least the photoconductive portion of each support is substantially transparent. Where the photoconductive material forms a part of a multicolor reflective

material.

photographic print, for instance, even a slight coloration is apparent to the human eye and therefore objectionable. For such applications, preferred photoconductive materials are those sensitive to the ultraviolet portion of the spectrum, but not sensitized to the visible spectrum, to avoid imparting a visible minimum density. Such photoconductive materials can be addressed with an ultraviolet laser beam.

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10 In certain applications, as where radiation-sensitive materials are intended to be located in the microcells, it is not practical to use ultraviolet radiation to address the photoconductive portion, since many radiation-sensitive imaging 15 materials exhibit a native sensitivity in the ultraviolet region of the spectrum. For example, silver halide possesses a native sensitivity in the near portion of the ultraviolet spectrum. introducing each of blue, green, and red-sensitized 20 silver halide into separate sets of microcells, the photoconductive portion is preferably sensitized to the red or a longer wavelength region of the spectrum. The first and second sets of microcells can be addressed with a red laser beam without fogging 25 the blue and green-sensitized silver halides introduced into the first and second sets of microcells. Even if a third laser scan is employed, the red-sensitized silver halide introduced into the third set of microcells is not fogged, since the 30 red-sensitized silver halide is not introduced until after the third laser scan is completed.

Sensitization of photoconductive materials to a selected portion of the spectrum can be undertaken employing spectral sensitizing dyes well known in the electrographic arts, such as those disclosed in Research Disclosure, Item 10838, cited above, Paragraph IV-C. Any minimum density imparted by spectral sensitization need not be objectionable.

For example, if the photographic image to be
produced is not intended to be viewed directly, such
as a multicolor negative image used for printing a
multicolor positive image, coloration due to spectral sensitization is not objectionable, since color
correction can be introduced in printing by
procedures well known to those skilled in the art.

In loading interlaid areas of the support surface with differing imaging materials wherein the imaging materials are located as a function of a pattern of radiation exposure, by exposing at an acute angle with respect to the plane of the support shadowing can be relied upon to define exposed and unexposed support areas. Shadowed and unshadowed areas can be controlled by varied lateral wall geoemetries forming the microcells. The angle of exposure can also control exposures. A variety of specific illustrative forms are described below.

An illustrative simple support 2300 is

shown in Figures 23A and 23B. The support has
substantially parallel first and second major
surfaces 2302 and 2304. The support defines a
plurality of parallel microgrooves 2306, which open
toward the first major surface of the support. The

microgrooves are defined in the support by an array
of lateral walls 2308 which are integrally joined to
an underlying portion 2310 of the support.

In Figure 23B the arrows 2312 schematically designate radiation striking the support at an acute angle 6 with respect to an axial plane 2314 along which the support is areally extended. A portion of the radiation strikes the bottom walls 2316 of the microgrooves in unshadowed microareas 2316A while another portion of the radiation strikes the lateral walls 2308 and is thereby interrupted, so that microareas 2316B of the microgrooves are shadowed and do not receive radiation, at least not to the same extent, as the unshadowed microareas.

The lines 2318 define the boundary of an area unit containing a single microgroove. The remaining depicted area of the support is formed by area units essentially identical to that within the boundary. Each area unit forms a pixel. The term "pixel" is employed herein to indicate an area which can be repeated to make up the support.

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Certain features of the invention can be appreciated by reference to support 2300. First, it should be noted that the lateral walls 2308 lie along half the boundaries between adjacent microareas. Thus, if a material is contained in the microgrooves which is capable of lateral spreading, it is restrained from spreading between microareas over half of the boundaries therebetween. Similarly, radiation that might otherwise be scattered between adjacent microareas is also restrained where the lateral walls are present.

The acute angle 6 at which the radiation 20 is directed toward the support can be varied by repositioning either the radiation source and/or the support. As shown, the radiation is directed parallel to the section line 23B-23B and perpendicular to the major axes of the lateral walls 2308. 25 this orientation the minimum angle of θ at which the radiation can strike the bottom walls 2316 is determined by the relationship tan θ = H/W, where H is the height of the lateral walls 2308 and W is the width of the bottom walls 2316. It is therefore 30 apparent that the proportion of the bottom walls that are unshadowed can be controlled by varying any one or combination of &, H, or W. Further, if the support is rotated 90° with respect to the radiation source so that the radiation is introduced perpen-35 dicular to the section line 23B-23B, no shadows are produced. It is therefore apparent that maximum shadowing for a given value of & is achieved when radiation is introduced perpendicularly to the major axes of the lateral walls and that the degree of shadowing can be decreased by rotating the lateral walls of the support toward alignment with the radiation.

5 Referring to Figure 23A, it can be appreciated that if the support 2300 is resolved into two separate halves joined along the section line 23B-23B and one half is translated with respect to the other along the axial plane 2314, the support 10 continues to respond to angled radiation exposure substantially as described above -- that is, it continues to satisfy the essential shadowing criteria described above. The plane represented by the section line 23B-23B thus constitutes a glide plane--herein defined as a plane separating two support portions which can be displaced relative to each other along the axial plane of the support without dimininishing the shadowing utility of the support. It is further observed that the support 20 2300 can be resolved not just into halves, but into a large number of separate portions displaced along the axial plane without substantially altering its shadowing utility. It is thus apparent that the support 2300 provides only a simple example of a 25 large family of lateral wall arrays that provide

This is specifically illustrated in Figure 24 in which support 2400 is comprised of identical support regions 2400A, 2400B, 2400C, and 2400D joined along parallel glide planes 2402. In comparing supports 2300 and 2400, it can be seen that the two supports are identical, except that the support

roughly similar shadowing utility.

regions 2400A and 2400C are laterally displaced with respect to the support regions 2400B and 2400D.

35 This has the result of producing lateral walls 2408 and microareas 2416A and 2416B which are limited in their maximum dimension in the form shown to the distance between glide planes 2402. Thus, support

2400 is superior to support 2300 for applications in which the microareas are preferably limited in their longest dimension. For example, by positioning the glide planes between support regions at a spacing of 5 200 microns or less and the lateral walls within each support region at a center-to-center spacing of 400 microns or less, microareas limited in both length and width to 200 microns or less can be readily obtained. As a result of the relative 10 translation of adjacent support regions, the support 2400 contains no grooves, but only upstanding lateral walls. This illustrates that neither microgrooves nor any other type of areally limited depressions in the support are required for the 15 practice of this invention.

In further comparing the microarea patterns of supports 2300 and 2400, it can be appreciated that the microareas 2416A and 2416B are interspersed to a greater degree than the microareas 2316A and 2316B. The microareas 2416A and 2416B are interlaid along two perpendicular axes, whereas the microareas 2316A and 2316B are interlaid along only one axis. The higher degree of interlay can represent a distinct advantage for specific applications requiring a high degree of interlay for desired optical or chemical properties.

and 2400, it can be seen that the lateral walls 2408 separate the first and second microareas 2416A and 2416B over a boundary approximately equal in length to that by which the lateral walls 2308 separate the microareas 2316A and 2316B. However, in the support 2400, because the microareas 416A and 416B are more highly interspersed, there is a larger boundary between adjacent microareas where no lateral walls are present. This feature of the support 2400 can, however, be readily modified in a manner which does not diminish the shadowing utility of the support.

If, for example, additional lateral walls are introduced along the glide planes 2402 in Figure 24, it can be seen that the lateral walls now extend over a much larger proportion of the boundaries between adjacent microareas. The result is to limit significantly the boundary region available for lateral spreading between adjacent microareas.

If additional lateral walls are provided for the support 2400 along the glide planes 2402, it 10 is apparent that a predetermined, ordered array of microcells is created, each containing two micro-In the geometrical form described the microcells produced on the modified support 2400 are approximately square, but it is apparent that 15 microcells of any geometric configuration can be employed. Thus, supports exhibiting any of the microcell configurations disclosed above can be employed in the practice of this invention. Polygonal (square, rectangular, and hexagonal), circu- 20 lar, and elliptical microcell configurations have been explicitly disclosed, although any other predetermined recurring microcell configuration (or combination of configurations, discussed below) can be employed in the practice of this invention.

25 Any predetermined, ordered array of lateral walls capable of interrupting radiation, whether or not microcells or microgrooves are formed by these walls, can be employed in the practice of this invention to produce two or more laterally displaced contiguously adjoining microareas (that is, microareas which over some boundary region are not separated by lateral walls). Supports having uniformly spaced lateral wall arrays, such as supports 2300 and 2400, or supports having a single repeated microcell configuration are particularly suited for forming two or more laterally displaced contiguous sets of microareas that are of uniform size in each individual occurrence.

Figures 23A, 23B, and 24 illustrate perhaps the simplest shadowing approach of this invention wherein the bottom walls of the supports are shown divided into two separate interlaid sets of uniform 5 microareas of substantially equal area by a single exposure of the support to radiation directed toward the axial plane of the support at an acute angle. Where one composition is introduced into exposed microareas and a second composition is introduced 10 into unexposed or shadowed microareas, an interlaid array of two separate compositions is produced. some applications the microareas represented by the lateral walls can also be utilized, so that three separate useful sets of microareas are actually 15 present.

Supports useful as described above can also be applied to applications requiring more than two laterally displaced compositions. For example, in Figures 23A and 23B it can be seen that by adjusting 20 the angle of exposure b, the size of the microareas 2316A exposed can be adjusted. If, for example, it is desired to place three separate strips of equal size of three separate compositions between adjacent pairs of lateral walls 2308, the 25 angle 6 is adjusted so that the radiation strikes only one third of the area of each bottom wall 2316. A first composition can then be selectively positioned in the microareas corresponding to the exposed portions of the bottom walls. The angle b 30 is then increased so that on a second exposure radiation strikes the area originally struck, now containing the first composition, and a contiguous one third of each bottom wall 2316. A second composition is then selectively positioned in the 35 microareas corresponding to the exposed areas not occupied by the first composition. The procedure can be repeated using radiation directed perpendicularly to the axial plane 2314 to position a third

composition in a third laterally displaced set of microareas, or the third composition can in many instances be introduced by a conventional technique for coating a single composition, such as doctor blade coating. Although described by reference to three compositions and a specific support, it is apparent that the procedure is generally useful with all of the supports containing lateral wall arrays herein described and with more than three compositions.

The procedure described above for positioning three or more laterally displaced compositions, while useful with all lateral wall array patterns, relies in part on the presence of a previously positioned composition to define a microarea resulting from a later exposure. Stated another way, the first and second exposures are in part areally overlapping. This limits the shadowing procedure described above to use with materials which allow the presence or absence of one composition to exclude a subsequent composition, as is possible in certain preferred embodiments of this invention. Exclusion and exhaustion effects are discussed more specifically below.

It is possible to address uniquely two or more areas of a support according to this invention so that no materials dependent exclusion effect is relied upon. An approach for uniquely addressing two separate sets of microareas with radiation while creating a third set of microareas by shadowing is illustrated in Figures 25A, 25B, and 25C. Except as otherwise noted below, the features bearing 2500 series reference numerals are identical to those bearing the corresponding 2300 series reference

35 numerals in Figures 23A and 23B and are not redescribed in detail.

The support 2500 as illustrated differs from support 2300 solely in the use of an optional

transparent underlying portion 2510; however, the
lateral walls 2508 remain capable of interrupting
radiation. In Figure 25B radiation 2512A is
directed toward the axial plane 2514 at an angle 6
chosen to permit impingement of radiation only on
the microareas 2516A. The remaining area of each
bottom wall 2516 is shadowed by the lateral walls
2508. Thus, exposure as shown in Figure 25B creates
one set of microareas 2516A in an interlaid pattern
with remaining support areas. A first composition
can be selectively positioned in the first set of
microareas.

In Figure 25C the support is given a second exposure to radiation 2512B at an acute angle 6'.

15 As shown, the radiation exposure patterns in Figures 25B and 25C are mirror images, although the angles 6 and 6' need not be equal, except when the microareas 2516A and 2516B are intended to be equal. Instead of changing the direction of radiation between the first and second exposures, the support could alternatively be rotated 180° in the axial plane.

Radiation impinges on the bottom walls 2516 only in the microareas 2516B, creating a second set 25 of radiation exposed microareas. A second composition can be selectively positioned in the second set of microareas. A third set of microareas 2516C, not exposed by either the first or second exposures, is created concurrently with the second set of micro-30 areas. A third composition can be positioned in the third set of microareas, if desired. It is to be noted that the first composition is laterally spaced from the second microareas, and no exclusion property is required in order to position the second 35 composition. It is appreciated that the angles 6 and/or o' can be increased to eliminate the microareas 2516C without in any way altering the shadowing technique described above.

Using the support 2300, 2400, and 2500, only two interlaid sets of microareas can be uniquely addressed by shadowing techniques. By the term "uniquely addressed" it is meant that a set of microareas is exposed to only the single radiation exposure which defines its boundaries and no other microarea defining radiation exposure. It is possible, however, to produce three, four, five, six, or even more sets of uniquely addressed micro-10 areas in a single support containing microcells. For this purpose microcells of polygonal shape are preferred. Generally the number of sets of uniquely addressed areas that can be produced by shadowing in a single polygonal microcell is equal to its number 15 of apices.

An illustration of the creation of microareas in a set of polygonal microcells by shadowing techniques of the type described above is provided in Figures 26A and 26B, in which a detail of a 20 support 2600 containing a predetermined, ordered array of microcells 2602 of a regular hexagonal shape is shown. The support 2600 in section can appear identical to the supports shown in Figures 23B or 25B. Referring first to Figure 26A, exposure of the support 2600 in a direction parallel to arrow la at an acute angle with the axial plane of the support exposes the bottom wall of each microcell in only diamond-shaped area 1b, the remainder of the wall of each microcell being shadowed. By changing 30 the direction of exposure, as indicated by arrows 2a, 3a, 4a, 5a, and 6a, but not the exposure angle, five more identical diamond-shaped exposed microareas 2b, 3b, 4b, 5b, and 6b are produced. The six diamond-shaped microareas provided in each microcell 35 are of equal area, since each microcell is a regular hexagon and the angle of exposure is unchanged. is to be noted that none of the six microareas impinges on any other of the six diamond-shaped

microareas and therefore each is uniquely addressed by shadowing exposures. Thus, it is possible to place up to six separate compositions in each microcell 2602 without relying upon any exclusion property.

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Exposure can be terminated after the sixth exposure and the central area of each microcell can be left unexposed, if desired. In this instance the lateral spacing in the center of each microcell between compositions introduced into the six separate microareas can be relied upon to prevent or reduce boundary mixing of compositions. In an alternative form in which the central region is desired to receive material, one or more compositions can be employed capable of wandering from the diamond-shaped areas to cover the central portion of each microcell.

By using a combination of the procedures described above and exclusion effects, it is
20 possible to produce additional microareas in each hexagonal microcell 2602. As shown in Figure 26A, a microarea 7b equal in area to the diamond-shaped areas is produced by exposing at the same acute angle in a direction indicated by arrow 7a. The radiation overlaps both the microareas 1b and 2b in exposing additional microarea 7b. By using exclusion effects a seventh composition can be located in only the microarea 7b. Microareas 8b, 9b, 10b, 11b, and 12b are sequentially similarly formed by shadowing exposures along like numbered axes.

Thus far it can be seen that 12 microareas can be formed, six of which can be uniquely addressed and six of which depend on exclusion effects. At this point the central portion of each hexagonal microcell remains shadowed. If desired, the central portion of the microcell can be left shadowed and unfilled. Alternately, the central, shadowed portion of the microcell can be filled with

a single composition. For example, if the microareas 1b, 2b, 3b, 4b, 5b, and 6b receive a first
composition and the microareas 7b, 8b, 9b, 10b, 11b,
and 12b receive a second composition, a third
composition can be located in the central, shadowed
portion of each microcell, and three compositions
will occupy roughly equal areas of each microcell
bottom wall.

By increasing the acute angle of exposure 10 and relying on exclusion effects, it is possible to form additional microareas in the central, initially shadowed portion of each microcell. By exposing again in the direction indicated by arrow 7a, but at an increased acute angle, the microarea 13b can be 15 formed, which is roughly equal to the previously formed microareas. Similarly, by exposing in the direction indicated by arrow 10a microarea 14b can be formed. By exposure in the direction indicated by arrow 6a the microarea 15b can be formed, and by 20 exposing in the direction indicated by arrow 3a the microarea 16b can be formed. Microareas 13b, 14b, 15b, and 16b are all formed at the same acute angle of exposure and are approximately equal. increasing the acute angle of exposure again, 25 microareas 17b and 18b can be formed by exposing in the direction indicated by arrows 6a and 3a, respectively. These microareas are roughly equal to the previously formed microareas. Two triangular microareas 19b remain unexposed which, together are 30 roughly equal to the remaining microareas. By using shadowed microareas 19b as one microarea, 19b laterally spaced compositions can be placed on the bottom walls of each hexagonal microcell, each composition occupying an approximately equal area. 35 The shown pattern is, of course, only exemplary.

Shadowing exposures can produce microareas of

differing configuration, size, and number.

The ability to uniquely address a plurality of sets of microareas so that the microareas cover an entire surface of a support, except for the areas occupied by lateral walls, is an obvious advantage

- in making maximum use of a support surface and in achieving a high degree of interdigitation of compositions. Some lateral wall patterns offer this capability and some do not. In referring to supports 2300, 2400, and 2500, it can be seen that
- the lateral wall patterns permit the creation of uniquely addressed microareas which cover the entire support surface not occupied by the lateral walls. It is also apparent that microcells of square or rectangular configuration also offer this capabil-
- 15 ity, since it has already been pointed out above that any two contiguous microareas in the same segment of the support 2400 can be enclosed in a microcell without altering the shadowing capability of the support. Upon further reflection it can be
- are but special cases of lozenge (diamond-shaped) and parallelogram configuration microcells and that all such microcells can be uniquely addressed over their entire bottom wall areas. As shown in Figure
- 25 26A, the uniquely addressed areas 1b through 6b of the hexagonal microcells 2602 do not occupy the entire bottom surface of the microcell; but, referring to Figure 26B, the identical support is uniquely addressed over the entire bottom walls of the
- microcells by three exposures at an acute angle with respect to the axial plane. Area ld is addressed by exposure in a direction lc, area 2d by exposure in a direction 2c, and area 3d by exposure in a direction 3c. This demonstrates that uniquely addressing
- microcells over their entire bottom walls is a function not only of the shape of the microcells, but also a function of the angle and direction of exposure. Many microcell configurations, such as

circular, elliptical, triangular, and trapezoidal microcells cannot be uniquely addressed over their entire bottom wall areas by shadowing techniques, regardless of the number or angle of shadowing exposures attempted.

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While the present invention can employ supports containing any of the microcell arrangements, it is additionally recognized that advantageous results can be obtained by using supports containing identical microcells which by their orientation can be resolved into interlaid sets that can be differentially addressed.

This is illustrated in Figure 27, in which a support 2700 is provided with a plurality of 15 identical microcells which appear triangular in plan. As can be readily appreciated, however, the triangular microcells are not all similarly aligned. There are two interlaid sets of microcells 2702A and 2702B. When the support is addressed by 20 radiation at an acute angle with respect to its axial plane, as indicated by arrow 2704, radiation strikes the bottom walls of the microcells 2702A in microareas 2706A and strikes the bottom walls of the microcells 2702B in microareas 2706B. It is to be 25 noted that the microareas are equal, but differ in their orientation similarly as the microcells in which they occur. While the triangular microcells shown are each equilateral triangles, triangles of any desired type, including isosceles and right 30 triangles, can be employed with similar results.

In each of the embodiments heretofore described at least two sets of microareas are contiguously adjoining—that is, they are not separated by a lateral wall over some portion of their boundary. Thus, the advantages which lateral walls have to offer in preventing lateral spreading either of materials or radiation are partially, but not entirely, realized. The preferred supports are

those which offer the capability of providing two or more interlaid sets of microareas by shadowing techniques, each of the microareas being entirely separated from microareas of other sets by lateral walls. Specifically preferred supports are those which allow three separate compositions to be interlaid by shadowing techniques in separate sets of microareas each separated from the other by lateral walls.

A simple support 2800 capable of providing three interlaid sets of microareas each entirely separated from the other by lateral walls is illustrated in Figures 28A, 28B, and 28C. Except as otherwise noted, the features bearing 2800 series reference numerals are identical to those bearing the corresponding 2300 series reference numerals in Figures 23A and 23B and are not redescribed in detail.

arranged in parallel relationship, but unlike the lateral walls in support 2300, are unequally spaced in a predetermined, ordered manner. The widest spaced lateral wall pairs together with the connecting portion 2810 form a first set of microgrooves 2806A each having a bottom wall 2816A. The next widest spaced pairs of lateral walls similarly form a set of microgrooves 2806B each having a bottom wall 2816B. The closest spaced pairs of lateral walls form a third set of microgrooves 2806C having a bottom wall 2816C.

When the support is exposed with radiation as indicated by arrows 2812A in Figure 28B, the acute angle 6 with respect to the axial plane 2814 is chosen so that the radiation strikes only the bottom walls 2816A. The bottom walls 2816A are shadowed, however, to some degree. The extent to which the bottom walls 2816A are shadowed can be reduced significantly by performing a second expo-

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sure as described above in connection with support 2500. For example, the support can be rotated 180° and given a second exposure at the same angle. properly positioning the lateral walls and choosing the angle 6, it is possible to expose all of the bottom walls 2816A without exposing any portion of the bottom walls 2816B and 2816C. Once the bottom walls 2816A have been selectively exposed, a first composition can be selectively located in the first 10 microgrooves 2806A.

5

With a first composition 2850 in place, as shown in Figure 28C, the support is given a second exposure to radiation 2812B at an increased acute angle φ with respect to the axial plane. Radiation strikes the first composition in the first microgrooves and also the bottom walls 2816B of the second microgrooves 2806B, but is blocked by the narrowness of the third microgrooves 2806C from striking the bottom walls 2816C. Since a portion of 20 the bottom walls 2816B remain shadowed, the support can be rotated 180° and exposed again to increase the exposure of the bottom walls 2816B as a function of exposure. The second set of microgrooves 2816B can then be filled with a second composition. A third composition can be introduced into the third microgrooves 2806C similarly as in positioning a third composition in the microareas 2516C.

The area between the lines 2818 forms a single pixel of the support 2800. It is to be noted 30 that the microareas 2816A, 2816B, and 2816C of the pixel present unequal areas. In applications where a more nearly equal distribution of microareas is preferred, the support can be formed so that the number of occurrences of each microarea is varied to 35 more closely balance the total areas presented by the separate sets of microareas. For example, a second microarea 2816C can be added to each pixel 2818, thereby doubling the area of the third set of

microareas without in any way altering the shadowing capability of the support 2800 described above.

An alternative support which responds to shadowing exposures identically as the support 2800, described above, but which offers the further advantage of providing three interlaid sets of microareas that present equal areas in each individual occurrence is shown in Figure 29. support 2900 is shown by reference to a single pixel 10 2918, which contains three separate microgrooves 2906A, 2906B, and 2906C. The only difference between the microgrooves is the depths of the bottom walls 2916A, 2916B, and 2916C, which, as shown, are parallel to the axial plane 2914 of the support.

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15 Shadowing exposure of the support 2900 can be appreciated by reference to the arrows 2912A, 2912B, and 2912C which strike the intersections of the bottom and lateral walls of the microgrooves 2906A, 2906B, and 2906C, respectively. By reference 20 to the arrows it can be appreciated that an exposure to radiation at an angle greater than θ , but less than φ , will strike the bottom walls of the microgrooves 2906A while leaving the bottom walls of the microgrooves 2906B and 2906C entirely in 25 shadow. After a first composition is introduced into the microgrooves 2906A, a second exposure at an angle with respect to the axial plane of greater than φ and less than α will permit the bottom walls 2916B of the microgrooves 2906B to be exposed 30 without exposing any portion of the bottom walls 2916C of the microgrooves 2906C. After a second composition is introduced into the second microgrooves, a third composition can be introduced into the third microgrooves by any technique described

It is apparent that the supports 2800 and 2900 can be resolved into separate segments along glide planes similarly as the support 2300 is

35 herein for introducing a third composition.

resolved along glide planes to form the support

2400. Further, although described by reference to
parallel lateral walls only, it is apparent that the
use of the sets of microcells differing in lateral
extent, in depth, or in any combination of both can
be employed in the practice of this invention.
Although described above in terms of three separate
sets of microareas, it is appreciated that any one
of the three sets of microareas in the supports 2800
and 2900 can be omitted to allow two compositions to
be interlaid substantially as described.

Figures 300A, 300B, and 300C illustrate a preferred support 3000 for use in the practice of this invention which is (1) capable of entirely

15 laterally separating three different compositions similarly as supports 2800 and 2900, (2) capable of providing equal composition microareas similarly as support 2900, (3) capable of additionally providing equal microcell volumes of each composition within each pixel, (4) capable of being radiation exposed by shadowing techniques over the entire bottom wall area of each of three separate sets of microcells, and (5) capable of having two microcell sets uniquely addressed.

The support 3000 is comprised of substantially parallel first and second major surfaces 3002 and 3004. The support defines a first set of rectangular microcells 3006A, a second set of rectangular microcells 3006B, and a third set of square microcells 3006C. The microcells are defined in the support by an array of lateral walls 3008 which are integrally joined to an underlying portion 3030 of the support.

The microcells 3006A and 3006B as shown are identical in shape, but not in orientation. The major axis of each microcell of the first and second set is aligned with or parallel to the major axis of microcells of the same set and perpendicular to the

major axis of each microcell of the other set. The set of square microcells is positioned so that an edge of each square is substantially parallel to an adjacent edge of a rectangular microcell.

The dashed lines in Figure 30A separate the support into identical pixels 3018. Each pixel contains one rectangular microcell from each of the first and second sets and two square microcells of the third set.

By uniformly exposing the first major surface of the support in the direction indicated by the arrows 3012A, it is possible to expose selectively the bottom walls of the first set of microcells 3006A while the lateral walls prevent direct impingement of the radiation on the bottom walls of the remaining two sets of microcells. If desired to expose entirely the bottom walls of the first set of microcells, the support can be rotated 180° and exposed again at the same angle or the support can

be exposed again at the same angle, but with the horizontal direction component of the radiation as shown in Figure 30A reversed. After a first composition is positioned in the first set of microcells as a function of exposure, the bottom walls of the

second set of microcells 3006B can be selectively exposed by uniformly exposing the first major surface of the support in the direction indicated by the arrows 3012B, and in the opposite horizontal direction at the same acute angle similarly as in

opposing the bottom walls of the first set of microcells. The bottom walls of the first and third sets of microcells are not exposed. A second composition can then be selectively introduced into the second set of microcells as a function of

35 exposure. The bottom walls of the third set of microcells can then be exposed by addressing the first major surface of the support in a direction perpendicular to its axial plane 3014. A third

composition can then be introduced into the third set of microcells. It is to be noted that no exclusion property is required to introduce selectively the first and second compositions into the first and second sets of microcells, but that in using a third, perpendicular exposure the first and second compositions must exclude the third composition from the first and second sets of microcells, since the third set of microcells is not uniquely addressed, but is addressed concurrently with all the other microcells.

In considering the sequence of exposures disclosed above, certain more general parameters of the invention will become apparent. In exposing the microcells 3006A, it is apparent that it is their length and the height of the lateral walls which controls exposure of the bottom walls. Exposure is entirely independent of the width of the first set of microcells. It is therefore apparent that the 20 width of the first set of microcells can be varied at will from very small to very large, depending upon the size of the microareas and the amount of the first composition desired. The width of the microcells of the first set in the direction of 25 arrows 3012B can even be increased to a point where it exceeds the length of these microcells in the direction of arrows 3012A. The widths can, of course, be variable from one microcell to the next, if desired. The microcells 3006B of the second set 30 can be of any desired length, but to avoid being exposed on their bottom walls while the first set of microcells are being addressed, the width of the second set of microcells must be no greater than half the length of the first set of microcells. Measured in a direction parallel to the major axes of the first set of microcells, the microcells of the third set can be up to one half the length of

the microcells of the first set without being

addressed on their bottom walls during exposure of the bottom walls of the microcells of the first set. The microcells of the third set similarly can be up to half the length of the microcells of the 5 second set measured in a direction parallel to the major axes of the second set of microcells. In the preferred form shown the first and second sets of microcells are of equal length and the microcells of the third set are each substantially one half the length of both the first and second sets of microcells and thus square; however, the third set of microcells can be rectangular whether or not the first and second sets of microcells are of equal length. As suggested above, the rectangular micro-15 cells of the first and second sets are only an example of a general class of microcells of parallelogram configuration. The microcells of the third set, shown to be square, can be of either lozenge or parallelogram configuration. another way, adjacent sides of the microcells need not be perpendicular, but to retain the functional capabilities disclosed, opposite sides of the microcells should remain parallel. The above discussion is limited to microcell dimensions that 25 provide all the advantages of the support 3000 as shown. If less than the entire bottom wall of each microcell of the first and second set is to be addressed by radiation, then the dimensions of the second and third sets of microcells can be increased 30 above the one half limits indicated.

A number of variations of the support 3000 and the shadowing technique for introducing compositions will readily be apparent. For example, instead of giving the support a third exposure to introduce the third composition, in many instances the third composition can be introduced without reference to any exposure pattern, simply relying on the first and second compositions to exclude the

third composition from the first and second sets of microcells, as has been mentioned in connection with previously discussed supports. The support 3000 can be adapted to the use of two rather than three compositions merely by omitting any one of the three sets of microcells without otherwise altering the capabilties or shadowing techniques described above. It is to be noted that the placement of the individual microcells in relation to each other is 10 entirely a matter of choice. For example, instead of placing pairs of square microcells side-by-side, as shown, they can be separated by intervening rectangular microcells. Alternatively, the square microcells can form columns and/or rows perpen-15 dicular to the columns which are not interrupted by rectangular microcells.

In looking at the support 3000, it is apparent that it is only exemplary of a large family of alternative support configurations capable of 20 exhibiting some or all of the advantages of this invention. For example, if the microcells 3006B are arranged in an end-to-end pattern in parallel columns (this can be done by laterally displacing the support along the horizontal dashed line in 25 Figure 30A extending in the same direction in the axial plane as the arrows 3012A); it is apparent that glide planes exist in these columns. By laterally displacing the support on one side of a glide plane one-half the length of the microcells 30 3006B, the second set of microcells 3006B are transformed into a serpentine microgroove. The shadowing utility of the support is not affected, however. In like manner, it can be appreciated that if the square microcells are arranged in a row or 35 column uninterrupted by rectangular microcells, glide planes exist in these rows or columns. By translating one portion of the support on one side of a glide plane with respect to the portion of the

support on the other side, the square microcells are . converted into a serpentine microgroove, but the shadowing utility of the support is not changed. Ιf additional lateral walls are provided aligned with 5 the glide planes, the serpentine microgrooves. formed by displacing halves of the first set of rectangular microcells, become rectangular microcells again, with two rectangular microcells being present where only one existed prior to displacement 10 along the glide plane. In like manner, the serpentine microgroove formed by displacement along a glide plane running through the square microcells is replaced by a series of smaller rectangular microcells which are equal in length to the sides of the 15 squares initially present, but smaller in width. The variants of the support 3000 that can be created by displacement along glide planes should be apparent by comparing supports 2300 and 2400 in light of the above description.

20 Figure 31 illustrates a preferred support 3100 for use in the practice of this invention which is (1) capable of entirely separating three different compositions by intervening lateral walls, similarly as supports 2800, 2900, and 30000 (2) 25 capable of providing equal microareas in each of three different sets, similarly as supports 2900 and 3000, (3) capable of providing equal volumes in each of three separate microcell sets, similarly as support 3000, (4) capable of being uniquely 30 addressed in each of three separate sets of microcells, a capability not shared by any of the supports previously discussed, and (5) capable of providing a more symmetrical distribution of three compositions than the support 3000.

35 The support 3100 can be resolved into a plurality of pixels 3118 each containing three identical microcells 3106 which are diamond-shaped in plan view. Each microcell within the pixel

belongs to a separate set of microcells. A first . set of the microcells is positioned so that the longest dimension of each microcell is aligned with or parallel to a first axis 3120. A second set of microcells is similarly positioned with respect to a second axis 3122, which intersects the first axis at a 60° angle. In like manner a third set of microcells is similarly positioned with respect to a third axis 3124, which intersects each of the first 10 and second axes at an angle of 60°. If the support 3100 is viewed in section along any one of the first, second, or third axes it would appear similar to the sectioned support shown in Figure 23B (ignoring wall structures outside of the section plane).

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If the support 3100 is uniformly exposed at an acute angle with respect to its axial plane similarly as the support 2300 in Figure 23B or the support 2500 in Figure 5B in a direction indicated by the arrow 3126, which is parallel to the first 20 axis, the bottom wall of each microcell of the first set can be exposed to radiation in the microarea 3128 while the bottom walls of the second and third sets of microcells remain entirely shadowed. If a second exposure is given at the same acute angle, 25 but in the opposite direction, as indicated by arrow 3130, the bottom walls of the first set of microcells are again exposed, this time in only the microareas 3132. Again the bottom walls of the second and third sets of microcells remain entirely 30 shadowed.

It can thus be seen that two uniquely addressed microareas can be formed by angled exposure of the bottom walls of the first set of microcells. After the first angled exposure, a first 35 composition can, if desired, be introduced as a function of exposure so that it is selectively positioned in only the microareas 3128. After the second exposure a second composition can be similarly selectively positioned in only the microareas 3132. Alternatively, both the first and second exposures can occur before any composition is introduced, and a single composition can then be introduced so that it is selectively positioned in the microareas 3128 and 3132 only.

5

By analogy it is apparent that if the procedure described above is twice repeated, the second and third sets of microcells can be similarly 10 uniquely addressed and up to four additional compositions placed in uniquely addressed interlaid sets of microareas. Uniform exposure in the direction indicated by arrow 3134, but otherwise identical to the first uniform exposure uniquely addresses 15 microareas 3136 while leaving the remainder of the bottom walls in shadow. A reversed exposure in the direction indicated by arrow 3138 uniquely addresses microareas 3140 while leaving the remainder of the bottom walls in shadow. Uniform exposure in the 20 direction indicated by arrow 3142 uniquely addresses microareas 3144 while a reversed exposure in the direction indicated by arrow 3146 uniquely addresses microareas 3148. Thus, six separate uniquely addressed microareas cnn be produced and six sepa-25 rate compositions can be introduced, each selectively positioned in a separate microarea. It is generally preferred to position three compositions in the microcells so that a different composition lies in each set of microareas.

In looking at the support 3110, it is apparent that it is merely representative of a family of possible supports having generally similar capabilities. For example, any one of the axes 3120, 3122, and 3124 shown in the drawings is merely one axis arbitrarily selected for purposes of illustration from among a family of identical parallel axes. Further, each family of axes constitutes a family of glide planes. By relatively

displacing portions of the support in the axial

plane of the support along one or up to the entire
family of glide planes, essentially functionally
identical supports can be created which have differently shaped microcells, microgrooves, and/or
microareas. To avoid converting microcells into
serpentine microgrooves by lateral displacement
additional lateral walls can be located along the
glide planes.

10 To illustrate the effect of displacement along glide planes, in Figure 32 a support 3200 is shown differing from the support 3100 by lateral displacement of adjacent portions of the support along glide planes 3220A and 3220B. This displace-15 ment converts one set of microcells having major axes in the glide plane 3220A into serpentine microgrooves which cross and recross this glide plane. Along the glide plane 3220B an additional lateral wall 3208 is provided so that the one set of 20 microcells having major axes in the glide plane are converted by displacement and the lateral walls to triangular microcells of approximately half the area, but twice the number, of the corresponding diamond-shaped microcells in support 3100. The 25 additional lateral walls 3208 can be present along both glide planes 3220A and 3220B or omitted entirely. The first and second sets of microcells are identical to those of support 3100. The shadowing utility of the support 3200 is identical to that 30 of the support 3100. Since the microcells of the first, second, and third sets are identical and form a symmetrical pattern in support 3100, it is apparent that identical patterns result from displacement along glide planes aligned with the 35 major axis of any one of the three sets of microcells. In terms of capabilties and use the support 3200 is substantially the same as support 3100.

Referring again to support 3100, three axes 3152, 3154, and 3156 are present extending through or parallel to the minor axes of the three sets of microcells. These three axes intersect at 60° 5 angles. Using any one of these axes as a glide plane and displacing the portions of the support lying on either side of the glide plane in the axial plane of the support, one set of microcells can be converted from diamond-shaped microcells to trian-10 gular microcells of approximately half the area, but twice the number. When this type of glide plane variation is undertaken, the result is a support that possesses the capabilities of support 3100, except the capability of uniquely addressing the 15 triangular set of microareas produced by lateral displacement. The triangular microcells can still be addressed similarly as the square microcells in the support 3000, however.

In Figure 33 an additional preferred 20 support 3300 for use in the practice of this invention is illustrated. The support is provided with first and second sets of diamond-shaped microcells 3306A and 3306B. The microcells of each of the first and second sets have major axes lying along 25 parallel axes, while the axes of one set intersect those of the other set at a 60° angle. A third set of microcells 3306C is rectangular in shape. major axes of the rectangular microcells are substantially parallel to each other and intersect the axes of the first and second microcells at 60° 30 angles. Thus, in terms of microcell content the support 3300 differs from the support 3100 in substituting for one set of diamond-shaped microcells a set of rectangular microcells. and second sets of microcells can be uniquely addressed in microareas 3326, 3332, 3336, and 3340, which are identical to corresponding microareas in support 3100. The rectangular microcells can be

uniquely addressed in microareas 3344 and 3348. which differ in shape from the corresponding uniquely addressed microareas in the support 3100. In terms of relative placement of microcells, it can be seen that the microcells of each set form a 5 separate column in the support 3300. Adjoining columns are shown separated by glide planes 3320A, 3320B, and 3320C. It is apparent that any column can be laterally displaced in the axial plane of the 10 support without in any way affecting the remaining columns or their function. For certain applications, such as linear scanning, the columnar arrangement of the microcells in support 3300 is particularly advantageous. Although the microcell pattern of support 3300 is less symmetrical than that of support 3100, it otherwise offers all the capabilities of the support 3100.

Each of the supports 3100, 3200, and 3300 contain microareas within each microcell, shown as 20 shadowed areas, which cannot be uniquely addressed. These areas are shadowed when the remaining bottom wall areas of each set of microareas is addressed with radiation at an acute angle with respect to the axial plane of the support. In some applications 25 the shadowed areas can be left free of any composition. That is, one or two compositions can be introduced into a microcell in only the uniquely exposed microareas thereof without taking any further steps to introduce an additional composition 30 in the remaining microareas. If the compositions introduced in uniquely addressed microareas are not capable of lateral spreading, the shadowed bottom wall portions remaining will have no composition associated therewith. Where compositions capable of 35 lateral spreading are introduced into the uniquely addressed microareas, they can spread over the entire bottom wall of each microcell in which they are contained. For example, if a mobile cyan,

magenta, or yellow dye is positioned in one uniquely addressed microarea of a microcell and a different mobile subtractive primary dye is placed in the remaining uniquely addressed microarea in the same microcell, one of three different additive primary colors, depending on the combination of subtractive primaries chosen, can be produced as the mobile dyes wander over the entire bottom wall of the microcell.

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Where compositions are introduced into the 10 uniquely addressed microareas of the supports 3100. 3200, or 3300 and it is desired to place a composition also in the shadowed areas remaining, this can be undertaken using techniques similar to those described above. For example, if the bottom walls 15 of the support are transparent and colorants are placed in the uniquely addressed areas, it may be undesirable to have transparent microareas as well as colored microareas. It is possible to selectively position an additional, high density or opaque composition in all of the shadowed microareas remaining to eliminate transparent microareas in the support. Since the lateral walls are capable of interrupting radiation, radiation cannot penetrate these areas of the support. Where a technique is 25 employed for positioning the additional composition that requires the initially shadowed microareas to be exposed to radiation, the support can be exposed in a direction substantially perpendicular to its axial plane and the exclusion properties of the previously positioned materials employed can be relied upon to position selectively the additional composition in the initially shadowed microareas. Where a technique is employed for positioning the additional composition in initially shadowed areas 35 that allows a material to be selectively positioned in unexposed areas, the additional composition can be selectively positioned without relying upon any exclusion capability by any composition previously

positioned and without exposing the initially shadowed areas to radiation.

In various embodiments described above it is suggested to expose the support substantially 5 perpendicularly to its axial plane where shadowing is not desired. In some instances this can be disadvantageous, since the radiation source is fixed at a particular acute angle for shadowing exposures and it may be inconvenient to provide a second 10 radiation source or relocate the radiation source used for shadowing. An alternative is possible when the lateral walls are capable of interrupting radiation, but are not entirely opaque. For example, if transparent lateral walls are dyed to 15 the extent necessary to provide shadowing, they may still be penetrable by radiation of increased intensity. In such instances it is contemplated to give the support a first uniform exposure at an acute angle, choosing a level of radiation intensity 20 which permits the lateral walls to interrupt the radiation and provide shadowing as required. Thereafter, when exposure of the shadowed areas is required, the same radiation source at the same acute angle can be increased in intensity and used 25 to reexpose the support. This time sufficient radiation penetrates the lateral walls to allow exposure of the initially shadowed areas. Instead of altering the intensity of radiation between exposures, a change in the wavelength or even type 30 of radiation can be relied upon to allow shadowing in one instance, but not another. Transparent lateral walls containing an ultraviolet absorber can interrupt ultraviolet radiation while permitting penetration of visible light. Similarly lateral 35 walls which are dyed to appear visibly opaque may nevertheless absorb little ultraviolet radiation.

In the preferred embodiments of the invention, described in connection with supports 2800,

2900, 3000, 3100, 3200, and 3300, one set of microareas can be entirely separated from all other sets of microareas by lateral walls. However, because of shadowing by the lateral walls, the entire bottom 5 wall surface between these boundary forming lateral walls cannot be entirely exposed at one time. some geometrical forms of the support, such as support 3000, the entire bottom wall surface between boundary forming lateral walls (e.g., the entire 10 bottom wall of a microcell) can be addressed by a combination of two exposures if the support is rotated 180° or the second radiation source is changed in direction. In some instances, however, this still leaves bottom wall surfaces shadowed that 15 are not intended to be differentiated from exposed microareas within the same lateral wall boundary. For example, the shadowed areas shown in the supports 3100, 3200, and 3300 can represent a significant inconvenience and limitation where it is 20 desired to locate three compositions, each in a different set of microcells, so that each composition entirely covers the bottom walls of its microcell set.

an entire bottom wall surface bounded by lateral walls, such as the entire bottom wall surface of a microcell, to form a single microarea, but exposure at an acute angle casts a shadow over at least a portion of the microarea, it is specifically contemplated to modify the support to either spread the radiation itself or to spread whatever modifying effect the radiation produces over the entire microarea. The specific approach for accomplishing this objective can be varied, depending upon the specific application the support is intended to serve.

In another form, a removable cover, preferably bearing a semitransparent reflective coating,

can be laid over the first major surface of the support to aid in reflecting, if desired. Exposure must, of course, occur through the cover. The lateral walls can be relied upon to prevent radiation from scattering beyond the intended boundary of the microarea.

5

Where the support or at least the bottom wall portion of the support is a photoconductor, as described above, a conductive layer which is at least partially transparent can be placed selectively on the the bottom wall surfaces. Without the conductive layer present only the bottom wall portions actually exposed to radiation are increased in conductivity, but with the conductive layer present, if any portion of a lateral wall bounded bottom wall is struck by radiation to which the photoconductor is responsive, the effect in terms of static charge retention is as though the entire bottom wall had been radiation struck.

Another approach applicable to supports generally (i.e., not limited to reflective or photoconductive supports, but also fully applicable to transparent and insulative or conductive supports) is to locate a fluor on the bottom wall surfaces. Exposure in one microarea stimulates emission of radiation by the fluor and causes the entire bottom wall portion in the bounded area to be exposed to either direct or stimulated radiation. Again, the lateral walls can be relied upon to prevent radiation scattering beyond the intended boundary of the microarea.

In a very simple form of the invention the bottom walls of the supports can themselves be relied upon to distribute radiation over a bottom wall surface. It is generally recognized that even a polished transparent support will reflect some radiation. For applications requiring very little radiation, the inherent light scattering property of

unmodified bottom walls can be sufficient to distribute a useful amount of radiation over the entire bottom wall surface. Scattering of radiation by the bottom walls can be significantly increased by roughening the bottom walls of the support.

5

In the foregoing exemplary embodiments the lateral walls of the microcells have been shown to be perpendicular to the bottom walls. However, where the lateral walls are reflective and particularly where the microcell walls have been mirrored, as discussed above, this can result in reflection of radiation into areas of the microcells intended to be shadowed. It is contemplated that unwanted reflection into microcell areas intended to be shadowed can be avoided by providing lateral walls which slope with respect to the bottom walls ofthe microcells.

Such an arrangement is shown in Figure 34.

The support 3400 is shown provided with lateral

walls 3402 which are in section of a keystone or
wedge shape. The lateral walls form obtuse angles
with the bottom walls. The slope of the lateral
walls is preferably chosen so that exposing radiation strikes the lateral walls at less than a 90°

angle and is reflected upwardly away from the bottom
wall and out of the microcell. If the slope of the
lateral wall is increased so that incident radiation
strikes the lateral wall at greater than a 90° angle
measure from the lateral wall surface, the opposite

effect, namely reflection down into the microcell,
will occur.

Although the invention has been specifically described by reference to preferred nonplanar supports, it is appreciated that still other nonplanar support structures can be employed, such as those described by Land, Gerber, and Walworth, cited above.

Example 1

Sample reaction microcells were prepared in the following manner:

- A pattern of hexagons 20 microns in width 5 and approximately 10 microns high was formed on a copper plate by etching. Using the etched plate having hexagon projections, dichloromethane and ethanol (80:20 volume ratio) solvent containing 10 grams per 100 ml of Genacryl OrangeR, a yellow azo 10 dye, was placed in contact with a cellulose acetate photographic film support for six seconds. Hexagonal depressions were embossed in the softened support, forming reaction microcells. The yellow dye was absorbed in the cellulose acetate film 15 support areas laterally surrounding, but not beneath, the reaction microcells, giving a blue density.
- В. Using an alternative technique, the desired hexagon pattern for the reaction microcells was 20 developed in a fine grain silver bromoiodide emulsion coated on a cellulose acetate photographic film support. The pattern was spin overcoated first with a very thin layer of a negative photoresist comprised of a cyclized polyisoprene solubilized in 25 2-ethoxyethanol and sensitized with diazobenzilidene-4-methylcyclohexanone. The pattern was then spin overcoated with an approximately 10 micron layer of a positive photoresist comprised of a cresylformaldehyde resin esterified with 6-diazo-30 5,6-dihydro-5-oxo-1-naphthalene sulfonyl chloride solubilized in 2-ethoxyacetate together with a copolymer of ethyl acrylate and methacrylic acid, the resist being stabilized with glacial acetic acid. The thin layer of negative photoresist 35 provided a barrier between the incompatible gelatin and positive photoresist layers. To prevent nitrogen bubble formation in the negative photoresist, an

overall exposure was given before the positive

photoresist layer was added. Exposure through the film pattern and development produced reaction microcells in the positive photoresist.

C. Using still another method, an aqueous

mixture of 12 1/2 by weight percent bone gelatin
plus 12 percent by weight of a 2 by weight percent
aqueous solution of ammonium dichromate (to which
was added 1 1/2 ml conc. NH₄OH/100 ml of the
aqueous mixture) was coated on a cellulose acetate
photographic film support with a 200 micron doctor
coating blade. Exposure was made with a positive
hexagon pattern using a collimated ultraviolet arc
source. Development was for 30 minutes with a hot
(41°C) water spray. Reaction microcells with sharp,
well defined walls were obtained.

By each of the above techniques, reaction microcells were formed ranging from 10 to 20 micron in average diameter and from 7 to 10 microns in depth with 2 micron lateral walls separating adjacent microcells.

Example 2

A fast, coarse grain gelatino-silver bromoiodide emulsion was doctor-coated onto a sample of an embossed film support having reaction micro25 cells prepared according to Example 1A and dried at room temperature. A comparison coating sample was made with the same blade on an unembossed film support. Identical test exposures of the embossed and unembossed elements were processed for 3 minutes in a surface black-and-white developer, as set forth in Table I.

Table I

Black-and-White Developer

	Water (50°C)	500 cc
	p-Methylaminophenol sulfate	2.0 g
5	Sodium sulfite, desiccated	90.0 g
	Hydroquinone	8.0 g
	Sodium carbonate, monohydrated	52.5 g
	Potassium bromide	5.0 g
	Water to 1 liter	

In a comparison of 7X enlarged prints made from the embossed and unembossed elements, the image made from the embossed element was visibly sharper.

Example 3

A coarse grain gelatino-silver bromoiodide

15 emulsion was doctor-coated onto a sample of an
embossed film support having reaction microcells
prepared according to Example 1A. The silver
bromoiodide emulsion was then overcoated with an
emulsion of fine grain, internally fogged converted

halide silver bromide grains. Exposure and development of the coarse grains released iodide which diffused to the fine grain emulsion, disrupting the grains and making them imagewise developable in the surface developer.

25 Example 4

A coarse grain silver bromoiodide emulsion was doctor-coated onto a sample of an embossed film support having reaction microcells prepared according to Example 1A and dried at room temperature.

30 After exposure the sample was developed in a lithtype developer of the composition set forth in Table II in which parts A and B were mixed in a volume ratio of 1:1 just prior to use. Extreme contrast was obtained without loss of sharpness.

-188-

Table II

Lith Developer

	A)	Hydroquinone	28.	6 g
		Sodium sulfite, desiccated	8.	0 g
5		Sodium formaldehyde bisulfite	134	g
		Potassium bromide	2.	4 g
		Water to 1 liter		
	B)	Sodium carbonate.H ₂ O	160	g
		Water to 1 liter		

10 Example 5

A high speed, coarse grain gelatino-silver bromoiodide emulsion was doctor-coated onto a sample of the film support having reaction microcells prepared according to Example 1B. A first sample of the element was imagewise exposed and was then developed in a black-and-white developer, as set forth in Table III.

<u>Table III</u> Black-and-White Developer

20	Water	970 m1
	Sodium sulfite	2 g
	1-Phenyl-3-pyrazolidone	1.5 g
	Sodium carbonate 20 g	
	Potassium bromide	2 g
25	6-Nitro (as 1/10 percent solution)	40 mg
	Water to 1 liter	

The first sample was washed in water and immersed in a fix bath of the composition set forth in Table IV.

30	Table IV	
	Fix Bath	
	Water (50°C)	600 cc
	Sodium thiosulfate	360.0 g
	Ammonium chloride	50.0 g
35	Sodium sulfite, desiccated	15.0 g
	Acetic acid, 28 percent	48.0 cc
	Boric acid, crystals	7.5 g
	Potassium alum	15.0 g
	Water to 1 liter	

The first sample was washed in water and allowed to dry. The sample was then immersed in a rehalogenizing bath of the composition set forth in Table V.

5	Table	V

Rehalogenizing Bath

Potassium ferricyanide 50 g Potassium bromide 20 g

Water to 1 liter

The first sample was washed in water and was then developed in the color developer set forth in Table VI.

Table VI

Color Developer

15	Sodium sulfite	2.0 g
	$4-(p-Toluenesulfonamido)-\omega-benzoyl$	
	acetanilide (dissolved in	
	alcoholic sodium hydroxide)	0.8 g
	N, N-diethyl-p-phenylenediamine• HCl	2.5 g
20	Sodium carbonate•H ₂ O	20 g
	2,5-Dihydroxy-p-benzene	
	disulfonic acid (dissolved	
	in alcoholic sodium hydroxide)	7.5 g
	Water to l liter, pH 11.2	

The first sample was washed in water and immersed in a bleach bath of the composition set forth in Table VII.

Table VII

Bleach Bath

Potassium ferricyanide 50 g
Potassium bromide 20 g

Water to 1 liter

The first sample was immersed in a fix bath of the composition set forth above in Table IV after which it was washed in water.

A second sample was similarly exposed and processed through the step of immersion in the fix bath (first occurrence). The images obtained using

the first and second samples were enlarged 10X onto a light-sensitive commercial black-and-white photographic paper. Graininess, due to the silver grain, was very apparent in the enlargement prepared from the second sample but was not visible in the enlargement prepared from the first sample. In the

enlargement prepared from the first sample. In the first sample, no grain was evident within the individual microcells. Rather, a substantially uniform intramicrocell dye density was observed.

10 Example 6

5

Coatings were made as follows: A magenta coupler, 1-(2,4-dimethyl-6-chlorophenyl)-3-[(3-m-pentadecylphenoxy)butyramide]-5-pyrazolone, was dispersed in tricresyl phosphate at a weight ratio of 1:1/2. This dispersion was mixed with a fast

gelatino-silver bromoiodide emulsion and doctorcoated onto a sample of a film support having a
pattern of 20 micron average diameter reaction
microcells prepared as discussed in Example 1A. For
comparison, a coating with the same mixture, but

without reaction microcells was made. Identical line test exposures on each coating were processed in the following manner:

The coating was developed for 3 minutes in 25 a black-and-white developer of the composition set forth in Table VIII.

<u>Table VIII</u> Black-and-White Developer

	Water (50°C)	500 cc
30	p-Methylaminophenol sulfate	2.0 g
	Sodium sulfite, desiccated	90.0 g
	Hydroquinone	8.0 g
	Sodium carbonate, monhydrated	52.5 g
	Potassium bromide	5.0 g
35	Water to 1 liter	

The coating was immersed in a fix bath of the composition set forth in Table IX.

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Fix Bath

	Water (50°C)	600 cc
	Sodium thiosulfate	360.0 g
5	Ammonium chloride	50.0 g
	Sodium sulfite, desiccated	15.0 g
	Acetic acid, 28 percent	48.0 cc
	Boric acid, crystals	7.5 g
	Potassium alum	15.0 g
- ^		

10 Water to 1 liter

The coating was washed in water. It was then reactivated 15 minutes in 25 weight percent aqueous potassium bromide and was washed for 10 minutes in running water, followed by development for 3 minutes in a peroxide oxidizing agent containing color developer of the composition set forth in Table X.

Table X Color Developer

	Color Beveloper	
20	Potassium carbonate	20 g
	Potassium sulfite, desiccated	2 g
	4-Amino-3-methyl-N-ethyl-N-B-	
	(methanesulfonamido)ethyl	
	aniline sulfate hydrate	5 g
25	Sodium hexametaphosphate	1.5 g
	Hydrogen peroxide (40 percent)	10 m1
	Water to 1 liter	

The coating was then washed in water.

Large amounts of dye were formed in both coatings. The comparison coating without the reaction microcells showed gross spreading of dye and image degradation. The reaction microcell coating spread was confined by the reaction microcells and showed no signs of intercell spreading.

35 Example 7

A cellulose acetate photographic film support was embossed with a pattern of reaction microcells approximately 20 microns in average diameter and 8 microns deep prepared according to Example 1A. A fast gelatino-silver bromoiodide emulsion was doctor-coated onto the film support having reaction microcells and dried at room temperature. An image of a line object was developed for two minutes in a black-and-white developer of the composition set forth in Table XI.

Table XI

10	Water (50°C)	500 cc
	p-Methylaminophenol sulfate	2.0 g
	Sodium sulfite, desiccated	90.0 g
	Hydroquinone	8.0 g
	Sodium carbonate, monohydrated	52.5 g
15	Potassium bromide	5.0 g
	Water to 1 liter	

The sample was immersed in a fix bath of the composition set forth in Table XII.

20 Table XII Fix Bath

5

20	Fix Bath	
25	Water (50°C)	600 cc
	Sodium thiosulfate	360.0 g
	Ammonium chloride	50.0 g
	Sodium sulfite, desiccated	15.0 g
	Acetic acid, 28 percent	48.0 cc
	Boric acid, crystals	· 7.5 g
	Potassium alum	15.0 g
	Water to 1 liter	

The sample was washed in water and dried.

30 It was overcoated with a dispersion of 2-[α-(2,4-di-tert-amylphenoxy)butyramido]-4,6-dichloro-5-methylphenol, hardened for two minutes in formalin hardener and was then washed in water. The sample was activated for 15 minutes in 25 percent by weight aqueous solution of potassium bromide and was washed for 10 minutes in water, followed by development for 5 minutes in a peroxide color developer of the composition set forth in Table XIII.

-193-

Table XIII

Color Developer

	Potassium carbonate	20 g
	Potassium sulfite, desiccated	2 g
5	4-Amino-3-methyl-N-ethyl-N-ß-	
	(methanesulfonamido)ethyl	
	aniline sulfate hydrate	5 g
	Sodium hexametaphosphate	1.5 g
	Hydrogen peroxide (40 percent)	10 ml
10	Water to 1 liter	

10 Water to 1 liter

Within the exposed microcells a random pattern of silver specks were formed by development in the black-and-white developer. Subsequent development in the color developer produced a cyan 15 dye within areas subtended by the microcells containing the silver specks. The cyan dye was uniformly distributed within these microcell subtended areas and produced greater optical density than the silver specks alone. The result was to 20 convert a random distribution of silver specks within the microcells into a uniform dye pattern. Example 8

Two donor elements for image transfer were provided, each having an imagewise distribution of 25 an alkali diffusible cyan coupler, 2,6-dibromo-1,5-

naphthalenediol on a film support.

A receiving element was prepared by coating a cellulose acetate film support embossed according to Example 1, paragraph A, so that the microcells in 30 the support were filled with gelatin. To provide a control-receiving element, a second, planar cellulose acetate film support was coated with the same gelatin to provide a continuous planar coating having a thickness corresponding to that of the 35 gelatin in the microcells.

Each of the receiving elements was immersed in the color developer of Table XIV and then laminated to one of the donor sheets.

-194-

TABLE XIV

Color Developer

	Benzyl alcohol	12 m1
	Sodium sulfite, desiccated	2.0 gm
5	4-Amino-3-methyl-N,N-	
	diethylaniline monohydro-	
	chloride	2.5 gm
	Sodium hydroxide	5.0 gm
	Water to 1 liter	

- 10 After diffusion of the cyan coupler to the receiving elements, the receiving and donor elements were peeled apart. The receivers were then treated with a saturated aqueous solution of potassium periodate to form the cyan dye.
- The cyan dye image formed in the receiving element having the microcells was perceptably sharper than the one formed in the control receiving element with the planar support and continuous gelatin layer.

20 Example 9

- A. Nine grams of a finely divided immobile particulate green pigment, Monolite Green GN, was mixed with 4.5 grams of a copolymer of <u>tert</u>-butyl-styrene and lithium methacrylate along with 85.5
- grams of Solvesso 100° (an isoparaffinic hydrocarbon liquid having a boiling point in the range of from 145 to 185°C, sold commercially by Exxon). The concentrate was ball-milled for two weeks at room temperature.
- B. Four grams of a finely divided immobile particulate red pigment, Red Violet MR° (Hoechst), was mixed with 4.0 grams of a copolymer of tert-butylstyrene, lauryl methacrylate, lithium methacrylate, and methacrylic acid in the weight ratio of
- 35 60:36:3.6:0.4 (hereinafter designated TBS) and 36.0 grams of Solvesso 100°. The concentrate was ball-milled for two weeks at room temperature.

C. Ten grams of a finely divided immobile particulate blue pigment, Monolite Blue (ICI), was mixed with 14.0 grams of TBS and 126.0 grams of Solvesso 100°. The concentrate was ball-milled for two weeks at room temperature.

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- D. Four and one-half grams of a mobile magenta dye-forming coupler, 1-(2-benzothiazoly1)-3-amino-5-pyrazolone, was mixed with 4.5 grams of TBS and 40.5 grams of Solvesso 100°. The concentrate was ball-milled for two weeks at room temperature.
 - E. The procedure of Paragraph D was repeated, except a mobile cyan dye-forming coupler, 2,6-di-bromo-1,5-naphthalenediol, was substituted for the magenta dye-forming coupler.
- F. A mobile yellow dye-forming coupler,
 α-(4-carboxyphenoxy)-α-pivaly1-2,4- dichloro acetanilide, in the amount of 3.14 grams was mixed
 with 3.14 grams of TBS and 28.3 grams of Solvesso
 100°. The concentrate was ball-milled for two
 weeks at room temperature.
 - G. The green pigment concentrate of Paragraph A and the magenta dye-forming coupler concentrate of Paragraph D were mixed in equal weights of 3.85 grams each with 4.55 grams of a 10 percent by weight solution of a copolymer of ethyl acrylate, ethyl methacrylate, lauryl methacrylate, and lithium
- this mixture was added Isopar G° (an isoparaffinic hydrocarbon liquid having a boiling point in the range of 145 to 185°C commercially available from Exxon) at the rate of 6 ml per minute for the first 50 ml and then at the rate of 15 ml per minute until the volume of the developer reached 500 ml.

sulfoethyl methylacrylate in Solvesso 100°. To

H. The procedure of Paragraph G was repeated,
except the red pigment concentrate of Paragraph B
was substituted for the green pigment concentrate of
Paragraph A and the cyan dye-forming coupler concentrate of Paragraph E was substituted for the magenta

dye-forming coupler concentrate of Paragraph D.

- I. The procedure of Paragraph G was repeated, except the blue pigment concentrate of Paragraph C was substituted for the green pigment concentrate of Paragraph A and the yellow dye-forming coupler concentrate of Paragraph F was substituted for the magenta dye-forming coupler concentrate of Paragraph D.
- J. A conventional planar photoconductive

 element consisting of a transparent 102 micron thick
 poly(ethylene terephthalate) film base coated with a
 transparent 0.2 micron cuprous iodide electrically
 conductive layer which was in turn overcoated with
 an 8 micron organic photoconductive layer was
- employed as a starting material. The photoconductive element is commercially available as a recording film under the trademark Kodak Ektavolt SO-101. The recording film and its characteristics are generally described in A Mini-Textbook--KODAK
- Products for Electrophotography, Kodak Publication No. G-95, Standard Book Number 0-87985-233-X, Eastman Kodak Company, 1979. The conductive layer and film base extend laterally beyond the photoconductive layer along one edge to allow convenient

An array of hexagonal projections 20 microns in width and approximately 7 microns high was formed on a copper plate by etching in generally the same manner described in the Whitmore patent application cited above. An embossing solvent was placed on the plate between one edge of the array of projections and a strip of pressure-sensitive tape employed to restrain migration of the solvent away from the projections. A sheet of the recording film was placed on the plate with the photoconductive layer adjacent the projections, and the resulting

sandwich was advanced beneath a roller with the edge

bearing the embossing solvent passing beneath the

roller first. The pressure exerted by the roller and the softening action of the embossing solvent being spread laterally at the roller nip resulted in a hexagonal array of microcells being formed on the photoconductive layer having lateral and bottom 5 walls corresponding to the walls of the hexagonal The embossing solvent was a roughly projections. equal volume mixture of methanol and dichloromethane containing 0.51 parts by volume per 100 parts of 10 solvent Sundan Black B (Color Index No. 26150). As a result, the lateral walls of the microcells were dyed black, since the dye entered the photoconductive layer along with the embossing solvent. bottom walls of the microcells remained transparent, 15 however.

The embossed photoconductive portion of the Κ. support was given a charge of +500 volts by being passed through a corona discharge. The conductive electrode was attached to ground. Except as stated 20 the support was not intentionally exposed to light to which the photoconductive portion was responsive. The positively charged support was scanned with a laser having a wavelength of 482 nm. area of the support evry third row of microcells was 25 scanned. In another area all of the microcells were scanned. For selected row scanning an indexing laser was employed in combination with the scanning laser. The indexing laser was of a red wavelength to which the photoconductive portion was not responsive. The indexing laser was employed in combination with a photosensor to detect the position of the lateral walls of the microcells. Thus, three interruptions of the indexing laser beam detected by the photosensor in advancing the support provided a 35 positive indication that the support had been advanced three rows of microcells. The dyed lateral walls of the microcells facilitated indexing as well as obviating light scatter to adjacent microcells.

After the laser scan was completed the support was electrophotographically developed using the electrophotographic developer of Paragraph G using a development time of 10 seconds and a general development technique and apparatus of the type described in Beyer et al U.S. Patent 3,407,786. A development electrode biased to +200 volts was employed.

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electrophotographic developers of Paragraphs H and
I. The result was an element having in one area
interlaid rows of microcells containing the electroscopic imaging compositions of Paragraphs G, H and
I. Under microscopic examination there was no
evidence of any overlap of the imaging compositions. In three separate areas all of the microcells were filled with one of the three electroscopic imaging compositions.

L. The element produced by Paragraph K was

20 employed to form a multicolor screened positive
using additive primary pigments and a transferred
multicolor negative using subtractive primary dyes
formed by the mobile couplers.

The filled microcells were overcoated with 25 a mixed silver sulfide and silver iodide silver precipitating agent dispersed in 2 percent by weight gelatin using a 50 micron coating doctor blade spacing. A commercially available black-and-white photographic paper having a panchromatically sensi-30 tized gelatino-silver chlorobromide emulsion layer was attached along an edge to the support with the emulsion layer of the photographic paper facing the microcell containing surface of the support. photographic paper was imagewise exposed through the 35 support (and therefore through the filters formed by the pigments in the microcells) with the elements in face-to-face contact. After exposure, the elements were separated, but not detached, and immersed for 3

-199-

seconds in the color developer of Table XV.

TABLE XV

Color Developer

	Benzyl alcohol	12 m1
5	Sodium sulfite, desiccated	2.5 gm
	4-Amino-3-methyl-N,N-	
	diethylaniline monohydro-	
	chloride	2.5 gm
	Sodium hydroxide	5.0 gm
10	Sodium thiosulfate	10.0 gm
	6-Nitrobenzimidazole	
	nitrate	20 mg

Water to 1 liter

Thereafter, the elements were restored to face-to
face contact for 1 minute to permit development of
the imagewise exposed silver halide and image
transfer to occur. The elements were then separated, and the silver image was bleached from the
photographic paper. A three-color negative image
was formed by subtractive primary dyes in the
photographic paper while a three-color screened
positive image was formed by the additive primary
filters and the transferred silver image on the
support.

25 Example 10 Formation of Transferred Multicolor Positive

Example 9 was repeated, but with a silver halide emulsion layer coated over the filled microcells and the silver nucleating agent layer being coated on a separate planar film support. The emulsion layer was a high-speed panchromatically sensitized gelatino-silver halide emulsion layer coated with a 150-micron coating doctor blade spacing. The color developer was of the composition set forth in Table XVI.

-200-

TABLE XVI

Color Developer

	Benzyl alcohol	12 m1
	Sodium sulfite, desiccated	2.5 gm
5	4-Amino-3-methyl-N,N-	
	diethylaniline monohydro-	
	chloride	2.5 gm
	Sodium hydroxide	7.5 gm
	Sodium thiosulfate	60.0 gm
10	6-Nitrobenzimidazole	
	nitrate	20 mg
	Potassium bromide	2.0 gm
	1-Phenyl-3-pyrazolidone	0.2 gm
	Water to 1 liter	•

15 Both elements were immersed in the color developer for 5 seconds and thereafter held in face-to-face contact for 2 minutes. A screened three-color negative was obtained on the support and a transferred positive silver and multicolor positive dye image was obtained on the planar support.

Both elements were immersed in the color developer for 5 seconds and thereafter held in face-to-face contact for 2 minutes. A screened three-color negative was obtained on the micro-

- 25 cellular support and a transferred positive silver and multicolor positive dye image was obtained on the planar support.
 - Example 11 Use of Immobile Additive Primary Dye
 Three grams of an immobile red dye,
- 30 Drimarene Scarlet* (Sandoz), were mixed with 3.0 grams of TBS and 27.0 grams of Solvesso 100° to form a red dye containing concentrate. The concentrate was ball-milled for two weeks at room temperature.
- 35 Example 12 Green Imaging Particles Produced By
 Immobile Yellow and Cyan Dyes
 Twenty grams of 1-(2,4,6-trichlorophenyl)3-[3-(2,4-diamylphenoxy-acetamido)benzamido]-4-(p-

methoxyphenylazo)-5-pyrazolone, a yellow-colored ballasted coupler, here employed as a substantially immobile yellow dye, and 40 grams of

a substantially immobile cyan dye, were melted and diluted to a volume of 750 ml with water to form an aqueous concentrate. To this concentrate were added 3.0 grams of 1-(2,4,6-trichlorophenyl)-3-(4-nitroanilino)-5-pyrazolone, a mobile magenta dyeforming coupler. The magenta dye-forming coupler was dissolved in methanol and 5 percent by weight 20 sodium hydroxide.

The resulting concentrate was formed into a particulate dispersion by forming a mist using a DeVilbus (Model 65)* ultrasonic nebulizer. The mist was passed through an air drying column, and the neubulized solids were collected.

Example 13 Red Imaging Particles Produced by Immobile Yellow and Magenta Dyes

The procedure of Example 12 was repeated, except that 30 grams of

30
$$C1 - \frac{1}{1000} - \frac{1}{100$$

a substantially immobile ballasted magenta dye, was substituted for the substantially immobile cyan dye and the mobile cyan coupler, 1-hydroxy-2-[β -(2'-aceatamido)phenethyl]naphthamide, was substituted for the mobile magenta coupler.

Example 14 Blue Imaging Particles Produced by Immobile Cyan and Magenta Dyes

The procedure of Example 13 was repeated, except that 30 grams of the substantially immobile cyan dye of Example 12 was substituted for the substantially immobile yellow dye and a mobile yellow dye-forming coupler, α-(4- carboxy-phenoxy)-α-pivaly1-2,4-dichloroacetanilide, was substituted for the mobile cyan coupler.

15 Example 15 Preparation of Green Electrographic
Imaging Composition Containing
Immobile Subtractive Primary Dyes
Dispersed in Carrier Vehicle to Form
Electrographic Developer and Use
Thereof

The green imaging particles of Example 12 in the amount of 0.7 gram were mixed with 7.0 grams of a 10 percent by weight solution of TBS in Solvesso 100°. These materials were placed in a container and tumbled for 24 hours to form a concentrate. The resulting concentrate was mixed in the amount of 3.40 grams with 450 ml of Isopar G using ultrasonic agitation.

The resulting electrographic imaging 30 composition was then employed substantially as described in Example 9, paragraph K, except that only a single imaging composition was employed.

Preparation of Red Electrographic Example 16 Imaging Composition Containing Immobile Subtractive Primary Dyes Dispersed in Carrier Vehicle to Form 5 Electrographic Developer and Use Thereof

One gram of the red particles of Example 16 were mixed with 10 grams of a 10 percent by weight solution of TBS in Isopar G. These materials were 10 mixed on a roller mill for 24 hours to form a concentrate. The resulting concentrate was mixed in the amount of 5.0 grams with 450 ml of Isopar G using ultrasonic agitation. The electrographic imaging composition particles in the resulting 15 electrographic developer were about 5 microns in diameter.

The electrographic developer was employed substantially as described in Example 9, paragraph K, except that only a single imaging composition was employed.

Example 17 Preparation of Blue Electrographic Imaging Composition Containing Immobile Subtractive Primary Dyes Dispersed in Carrier Vehicle to Form Electrographic Developer and Use Thereof

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The procedure of Example 16 was repeated, but with the particles of Example 14 substituted for those of Example 13. Instead of using ultrasonic 30 agitation to form the electrographic developer, a paint shaker was employed for agitation. electrographic imaging composition particles were plate-like having a maximum dimension of from 10 to 15 microns. The resulting electrographic imaging composition was then employed substantially as described in Example 11, except that only the imaging composition of this example was employed.

In comparing the electrographic imaging compositions of Examples 15 through 17 with those of Examples 9, paragraphs G, H, and J, the former exhibited longer shelf life. That is, the electro-5 graphic imaging composition particles settled at a The former also exhibited a higher slower rate. charge to weight ratio and a higher extinction coefficient. The higher extinction coefficient resulted in a higher maximum optical density. It is 10 attributed to a higher proportion of colorant, since materials such as coupler solvent and gelatin were entirely eliminated in using pigment colorants. Coupler mobility was initially observed to be higher using the compositions of Examples 15 through 17, 15 but the mobility of couplers in pigment containing compositions was found to be susceptible to increase by empirically selecting mobile couplers to be employed.

Example 18

embossing master.

20 Following a procedure similar to that of Example 9, a microcellular array was thermally embossed in the photoconductive layer of the support. The microcellular pattern was similar to that shown in Figures 30A through 30C, except that 25 pixels were displaced along glide planes so that the second set of microcells 3006B were out of major axis alignment by one-half of their width. viewing Figure 30A, the microcells appearing above the horizontal dashed line were all displaced to the 30 right one width of the microcells 3006B from the position shown. The microcells were 25 microns deep from the wall widths between adjacent microcells being 15 microns. The inside width of the square microcells of the third set 3006C was 125 microns. 35 Thermal embossing was conducted at a temperature of 82.2°C and at a pressure of 172 kPa applied to the

Example 19 Introduction of Imaging Compositions into Microcells of Support

The embossed photoconductive portion of the support was given a charge of +460 volts by being 5 passed through a corona discharge. The conductive electrode was attached to ground. Except as stated. the support was exposed as shown in Figure 30B. A Xenon arc lamp was employed controlled by an electronic shutter. Light was substantially collimated 10 and directed at an acute angle of 12° with respect to the axial plane 3014 of the support. After exposure the support was rotated 180° in the axial plane 3014 and exposed a second time. Each exposure was for 2 seconds, and the bottom walls of the first 15 set of microcells 3006A received during each exposure approximately 600 erts/cm2 in the areas exposed. Direct light exposure of bottom wall areas were limited to the bottom walls of the first set of microcells. The 15 microns width of the lateral 20 walls was sufficient to prevent light exposure of the remaining sets of microcells through the lateral walls.

After angled exposure of the first set of microcells was completed, the microcellular support was electrographically developed using an electrographic developer of the type disclosed in Example 9, paragraph H, and a development time of 15 seconds. A development electrode biased to +200 volts was employed.

The procedure described in the two preceding paragraphs was repeated, except that an electrographic developer of the type disclosed in Example 9, paragraph I, was employed and the exposure was as shown in Figure 30C rather than Figure 30B. That is, the second set of microcells 3006B were selectively addressed and filled. Thereafter the support was again recharged to +460 volts and exposed perpendicular to the axial plane 3014 at a distance

of 15.24 cm to give an exposure of approximately
1,300 ergs/cm² using a UVL Mineralite. Development was repeated as described above, but using the
electrographic developer of the type disclosed in

5 Example 9, paragraph G. After each development step and prior to recharging a forced air dryer was employed to evaporate developer solvent.

Example 20 Preparation of Photoconductive Support
Having Hexagonal Microcells

10 A conventional planar photoconductive element similar to that described in Example 18 was solvent embossed using an embossing master having an array of hexagonal projections 20 microns in width and approximately 7 microns high. An embossing solvent was placed on the plate between one edge of the array of projections and a strip of pressuresensitive tape employed to restrain migration of the solvent away from the projections. A sheet of the recording film was placed on the plate with the 20 photoconductive layer adjacent the projections, and the resulting sandwich was advanced beneath a roller with the edge bearing the embossing solvent passing beneath the roller first. The pressure exerted by the roller and the softening action of the embossing solvent being spread laterally at the roller nip resulted in a hexagonal array of microcells being formed on the photoconductive layer having lateral

bottom walls corresponding to the walls of the hexagonal projections. The embossing solvent was a roughly equal volume mixture of methanol and dichloromethane containing 0.2 gram per 10 ml of solvent Sudan Black B (Color Index No. 26150). As a result, the lateral walls of the microcells were dyed black, since the dye entered the photoconduc-

35 tive layer along with the embossing solvent. The bottom walls of the microcells remained substantially transparent, however. Example 21 Introduction of Imaging Compositions into Hexagonal Microcells of Support

The photoconductive portion of the support embossed with hexagonal microcells was given a 5 charge of +460 volts by being passed through a corona discharge. The conductive electrode was attached to ground. Except as stated, the support was not identically exposed to light to which the photoconductive portion was responsive. The positively charged support was exposed as shown in Figure 26B. A Xenon arc lamp was employed controlled by an electronic shutter. Light was substantially collimated and directed at an acute angle of 26° with respect to the axial plane of the 15 support. Exposure was in the direction indicated by the arrow 1 in Figure 26B. The time of exposure was 0.3 second. Only the bottom wall areas 1 were exposed. The microcellular support was electrographically developed using an electrographic 20 developer of the type disclosed in Example 9, paragraph I, and a development time of 10 seconds. A development electrode biased to +200 volts was employed. The developer solvent was evaporated using heated forced air. Material was selectively 25 deposited in the microareas 1 of the support.

The support was rotated 120° in the axial plane with respect to the light source, and the procedure described above was repeated, but with the substitution of an electrographic developer of the type disclosed in Example 9, paragraph G, for the developer of Example 9, paragraph I. After the developer solvent was evaporated, the support was again rotated 120° so that it occupied yet a third position with respect to the light source, and the procedure described above was again repeated, but with the substitution of the electrographic developer of Example 8. The result was the selective placement of material in the microareas 1, 2,

and 3 as shown in Figure 26B in each of the hexagonal microcells.

Example 22

A pattern of hexagons 20 microns in width 5 and approximately 10 microns high was formed on a copper plate by etching. Using the etched plate having hexagon projections, dichloromethane and ethanol (80:20 volume ratio) solvent containing 10 grams per 100 ml of Genacryl Orange-R, a yellow azo 10 dye, was placed in contact with a cellulose acetate photographic film support for six seconds. Hexagonal microcells were embossed in the softened support separated by 2 micron lateral walls, as measured at the surface of the support. The yellow 15 dye was absorbed in the cellulose acetate film support areas laterally surrounding, but not beneath, the microcells, giving a density to blue light.

A membrane was prepared by placing four 20 drops of a commercial casting solution (Microfilm Solution, Sig Manufacturing Company, Montezuma, Iowa) onto the surface of water contained in a 30 by 35 cm tray. The casting solution contained cellulose nitrate as a film-forming polymer in an organic 25 solvent comprised of aromatic hydrocarbon liquids (toluene and xylene) forming a major component and, as minor components, a mixture of lower molecular weight aliphatic alcohols, esters, and ketones (isopropyl alcohol, methyl ethyl ketone, 2-methyl 30 propanol, isopropyl acetate, and methyl isobutyl The membrane was estimated to be in the range of from 0.2 to 0.6 micron in thickness.

A balsa wood frame forming a square opening 16 cm on an edge was placed upon the membrane to protect an area, and the membrane outside the frame was then collapsed by crushing it against the frame. The microcellular film support was coated with this membrane by immersing the film support in

the water contained in the tray and then withdrawing it through the membrane with the microcells on the upper surface of the film support. The combined membrane and microcellular film support, with most microcells now containing water, was then dried, so that no water remained as a liquid within the microcells.

5

In order to increase the light absorbing capability of the membrane, the outer membrane

10 surface was passed rapidly through the incandescent portion of a candle flame. Under microscopic examination, carbon could be seen on the outer surface of the membrane.

To open a first set of microcells, the

microcellular film support with the membrane present providing a lightly carbon-coated outer surface was subjected to irradiation with a 647 nanometer laser beam in a pattern of laterally spaced lines. The beam power was in the 12 to 28 milliwatts per square centimeter range, and the beam cross-section was about 23 microns. Where the laser beam struck the membrane, the microcells were uncovered in a single or double line, depending upon the power and placement of the beam.

To form materials for selectively filling microcells, three subtractive primary filter dye compositions were prepared as described below, identified as Yellow Dye Dispersion A, Magenta Dye Dispersion B, and Cyan Dye Dispersion C. The filter dye was in each instance chosen to be immobile, thereby avoiding transfer from the microcells once introduced.

To form the compositions actually used to fill each of three separate sets of microcells, two of the subtractive primary dye dispersions identified above were blended to form an additive primary filter material. An initially mobile and colorless subtractive dye-forming coupler was also blended

with the two subtractive primary filter dyes. (The mobile couplers were, of course, immobile in the microcells, since mobility refers only to mobility upon contact with a photographic processing solution.)

5

Yellow Dye Dispersion A

A conventional aqueous-oil dispersion was prepared by homogenizing 40 grams yellow dye $3-13-[\alpha-(2,4-di-\underline{t}-pentylphenoxy)]$ acetamido]-

benzamido/-4-(4-methoxyphenylazo)-1-(2,4,6-trichlorophenyl)-2-pyrazolin-5-one, 120 grams auxiliary solvent 2-(2-butoxyethoxy)ethyl acetate and 27.2 grams gelatin diluted to 454 grams with water. Following homogenization, the dispersion was chill-set and noodle-washed to remove the auxiliary solvent.

Magenta Dye Dispersion B

A conventional aqueous-oil dispersion was prepared by homogenizing 40 grams magenta dye

3-13-[α-(2,4-di-t-pentylphenoxy)acetamido]benzamido/-N-14-[N-ethyl-N-(2-hydroxyethyl)amino]-2-tolylimino/-1-(2,4,6-trichlorophenyl)2-pyrazolin-5-one, 80 grams permanent solvent
1,4-cyclohexylenedimethylbis(2-ethylhexanoate), 80

grams auxiliary solvent cyclohexanone, and 60 grams gelatin diluted to 1000 grams with water. Following homogenization, the dispersion was chill-set and noodle washed to remove the auxiliary solvent.

Cyan Dye Dispersion C

A conventional aqueous-oil dispersion was prepared by homogenizing 40 grams 2-[4-(2,4-di-t-pentylphenoxy)butylcarbamoyl]-N-i-4-[N-ethyl-N-(2-hydroxyethyl)amino]-2-tolyl/-1,4-naphthoquinone 4-monoimine, 80 grams permanent solvent 1,4-cyclo-hexylenedimethyl bis(2-ethylhexanoate), 80 grams auxiliary solvent cyclohexanone, and 60 grams gelatin diluted to 1000 grams with water. Following homogenization, the dispersion was chill-set and

noodle-washed to remove the auxiliary solvent.

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Dry Red Microsphere Dispersion Beads

First, 30 grams of yellow dye dispersion A and 30 grams of magenta dye dispersion B were melted together and diluted to 750 ml with water. Next, 3.0 grams cyan dye-forming coupler, 1-hydroxy-N-[2-(2-acetamido)phenethyl]-2-naphthamide, were dissolved in a minimum amount of ethyl alcohol and 5 percent sodium hydroxide and added to the solution of dispersions.

The resultant mixture was passed through a DeVilbiss* (Model 65) ultrasonic nebulizer and into a heat jacketed drying column where the water was evaporated. The resultant dry red microsphere dispersion beads containing a cyan dye-forming coupler were collected and examined microscopically. They were approximately three microns and smaller in size.

Dry Green Microsphere Dispersion Beads

Yellow dye dispersion A, 20 grams, and cyan dispersion C, 40 grams, were melted together and diluted to 750 ml with water. Magenta dye-forming coupler, 3-(4-nitroanilino)-1-(2,4,6-trichloro-phenyl)-2-pyrazolin-5-one, 3.0 grams, dissolved in a minimum amount of ethyl alcohol and 5 percent sodium hydroxide were added to the solution of dispersions. Following treatment in the nebulizer and drying column, dry green microsphere dispersion beads containing a yellow dye-forming coupler were obtained.

Dry Blue Microsphere Dispersion Beads

Magenta dye dispersion B, 30 grams, and cyan dye dispersion C, 30 grams, were melted together and diluted to 750 ml with water. Yellow dye-forming coupler, α-(4-carboxyphenoxy)-α-pivaloyl-2,4-dichloroacetanilide, 3.0 grams, dissolved in a minimum amount of ethyl alcohol and 5 percent sodium hydroxide were added to the solution

of dispersions. Following treatment in the nebulizer and drying column, dry blue microsphere dispersion beads containing a yellow dye-forming coupler were obtained.

The microcellular film support with the membrane thereon destroyed in laterally spaced lines to open a first interlaid set of microcells was covered with the green microsphere dispersion beads. The dispersion beads were introduced into the opened microcells with a flexible rubber blade with excess beads being removed by brushing.

Microscopic examination showed that microcells not struck by the laser beam still retained a membrane cover.

The microcellular film support with the membrane thereon was again scanned with the laser microbeam, but at an angle to the first linear scan. As before, the laser microbeam removed membrane in areas contacted, leaving a second, interlaid set of microcells uncovered. The newly uncovered microcells were filed with blue microsphere dispersion beads by the same procedure described above for filling with the green microsphere dispersion beads.

Thereafter, the remnants of the membrane were removed with an adhesive tape, opening the third interlaid set of microcells. The newly opened microcells were filled with the red microsphere dispersion beads. Excess fill material was then lifted from the microcellular face of the film support using adhesive tape.

The resulting three color microcellular filter array was placed in a high relative humidity environment overnight. The microcell contents

35 became less scattering and appeared to be partially fused.

Example 23

The procedure of Example 22 was repeated, except that the balsa wood frame was immersed in the water beneath the membrane and lifted upwardly to raise the membrane from the surface of the water. Thereafter the microcellular support element was gently laid on the membrane so that the membrane closed the microcells. The support element with the membrane in place was flexed so that the first major surface bearing the microcells was convex. Final setting of the membrane occurred with the support in this configuration.

Example 24

The procedure of Example 22 was repeated,

15 except that the composition of the casting solution
was varied. The casting solution employed to form
the membrane consisted of 8.5 grams of cellulose
acetate and 42.0 grams of solvent. The solvent
consisted of 80 ml of dichloromethane and 20 ml of

20 methanol containing 0.6 g of Genacryl Blue dye to
enhance the radiation adsorption of the membrane.
No carbon was placed on the surface of the membrane.
Example 25

The procedure of Example 22 was repeated,

25 except that the composition of the casting solution
was modified to include 1 g of Sudan Black B, wet
with 10 drops of dichloromethane per 12 g of casting
solution. No carbon was placed on the surface of
the membrane.

In both Examples 24 and 25, the membranes adsorbed sufficient radiant energy from the laser to permit their local destruction to open selected microcells.

WHAT IS CLAIMED IS

A photosensitive element comprising a support and radiation-sensitive imaging means capable of undergoing as a function of at 5 least one of photographic exposure and processing a change in the optical density or mobility of said imaging means characterized in that said support provides a nonplanar surface pattern forming an array and said imaging means includes a high aspect 10 ratio tabular grain silver halide emulsion comprised of a dispersing medium and silver halide grains, wherein tabular silver halide grains having a thickness of less than 0.5 micron and a diameter of at least 0.6 micron have an average aspect ratio of 15 greater than 8:1 and account for at least 50 percent of the total projected area of the silver halide grains.

20

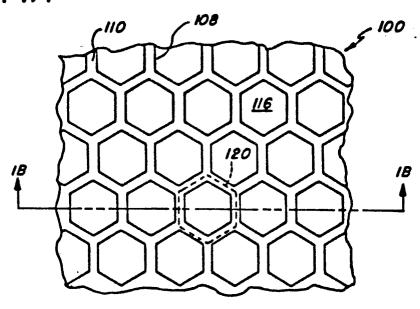
25

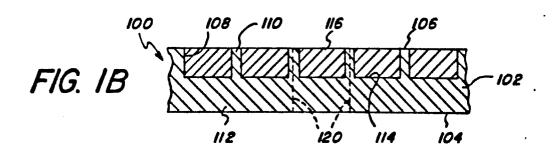
30

35

1/20

FIG. IA





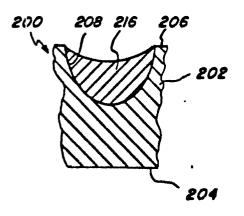


FIG. 2

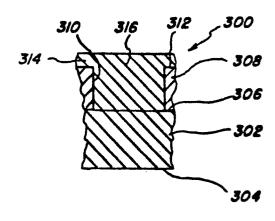
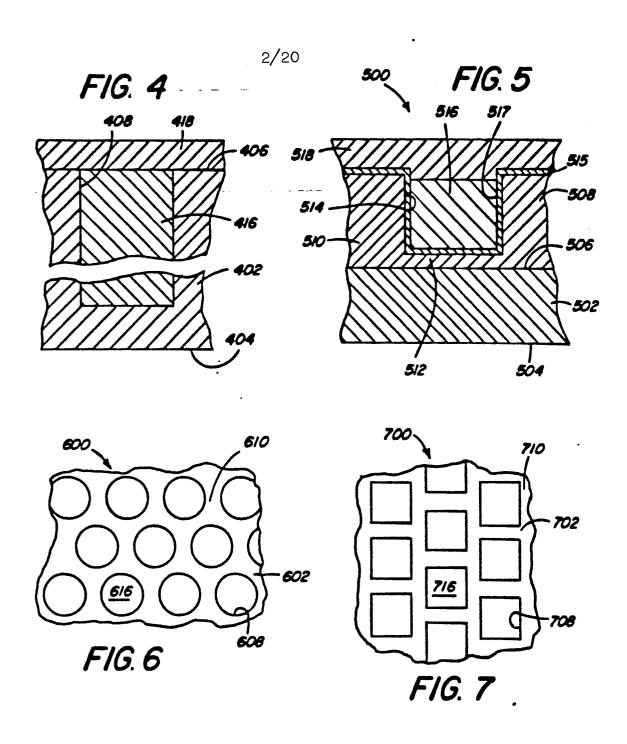
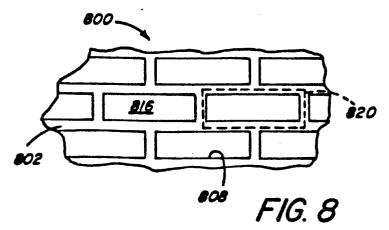


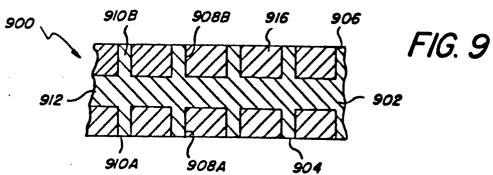
FIG. 3

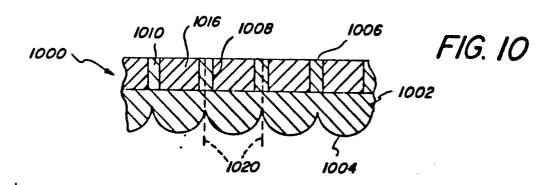


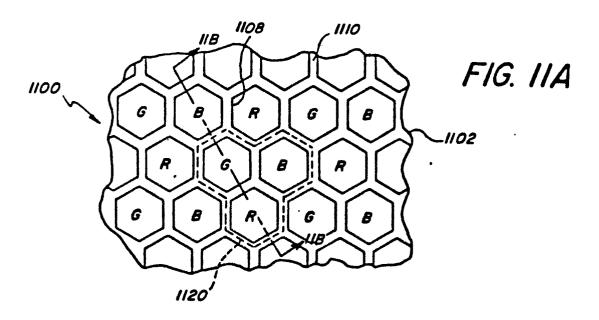


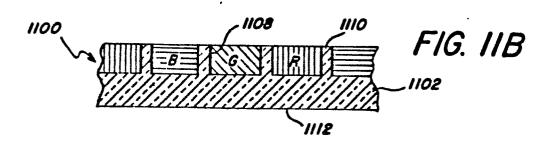


)









4/20

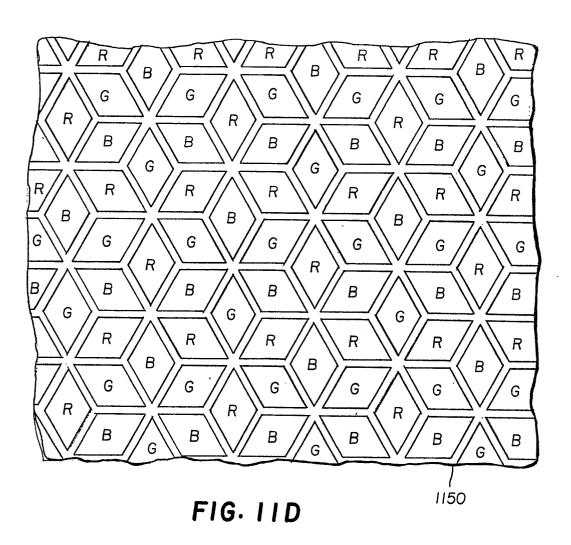
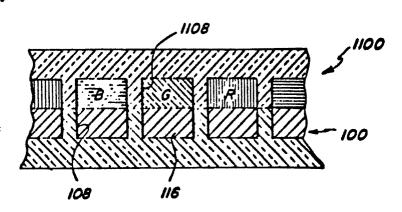
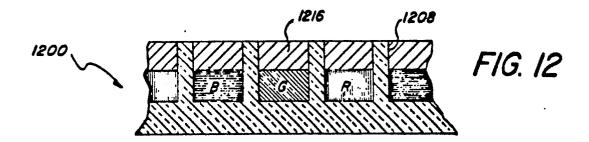
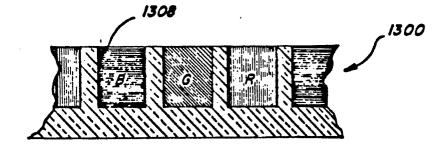


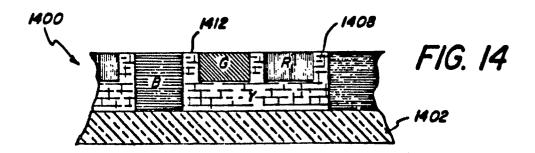
FIG. IIC

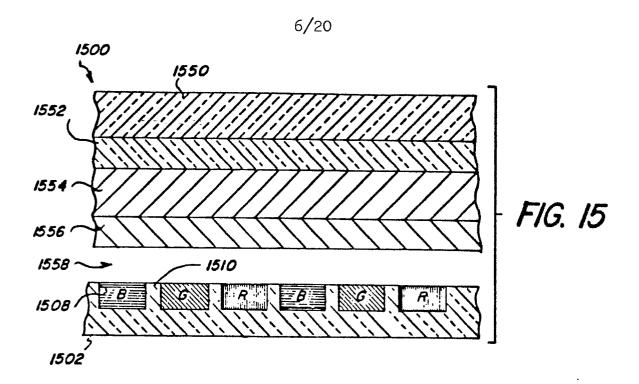


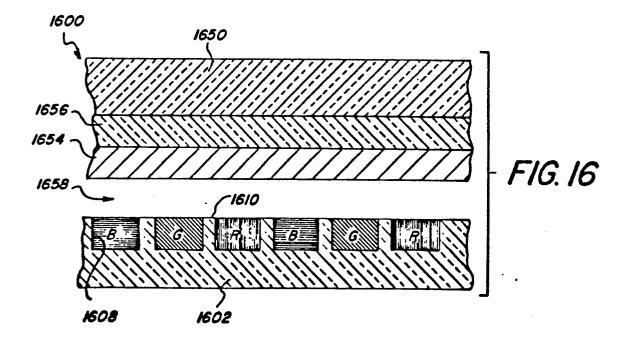


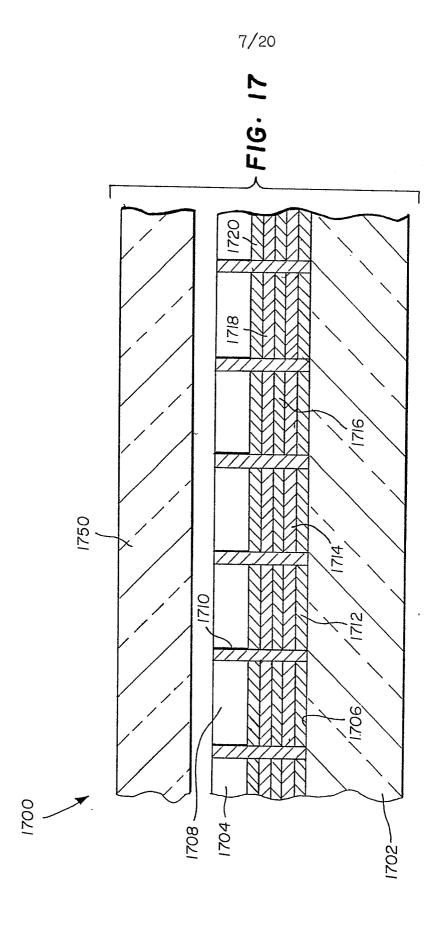


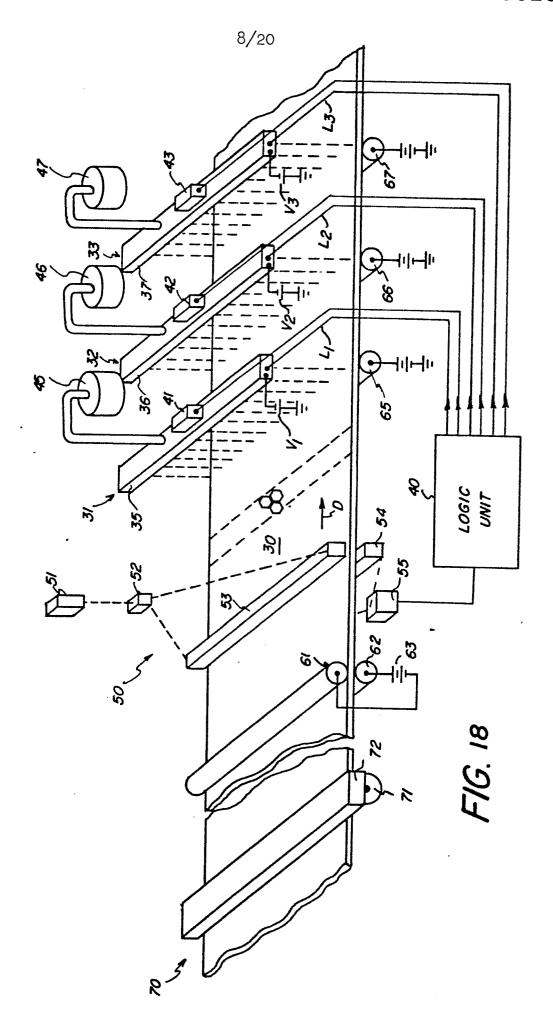


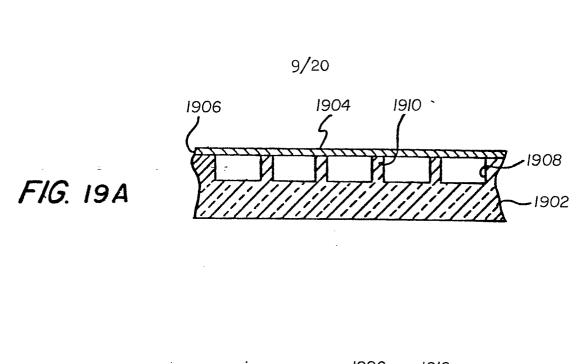


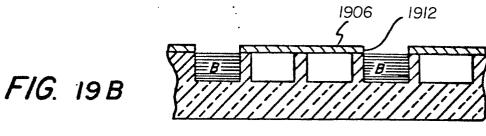


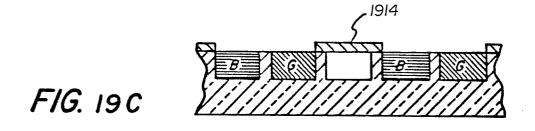


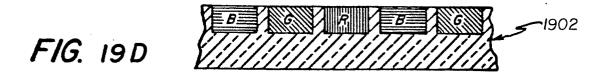


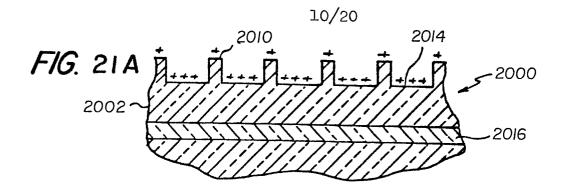


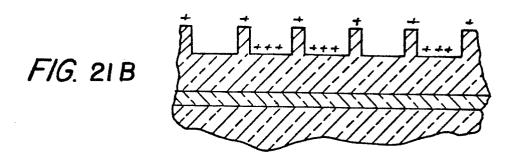


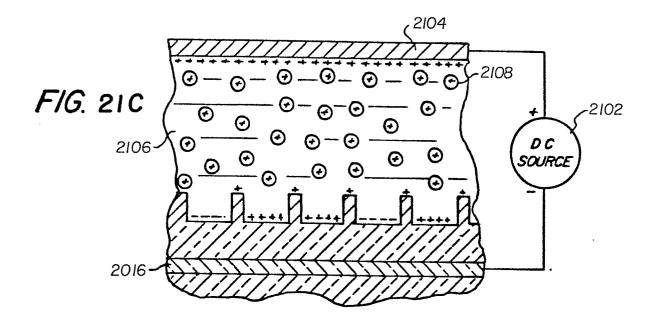


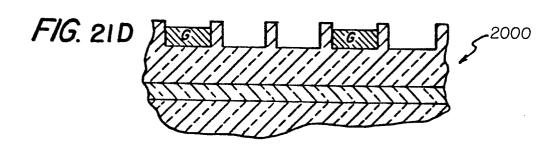


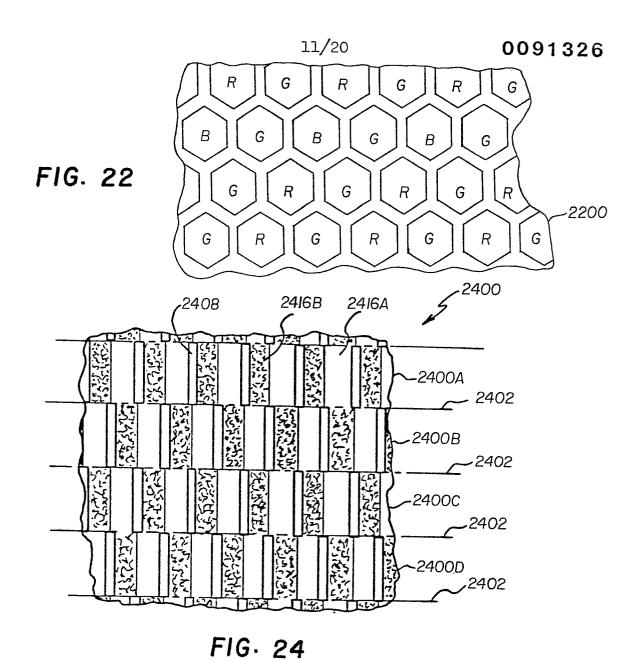












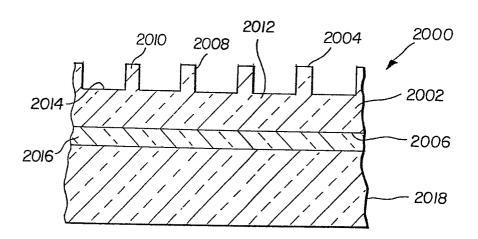
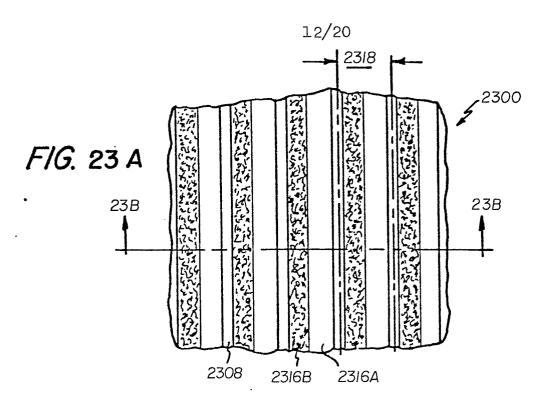
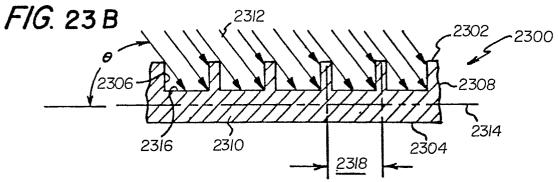
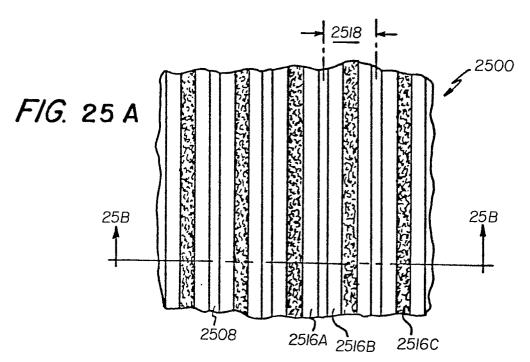
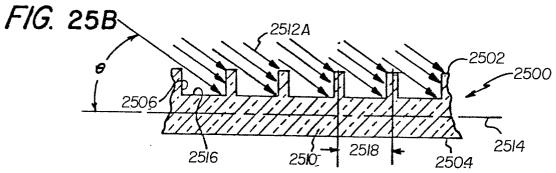


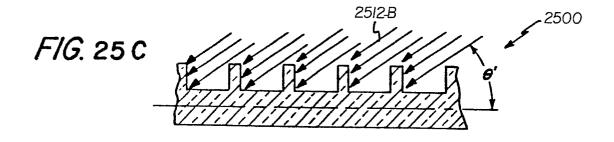
FIG. 20











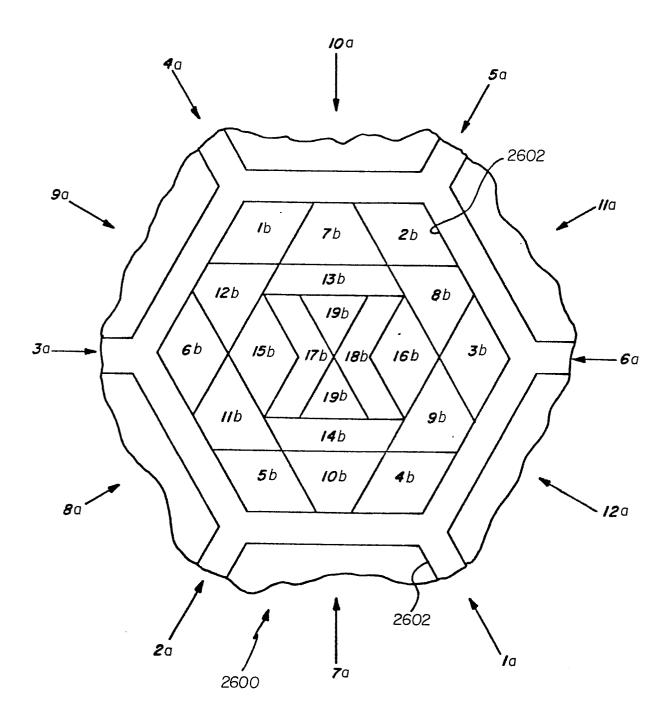


FIG. 26 A

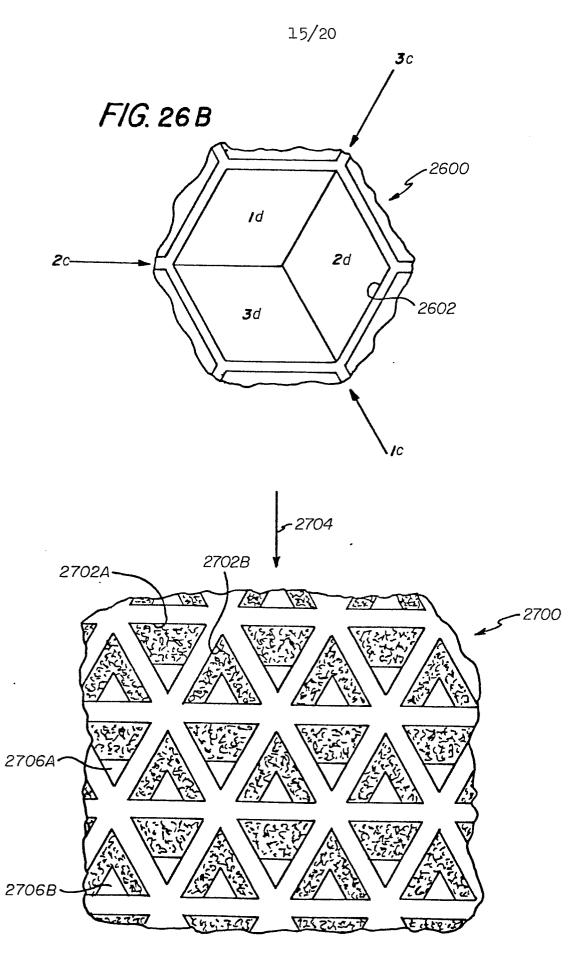
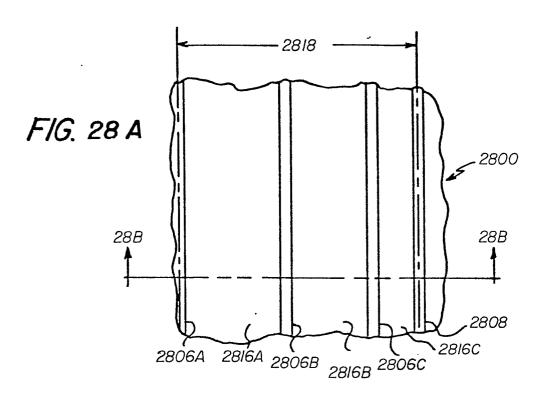
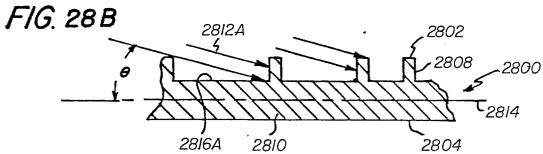
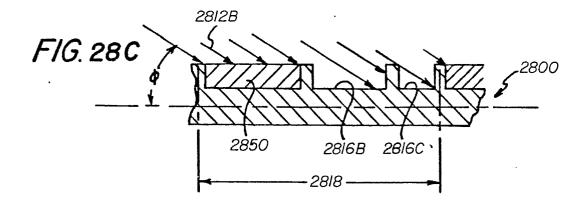


FIG. 27

16/20

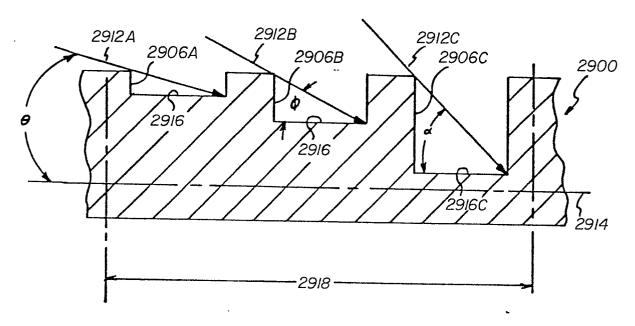


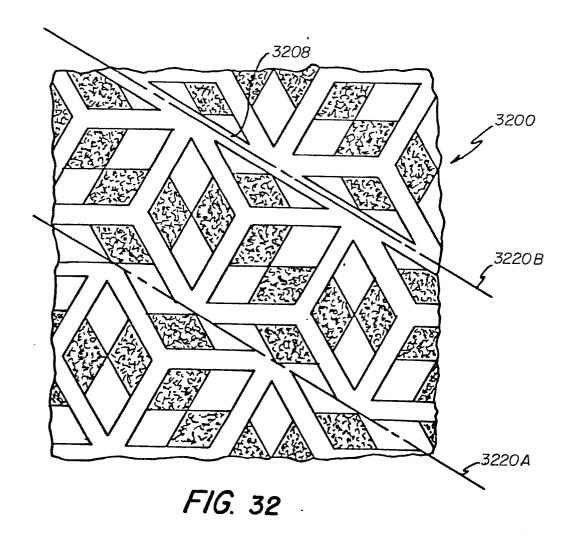




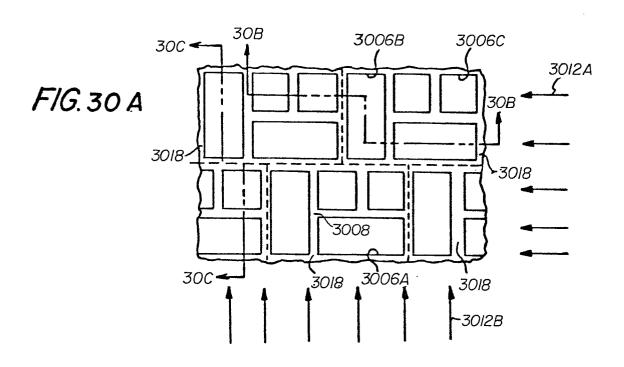
17/20

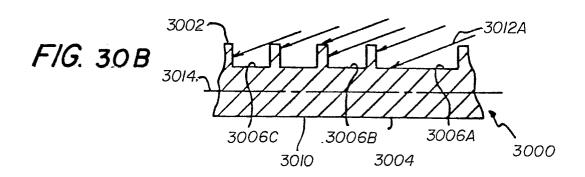
FIG. 29

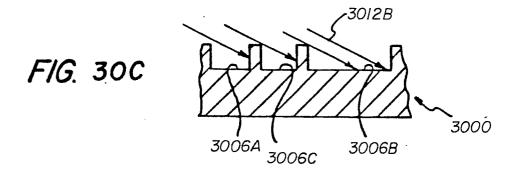




18/20







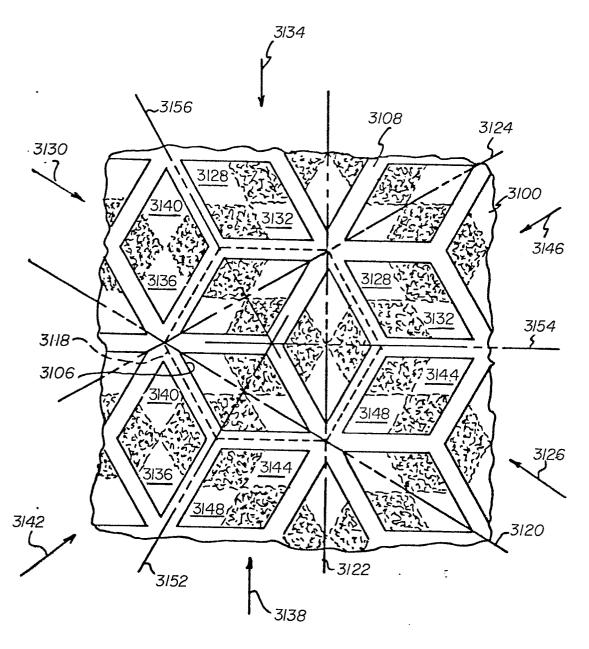
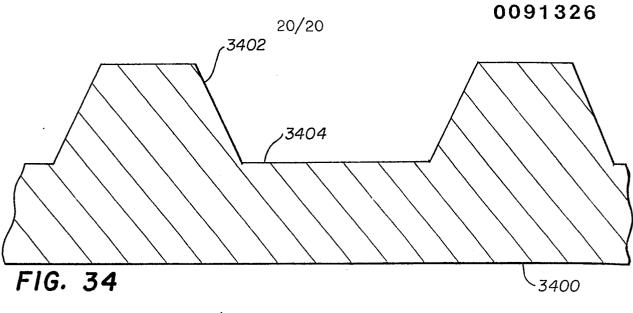


FIG. 31



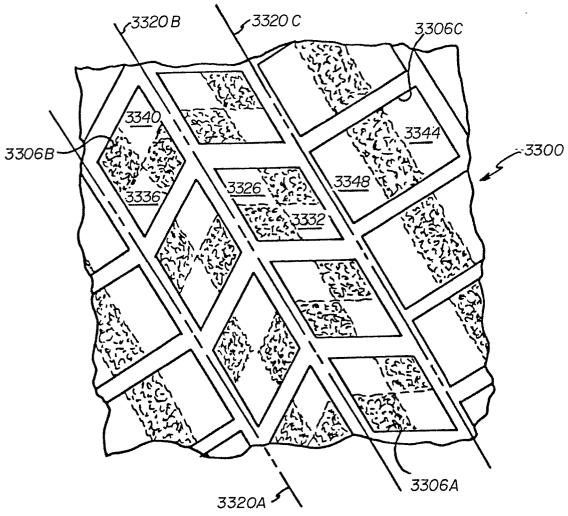


FIG. 33